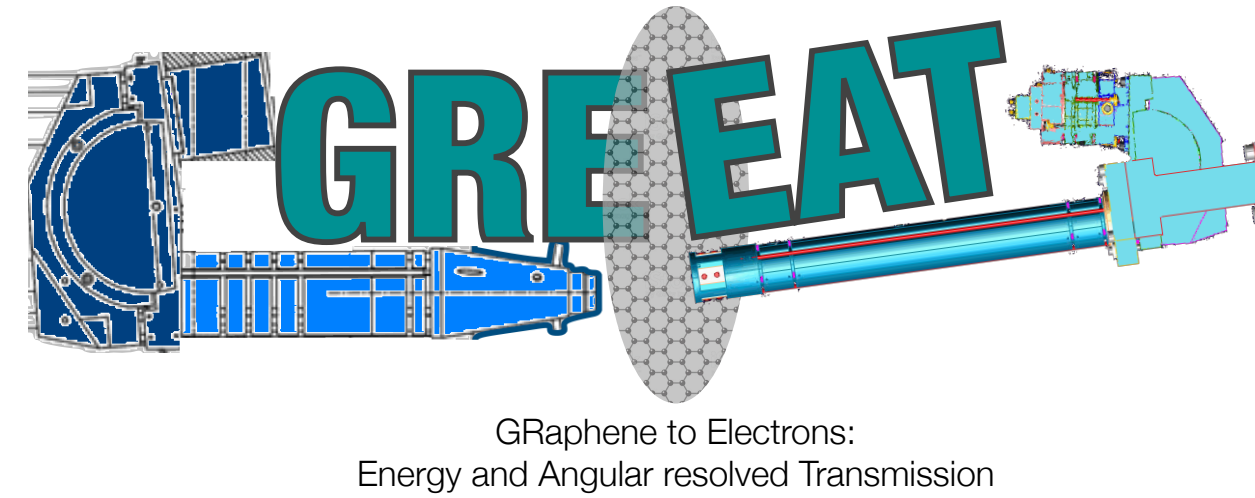




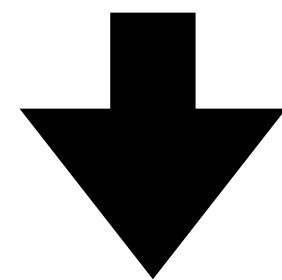
ELECTRON TRANSMISSION THROUGH MONOLAYER GRAPHENE BETWEEN 200 AND 5000 eV

PTOLEMY COLLABORATION MEETING, 01/07/2025

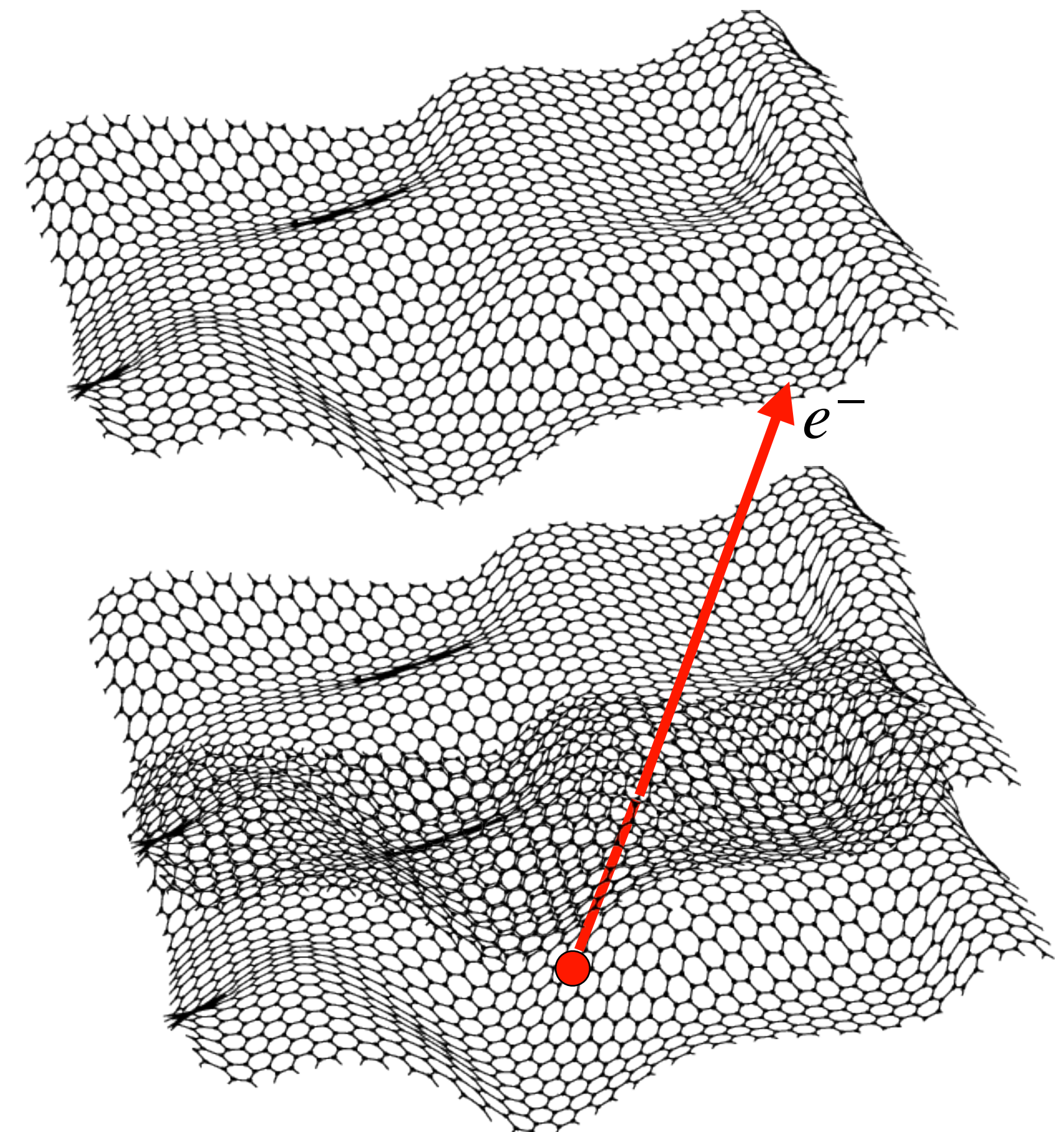
ALICE APPONI, ORLANDO CASTELLANO, MARTINA CHIRICO, FRANCESCO PANDOLFI, ALESSANDRO RUOCCO

WE NEED TO OPTIMIZE THE TRITIUM SOURCE

- $1\ \mu\text{g}$ of T correspond to $\mathcal{O}(\text{cm}^2)$ of graphene
- 1) Which is the best way to arrange all this graphene?
 - 2) Can we **stack graphene monolayers** one on top of the other?



Check whether β electrons of T are affected by the **passage through graphene**



THE GREEAT PROJECT



Research article
**Transmission through graphene of electrons
in the 30 – 900 eV range**

Alice Apponi ^{a b}, Domenica Convertino ^c, Neeraj Mishra ^{c d}, Camilla Coletti ^{c d},
Mauro Iodice ^b, Franco Frasconi ^e, Federico Pilo ^e, Narcis Silviu Blaj ^f, Daniele Paoloni ^{a b},
Ilaria Rago ^g, Giovanni De Bellis ^{h i}, Gianluca Cavoto ^g, Alessandro Ruocco ^{a b}

**Transmission
up to 5 keV**

**Total cross
section**

**Differential
cross section**

**Extend the
study to other
nanostructures**

THE GREEAT PROJECT



Research article

Transmission through graphene of electrons
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**Transmission
up to 5 keV**

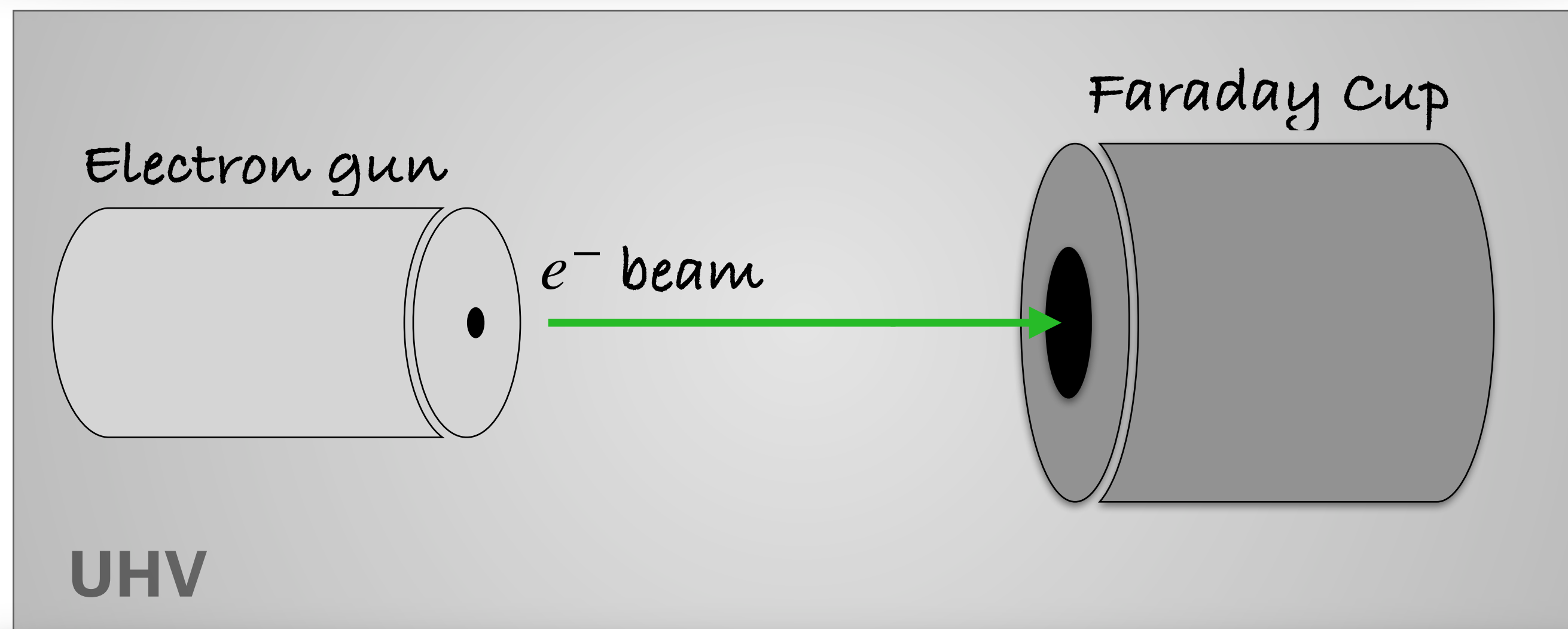
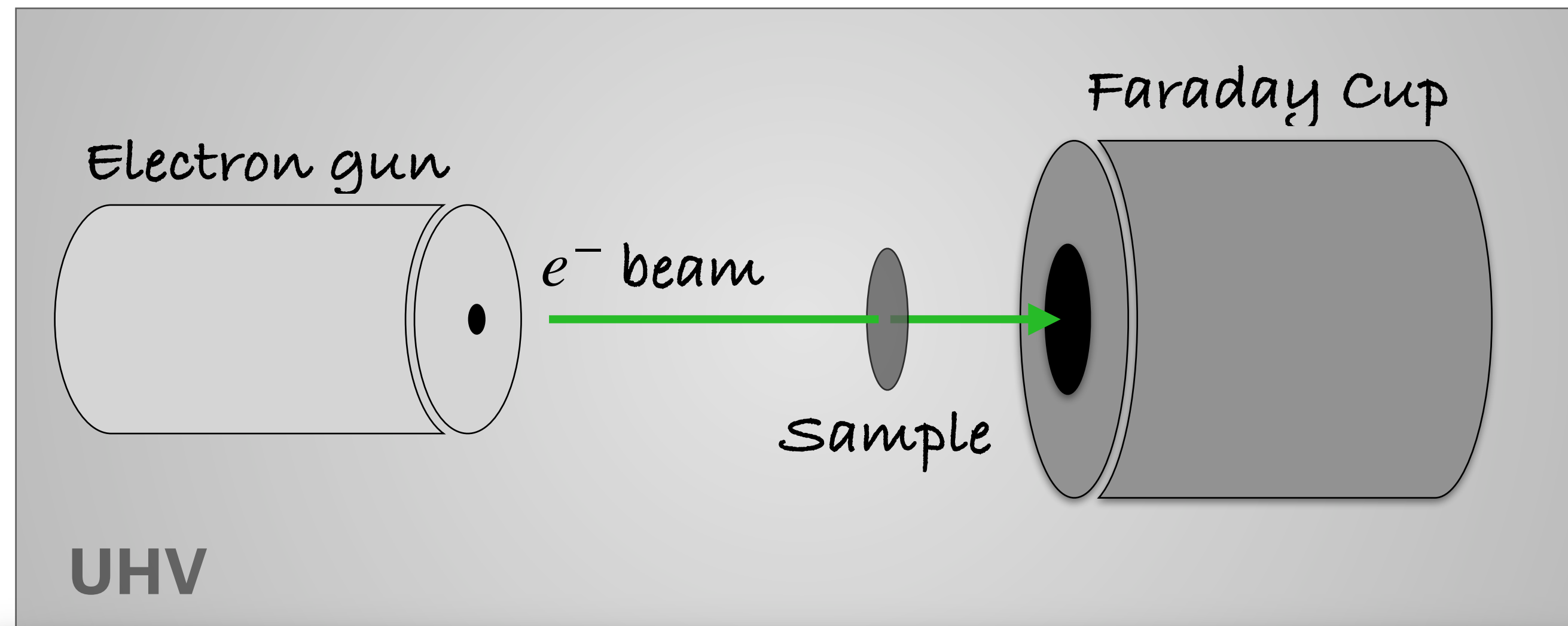
This talk!

**Total cross
section**

**Differential
cross section**

**Extend the
study to other
nanostructures**

ELECTRON TRANSMISSION THROUGH GRAPHENE

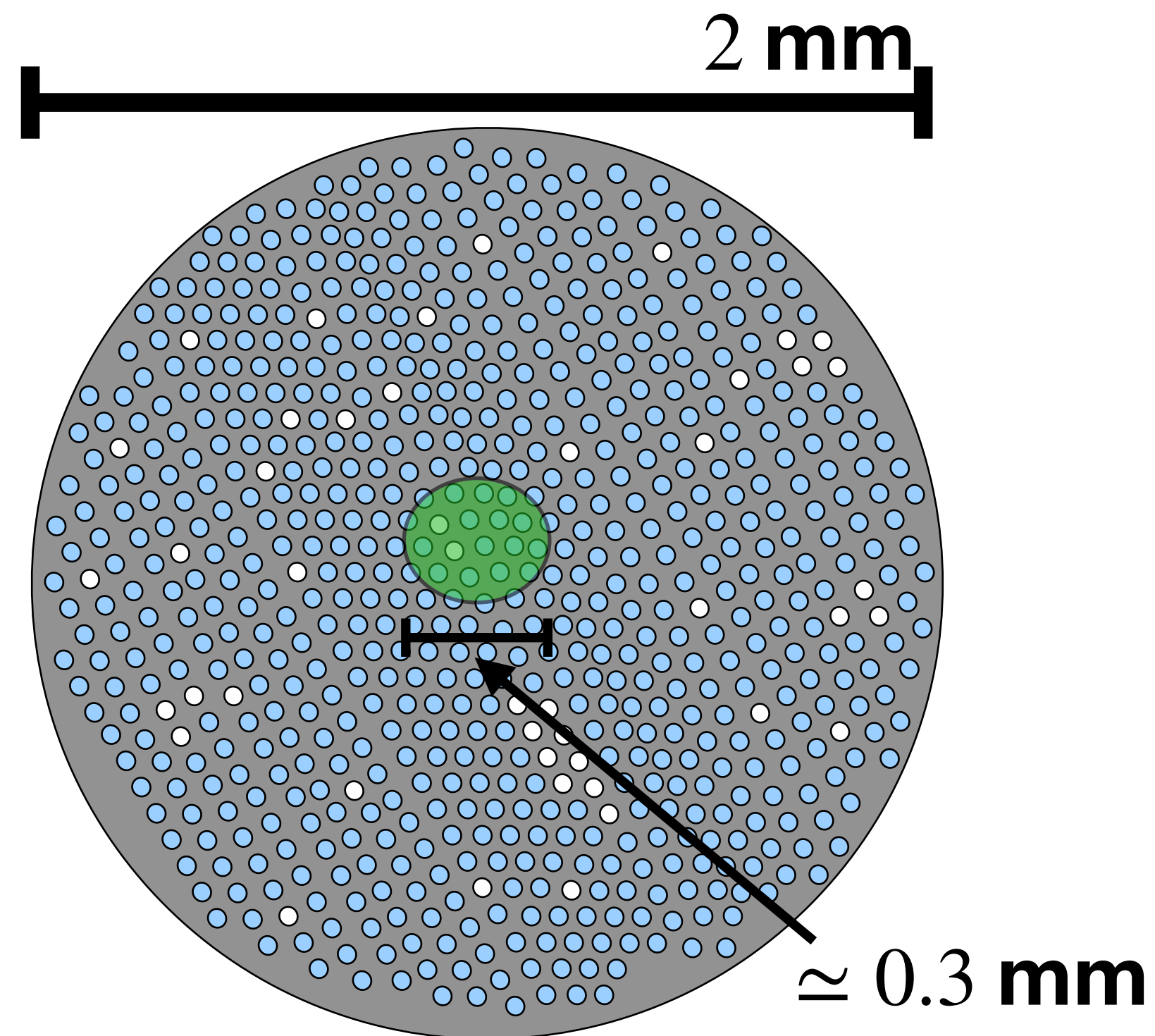


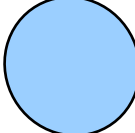
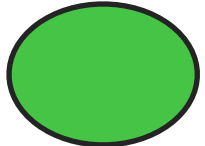
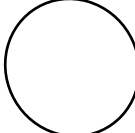
- Measure I_{sample}

- Measure I_0

Reconstruct T_G

I_{MEAS} IS A SUM OF TWO CONTRIBUTIONS



-  = covered hole
-  = electron spot
-  = uncovered hole
-  = grid

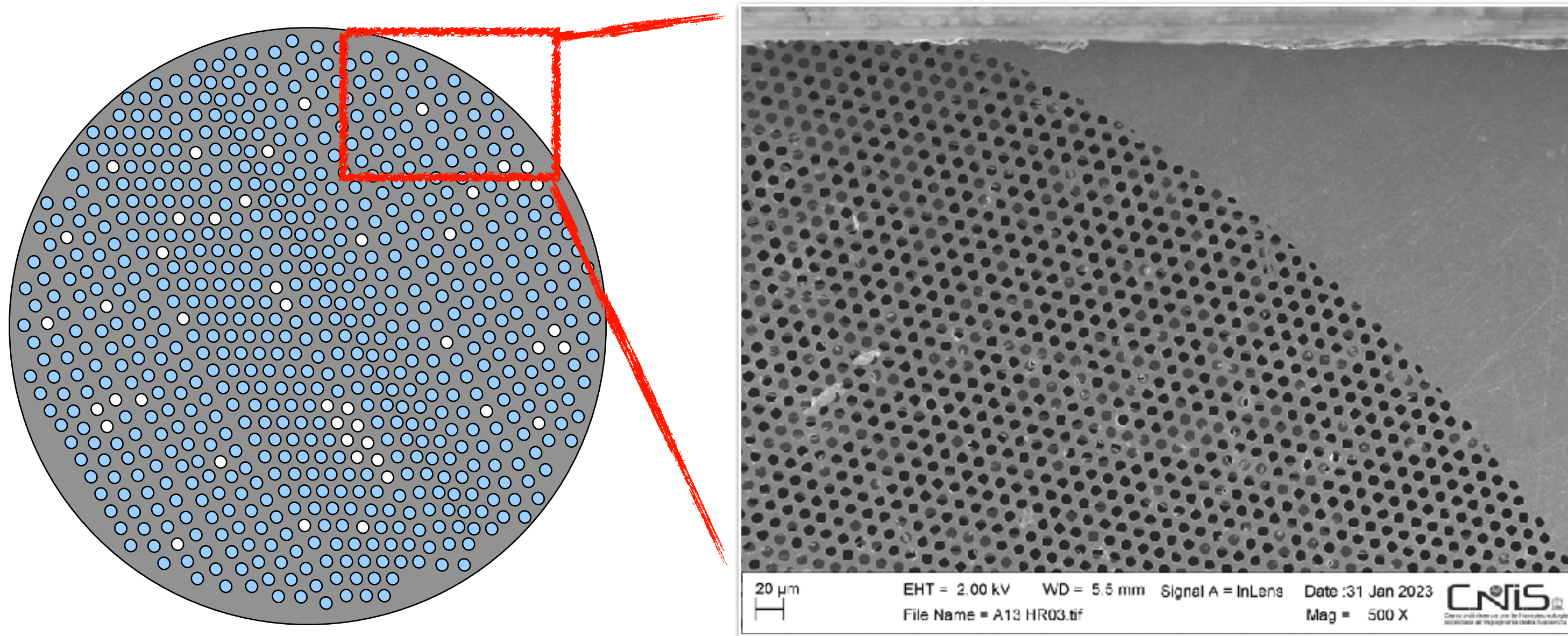
$$I_{meas} = I_0 T_{geom} [a T_G + (1 - a)]$$

Where:

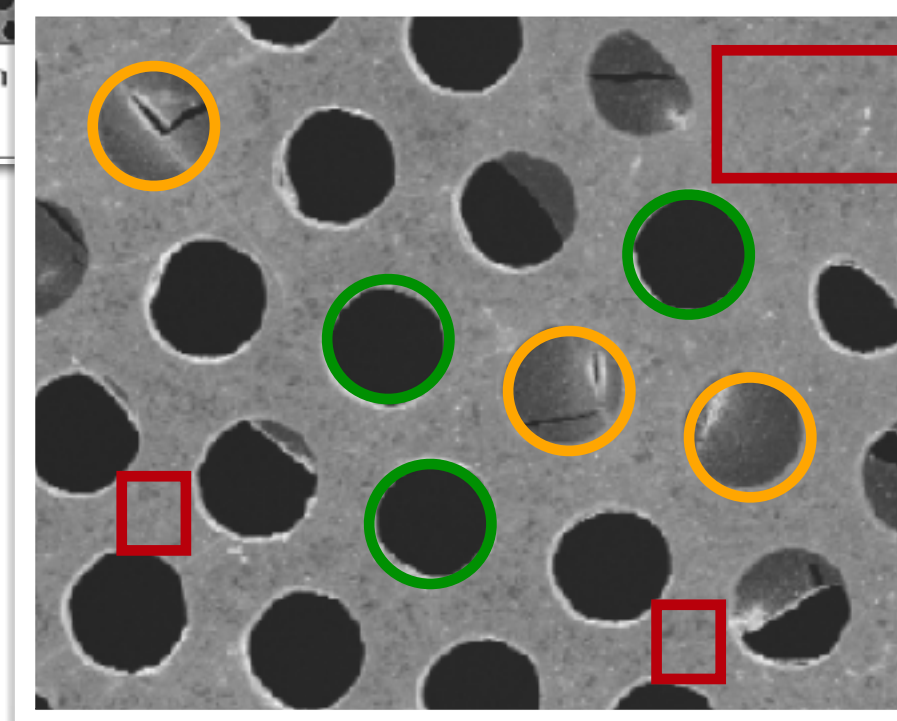
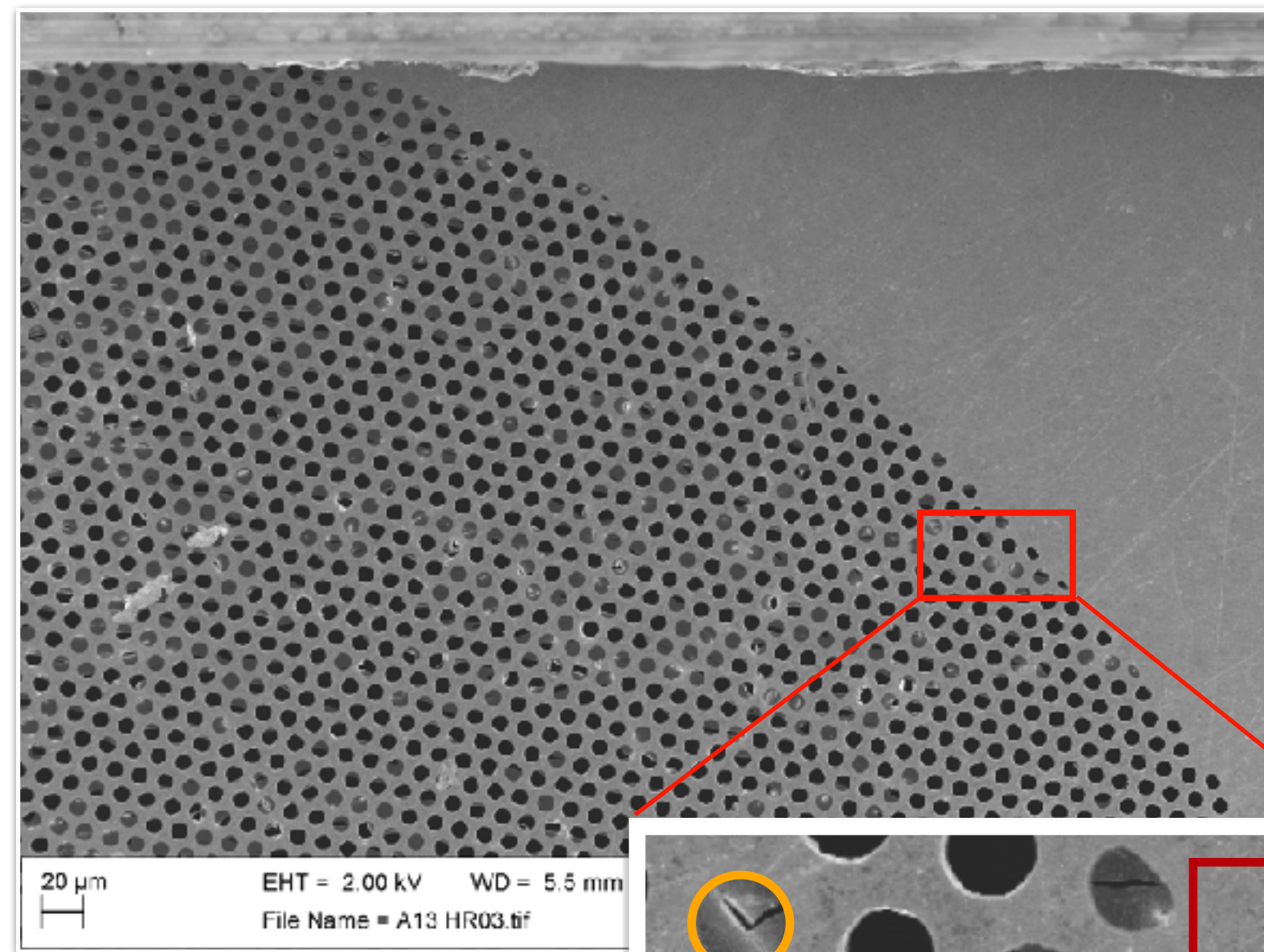
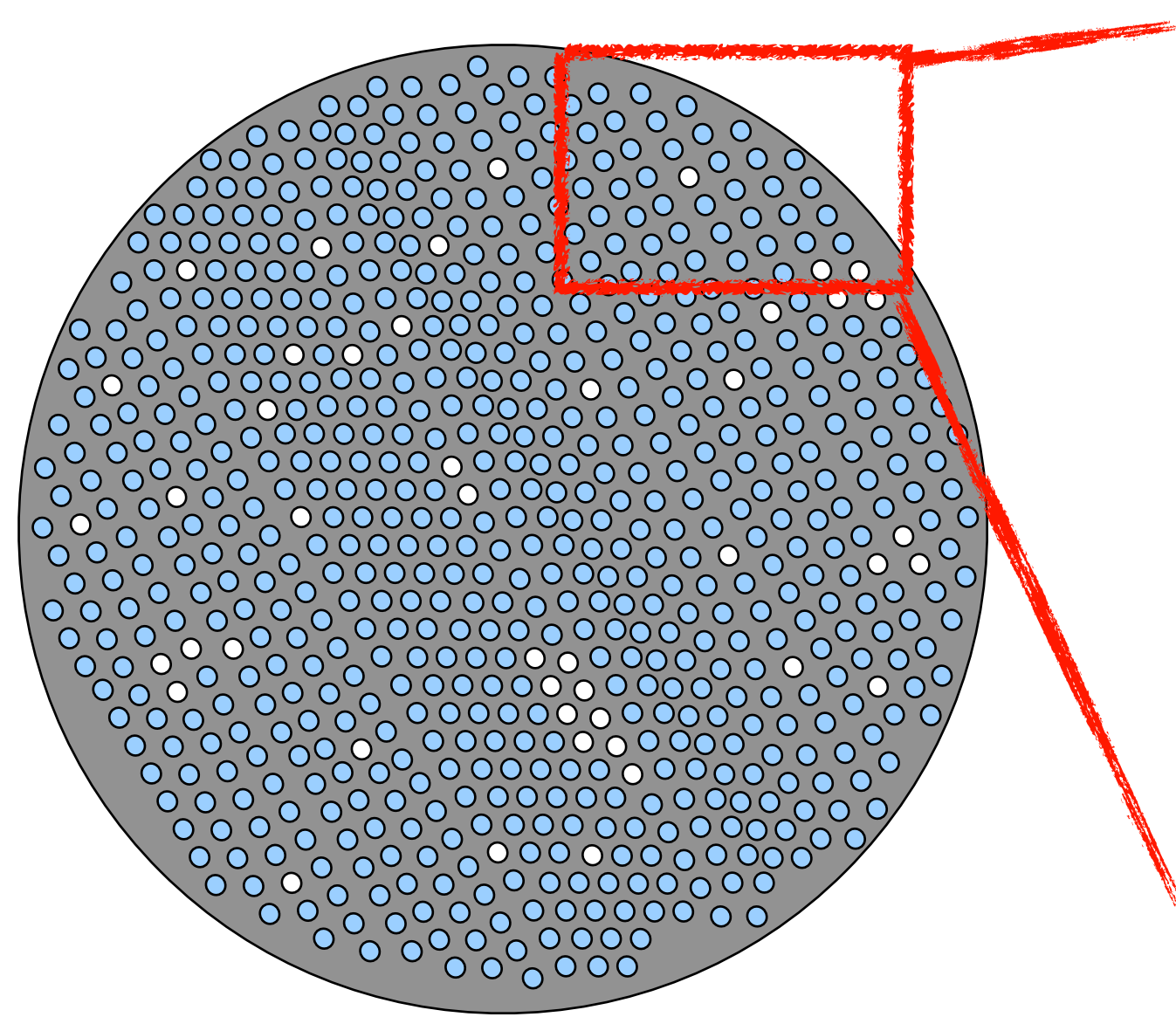
- $T_{geom} = \frac{\text{Area} (\text{blue circle} + \text{white circle})}{\text{Area} (\text{blue circle} + \text{white circle} + \text{gray square})}$

- $a = \frac{\text{Area} (\text{blue circle})}{\text{Area} (\text{blue circle} + \text{white circle})}$

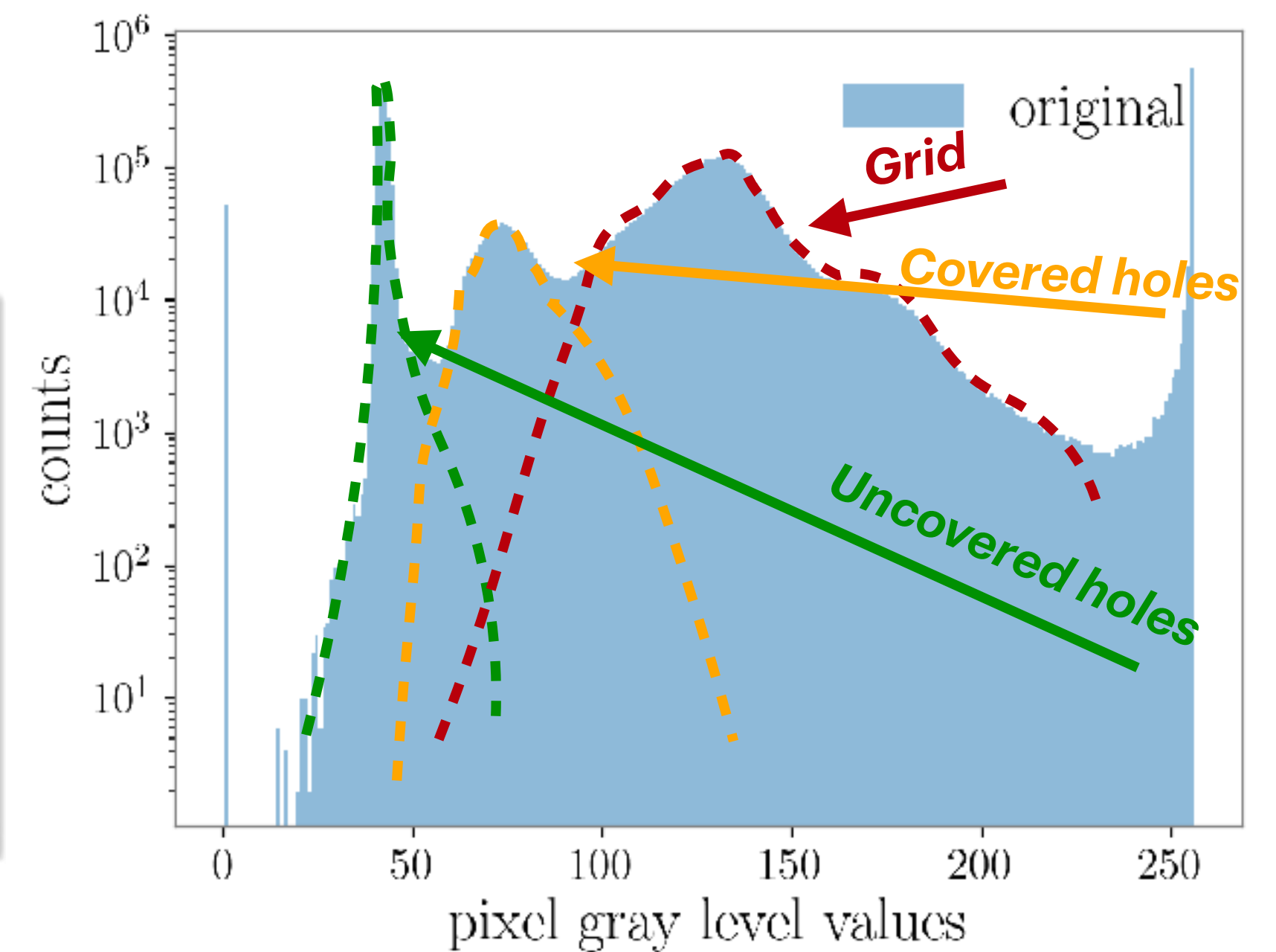
SAMPLE CHARACTERIZATION @ SEM



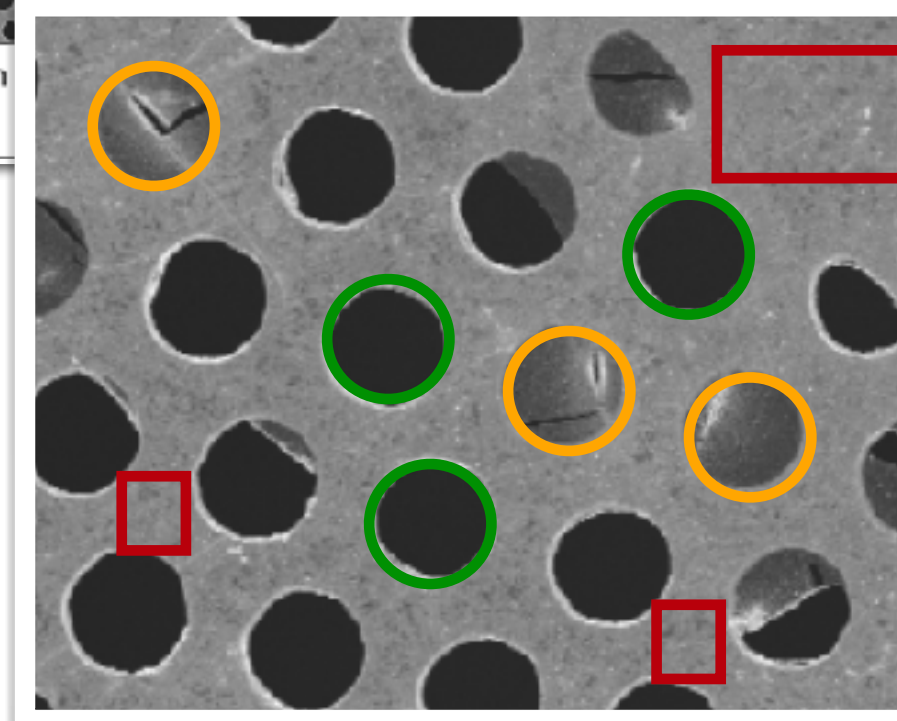
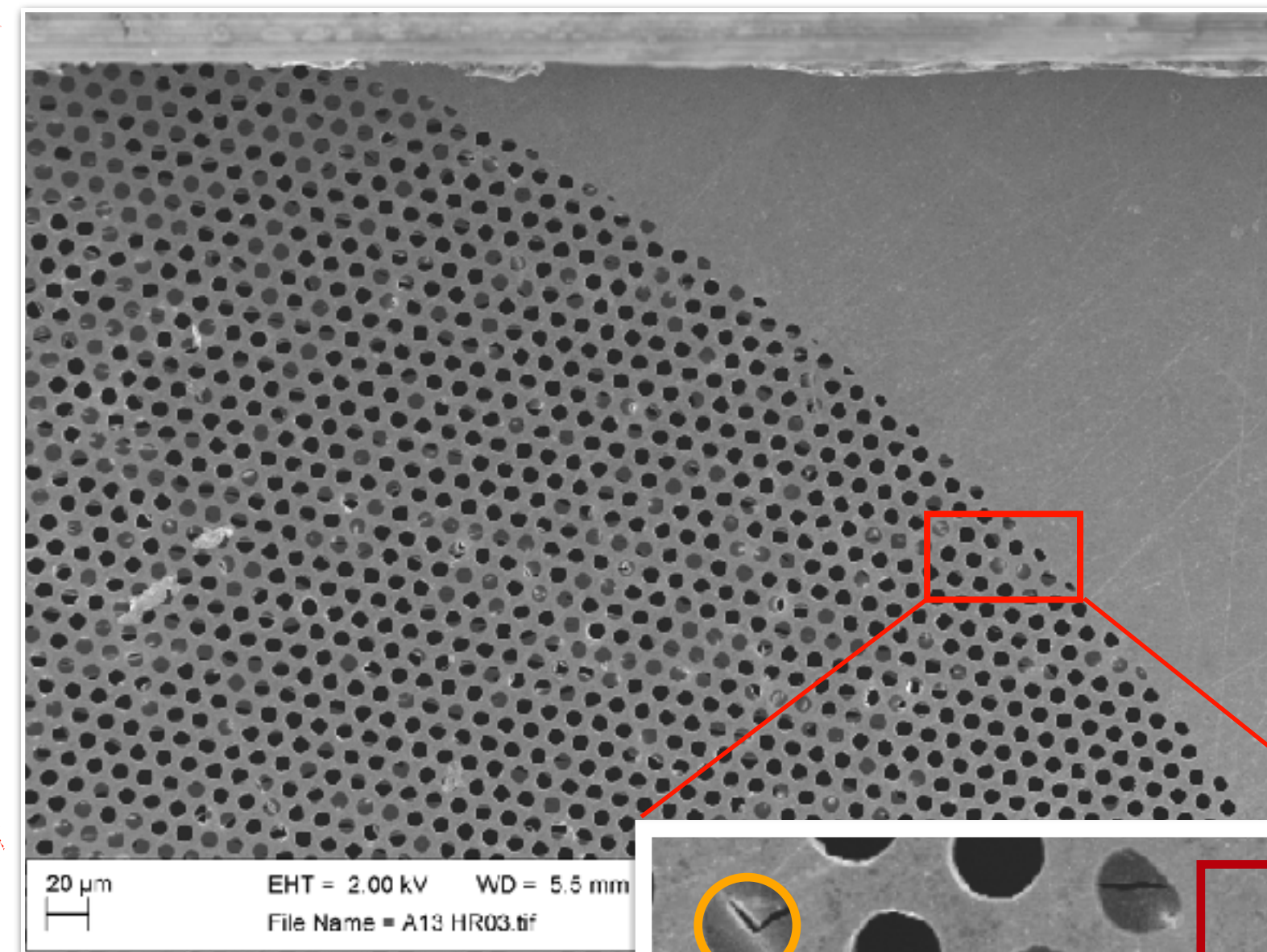
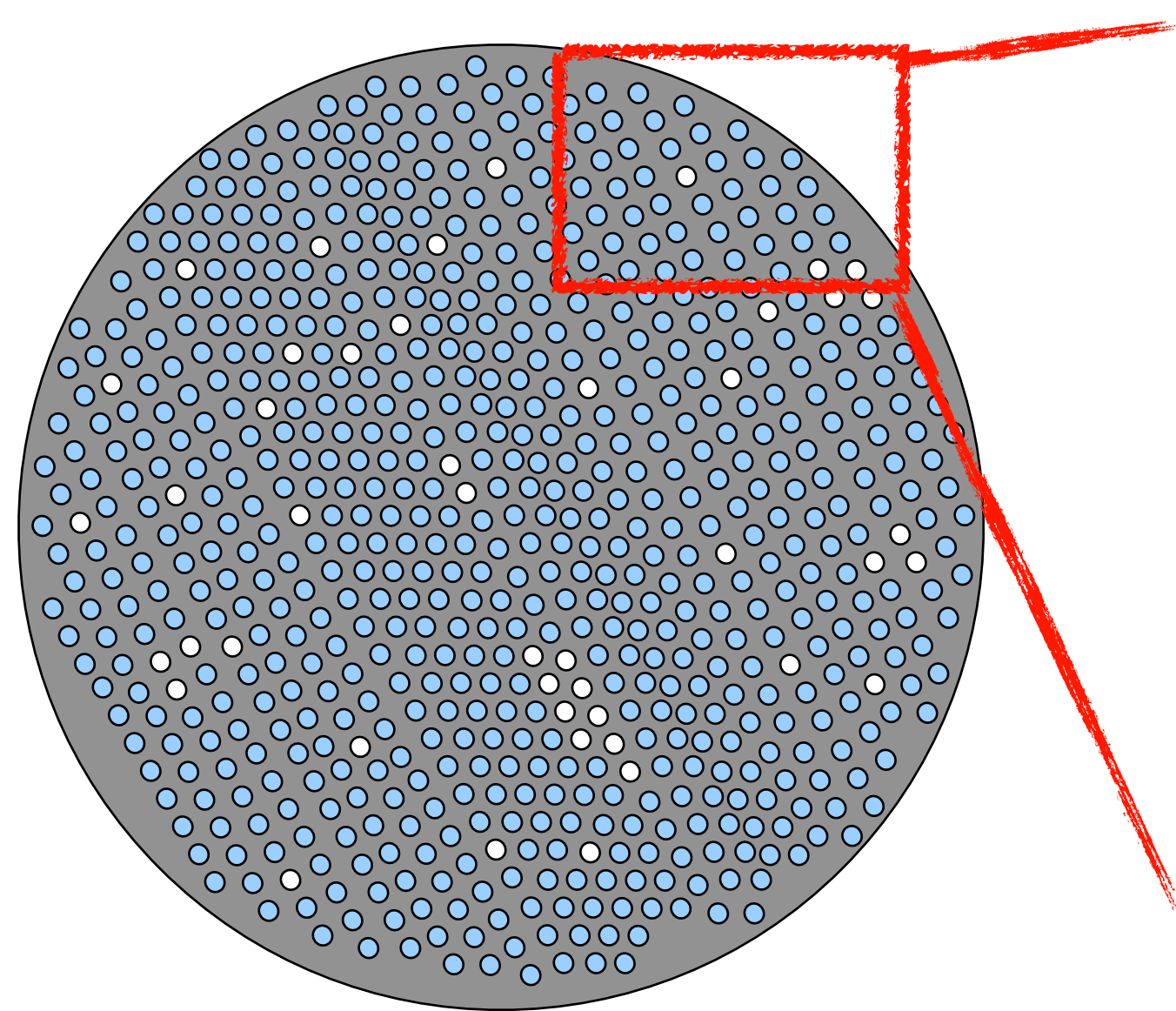
SAMPLE CHARACTERIZATION @SEM



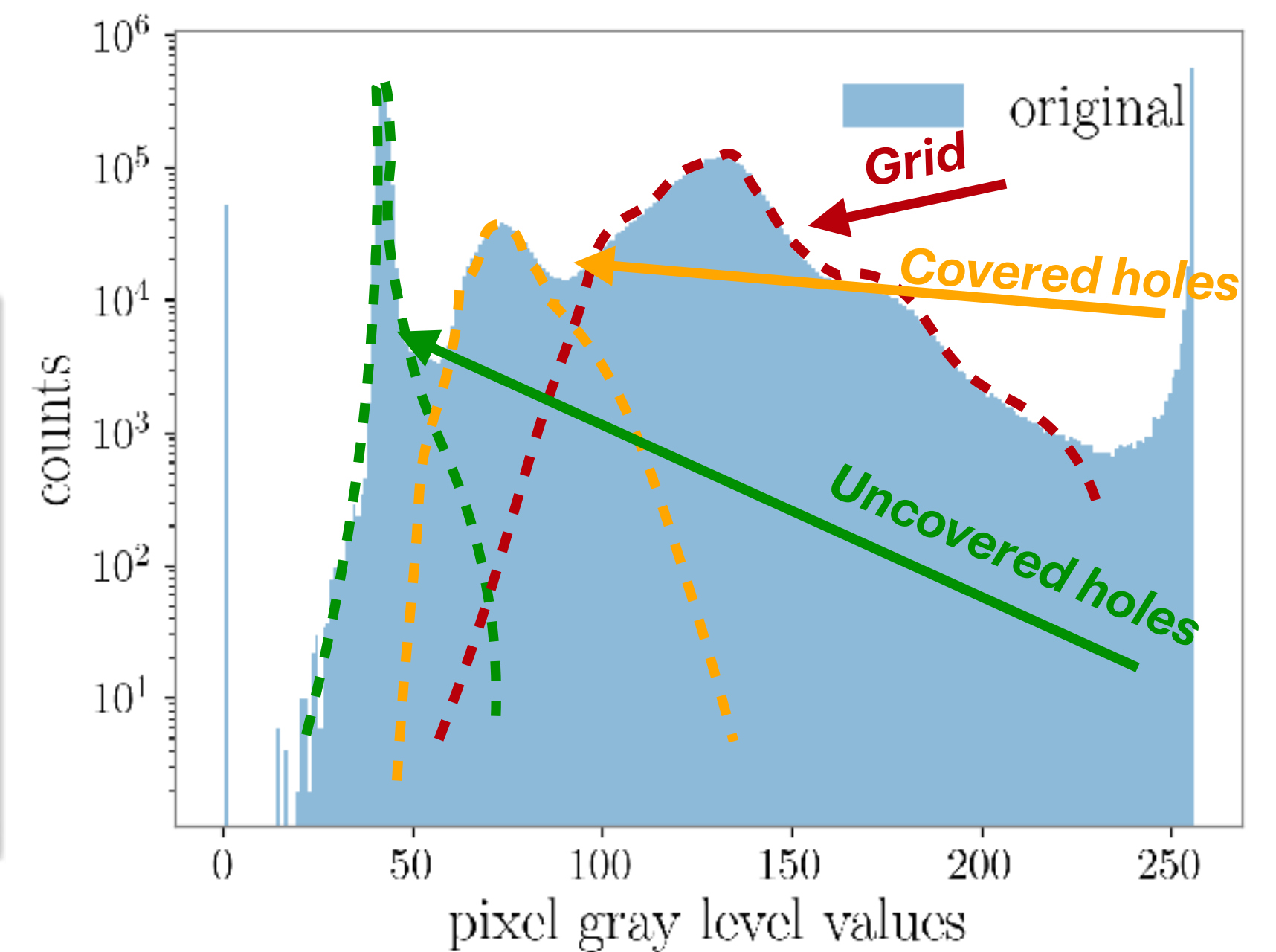
Pixel gray level histogram



SAMPLE CHARACTERIZATION @SEM

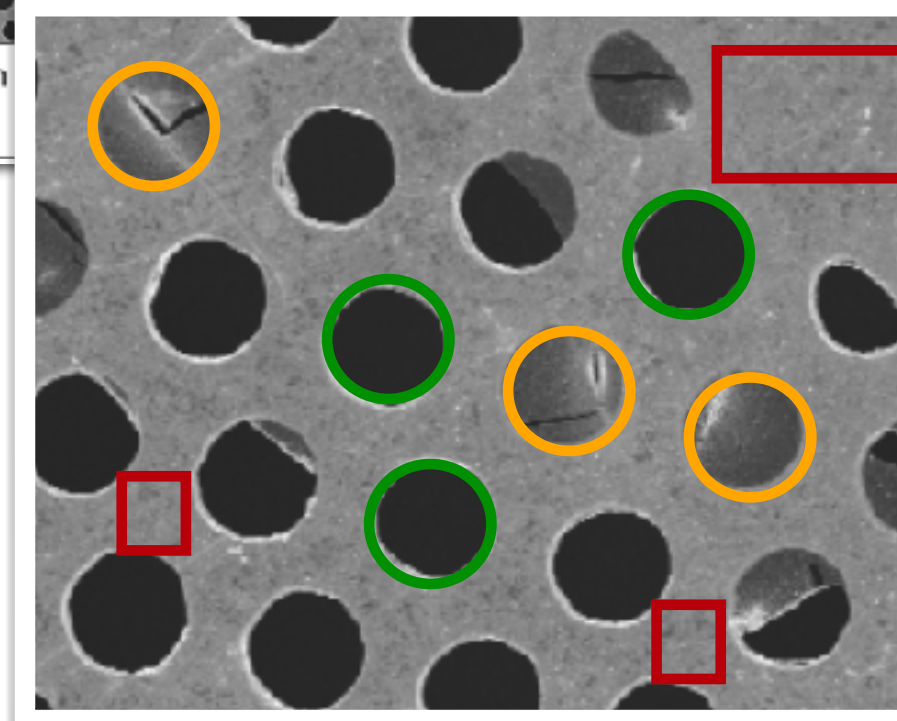
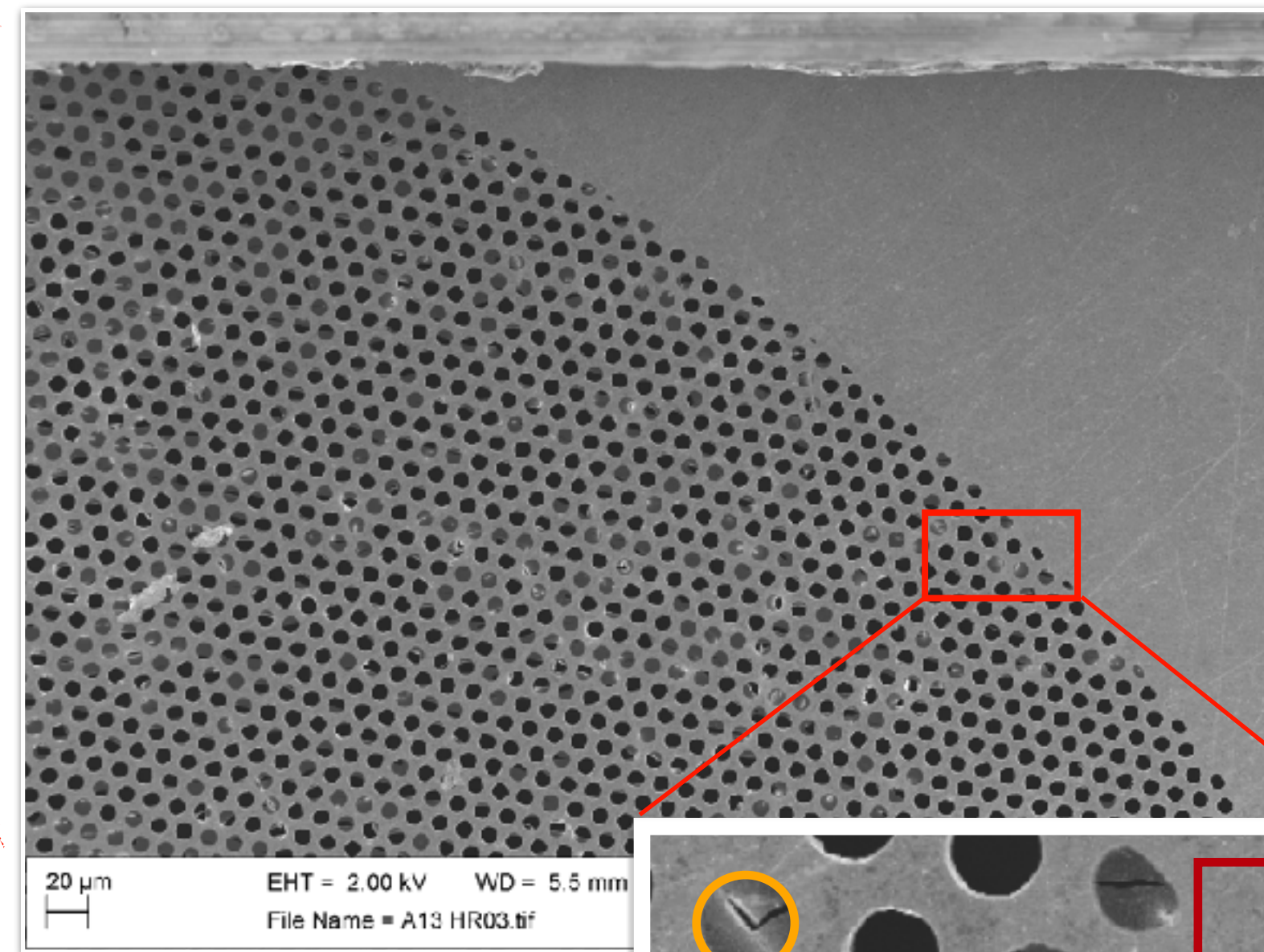
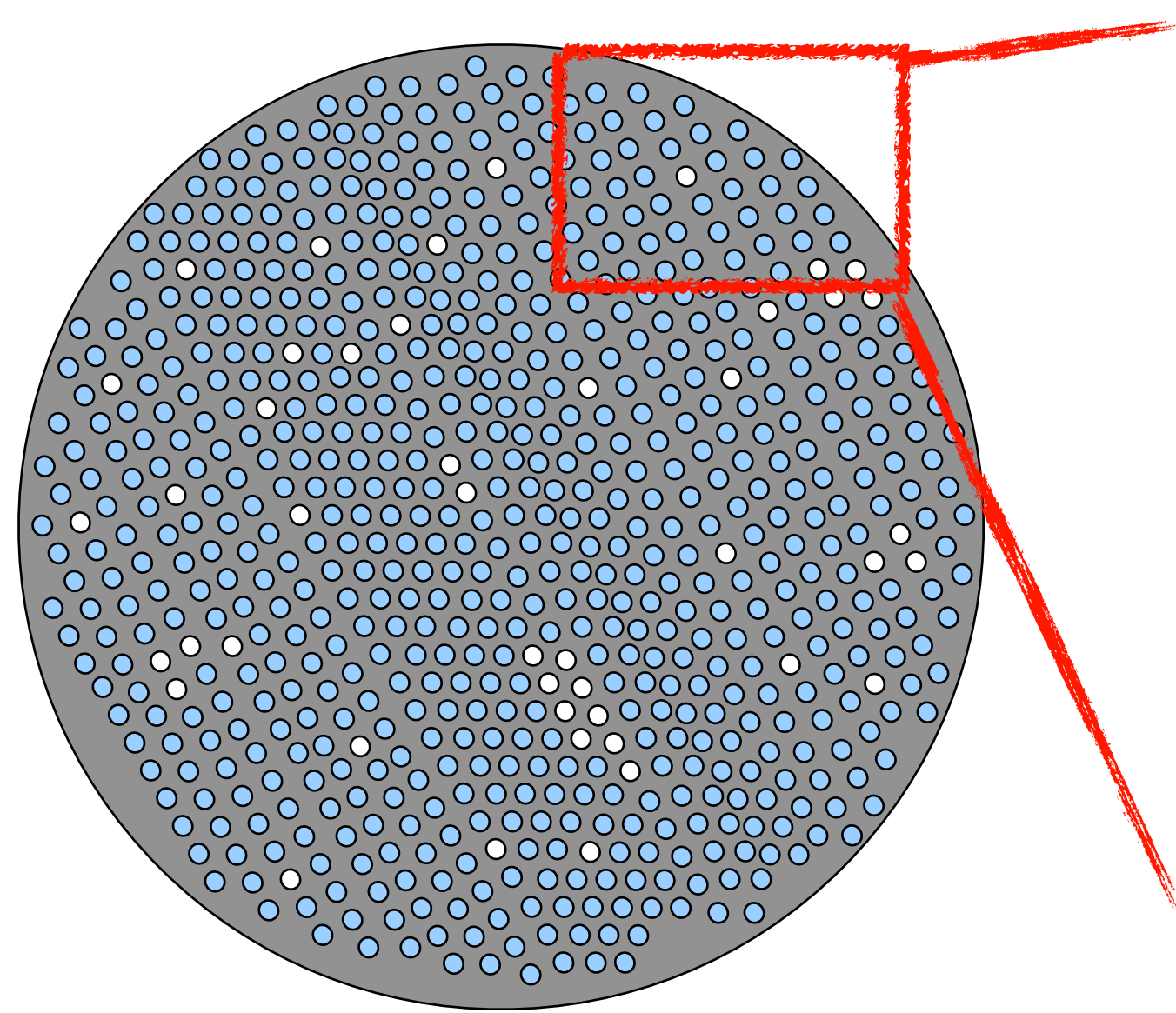


Pixel gray level histogram

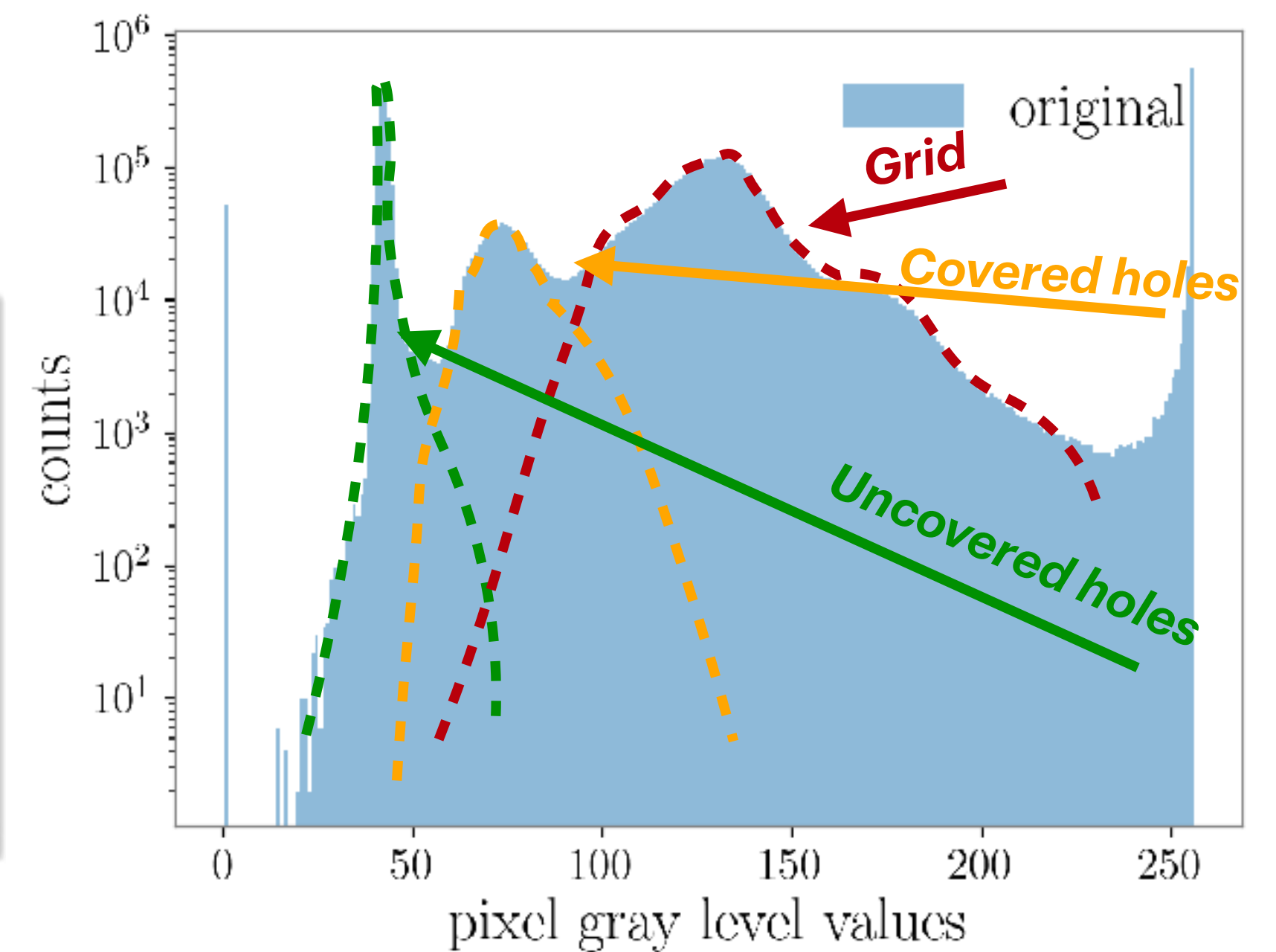


$$T_{geom} = \frac{A_{hole}}{A_{cell}}$$

SAMPLE CHARACTERIZATION @SEM



Pixel gray level histogram

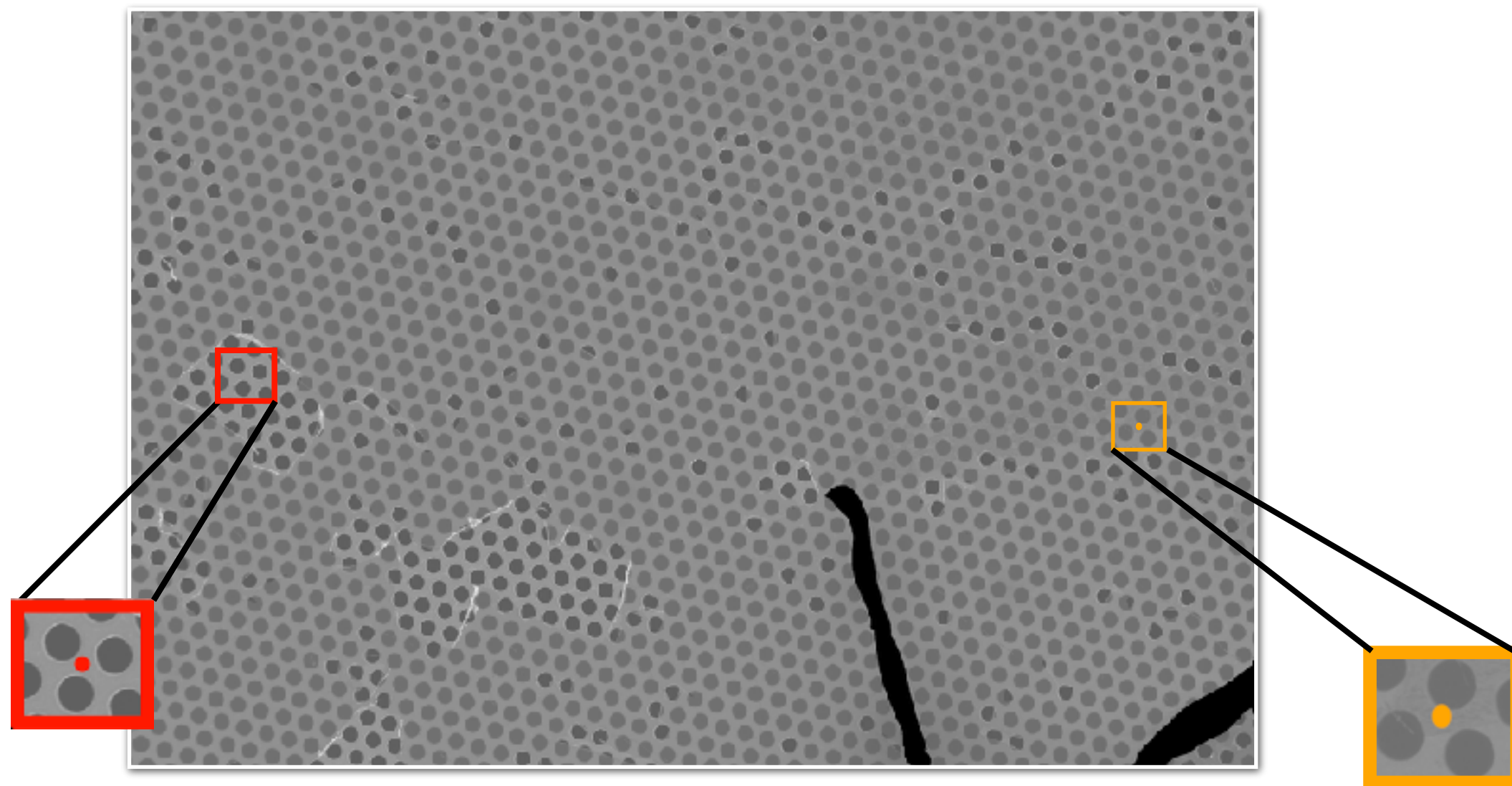


$$T_{geom} = \frac{A_{hole}}{A_{cell}}$$

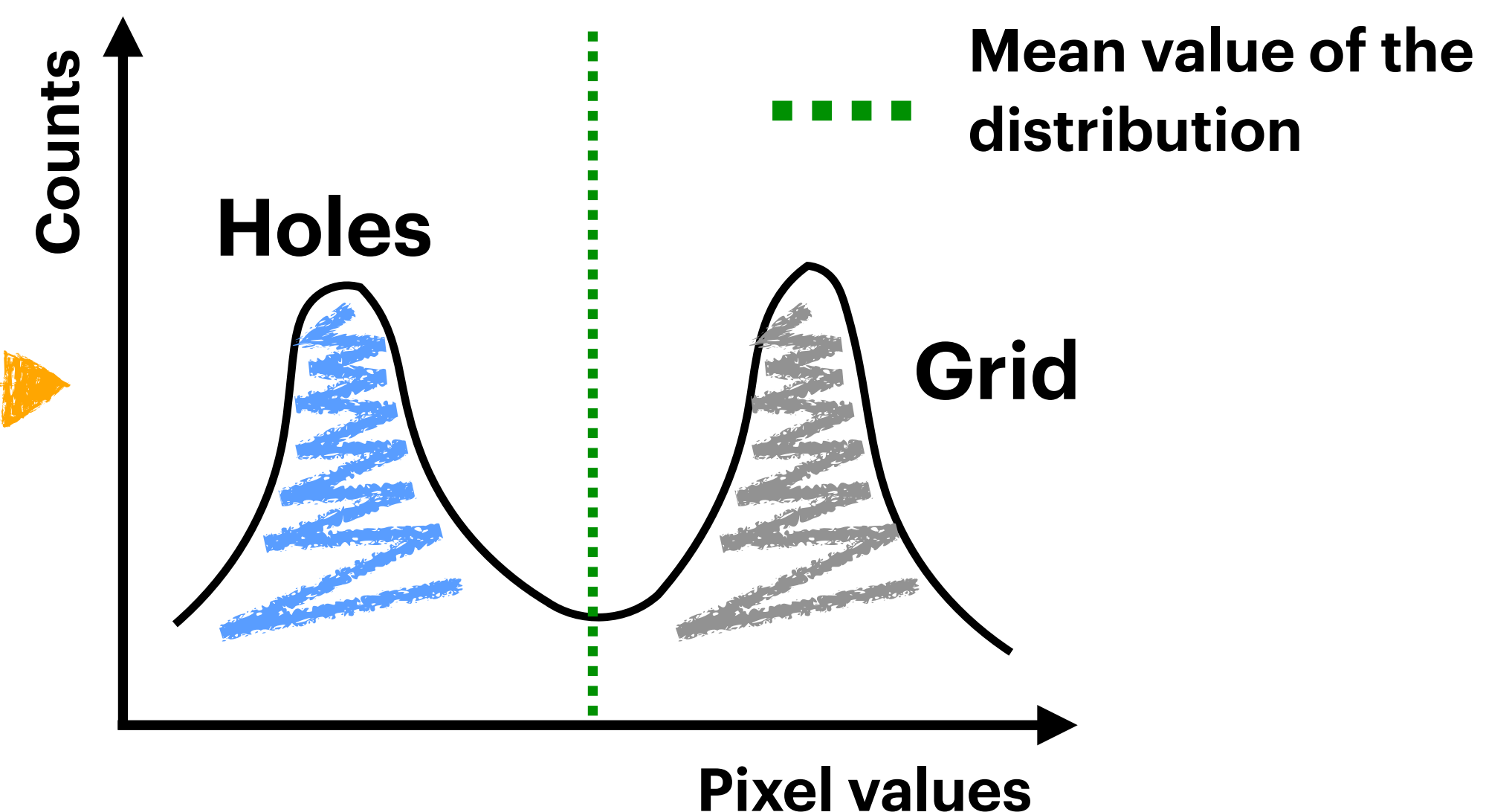
$$C = \frac{\sum covered}{\sum holes}$$

CREATE A MASK TO EXTRACT HOLES

- Cut labels and corrupted parts



Pixel gray level histogram **inside the box**

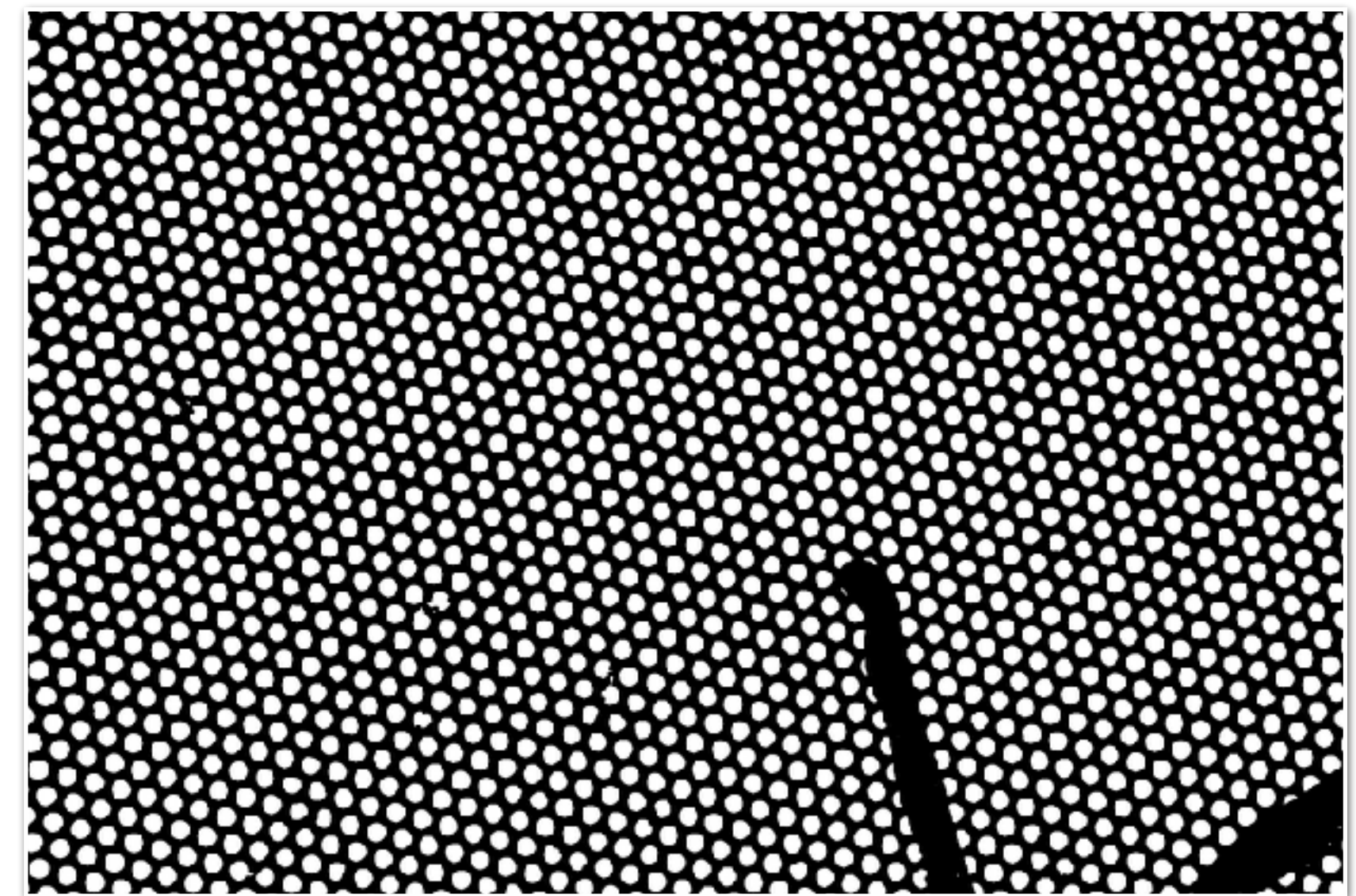
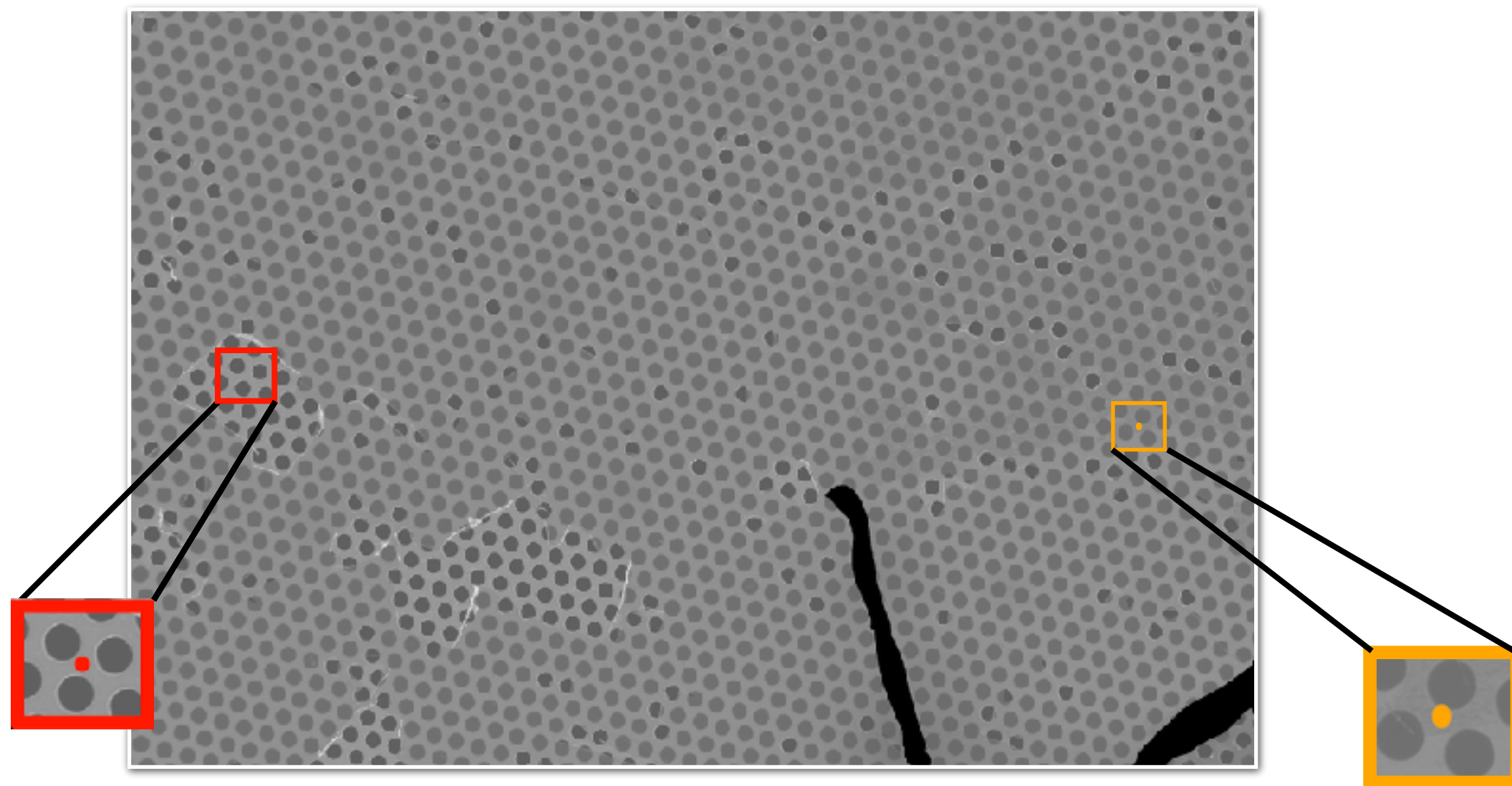


- Choose threshold pixel by pixel (*Adaptive threshold*):
mean inside the box + **offset**

Actually the best choice depends on whether you are considering covered or uncovered places of the grid

CREATE A MASK TO EXTRACT HOLES

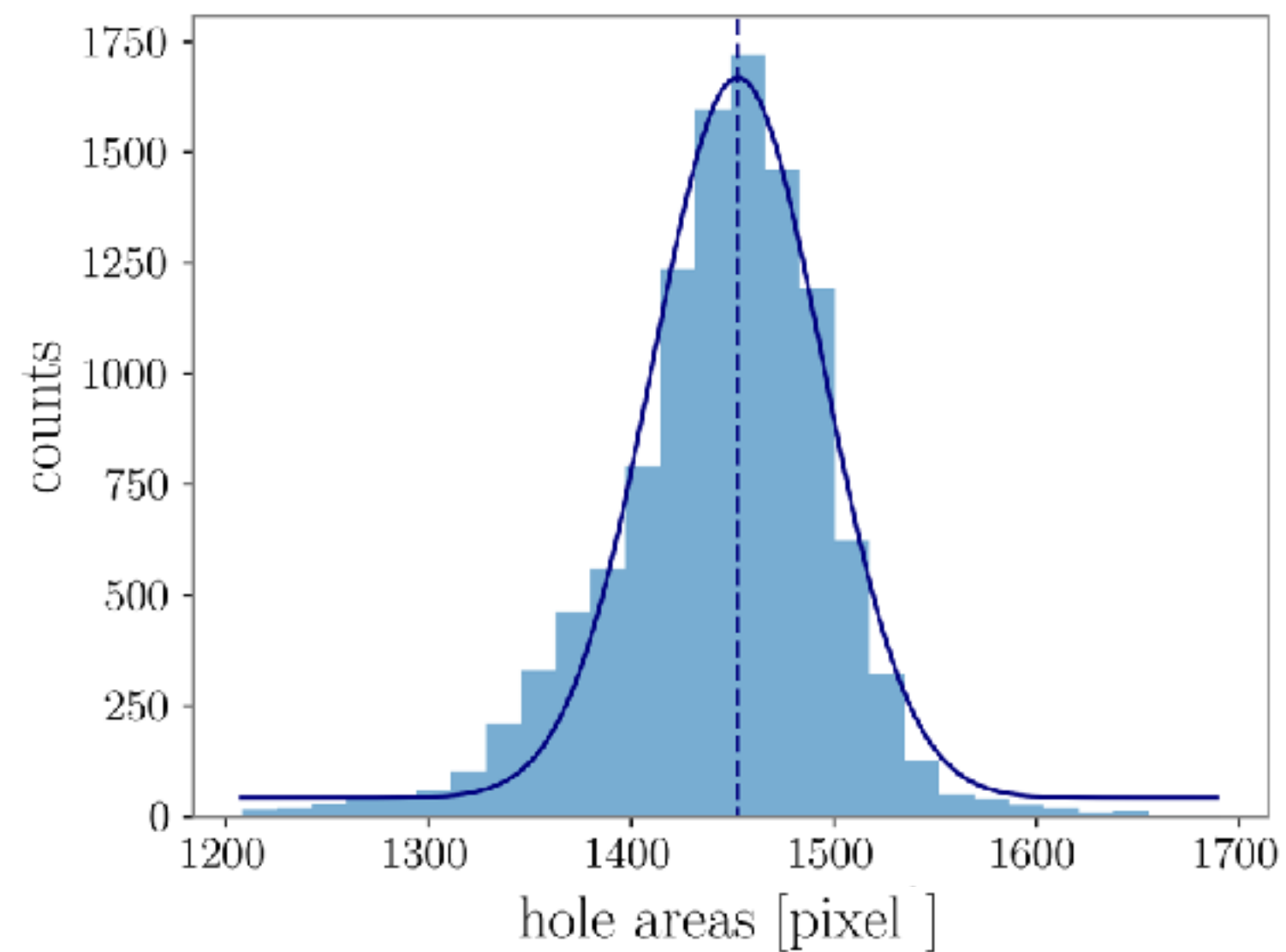
- Cut labels and corrupted parts



- Choose threshold pixel by pixel (*Adaptive threshold*):
mean inside the box + **offset**

- Select *good* holes:
 - size $\in [1100, 1700] \text{ pixel}^2$
 - circularity $\in [0.92, 1.00]$

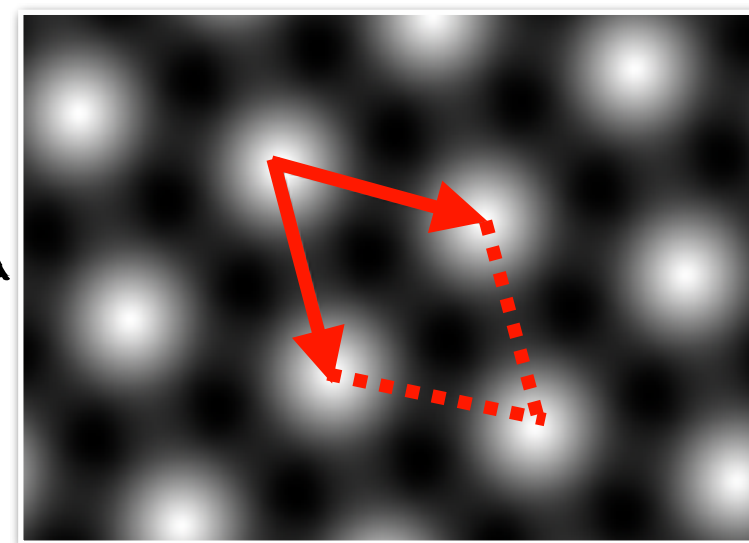
HOLE AREAS FOR GEOMETRIC TRANSMISSION



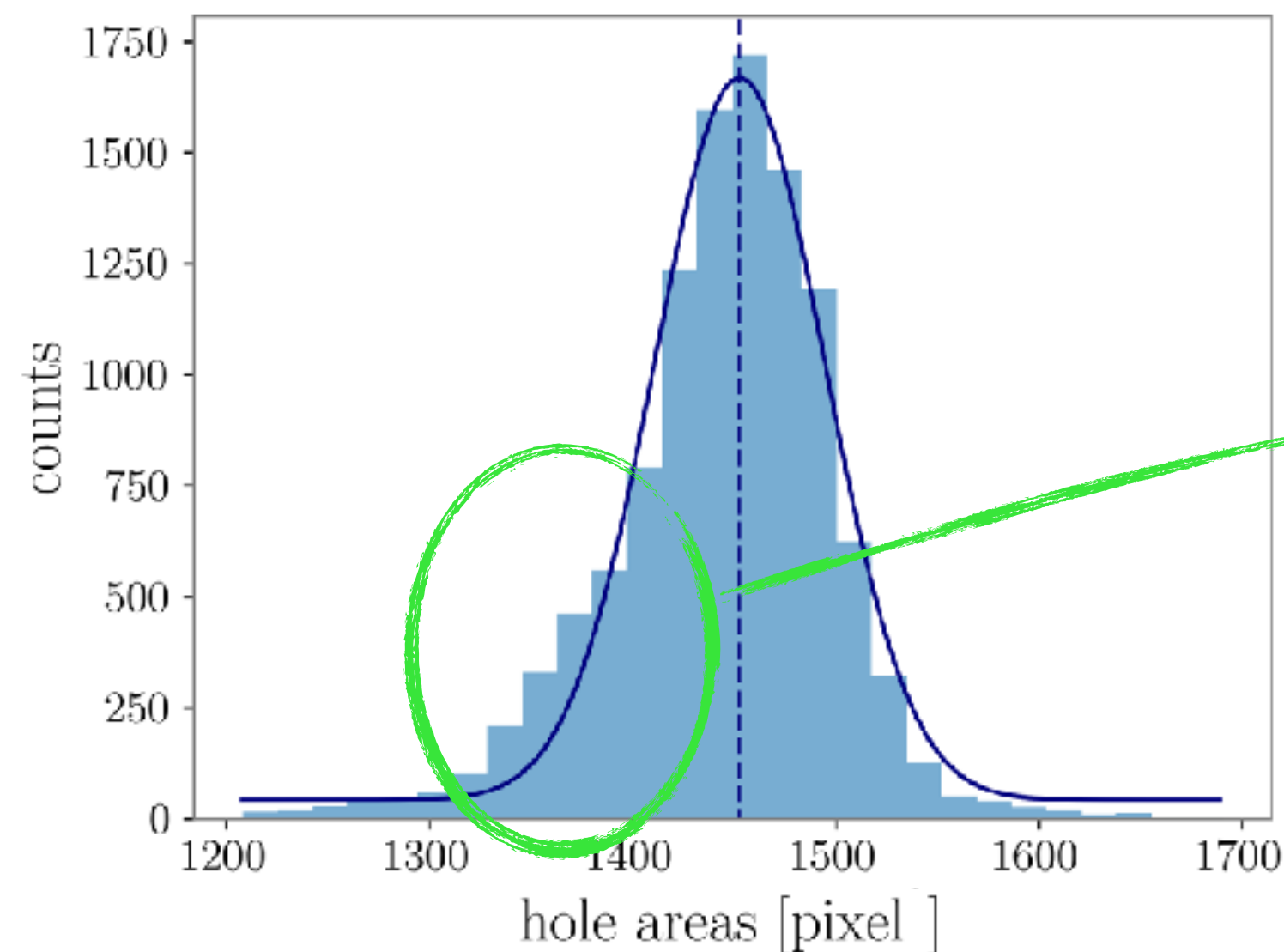
$$\bar{A} = (1452 \pm 7) \text{ pixel}$$

$$A_{cell} = (3473 \pm 3) \text{ pixel}$$

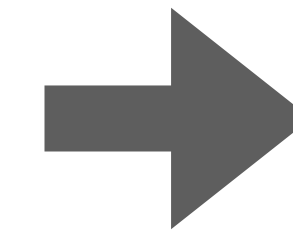
Autocorrelation spectrum:



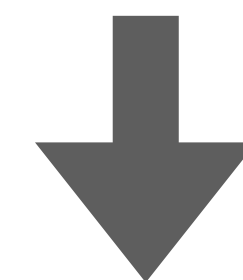
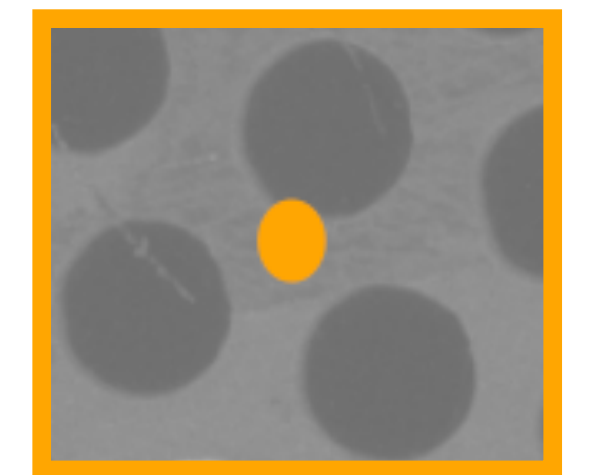
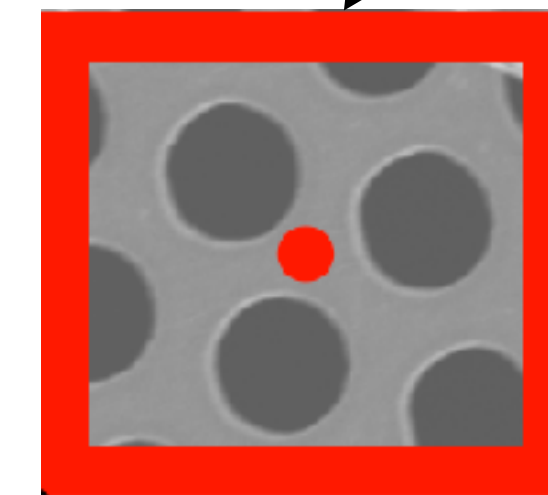
HOLE AREAS FOR GEOMETRIC TRANSMISSION



This histogram contains **two populations** of areas, one for the covered holes and one for the uncovered. It is an artifact of the thresholding prescription we are using



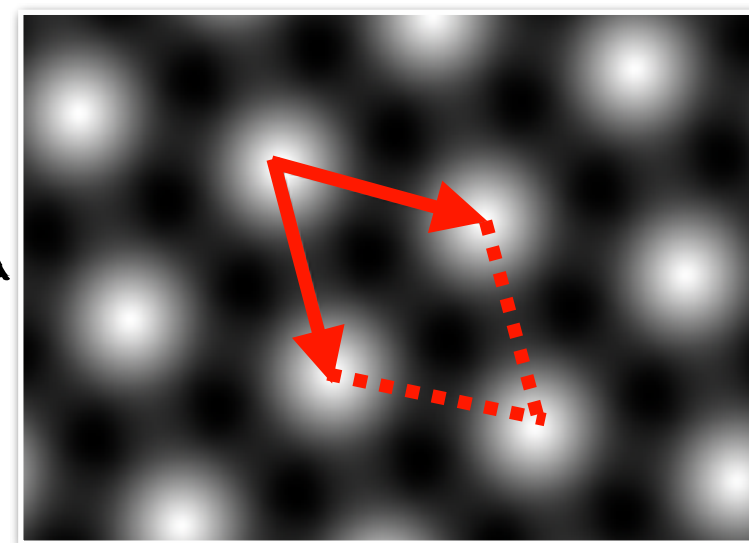
Different gradients at the borders



$$\bar{A} = (1452 \pm 7) \text{ pixel}$$

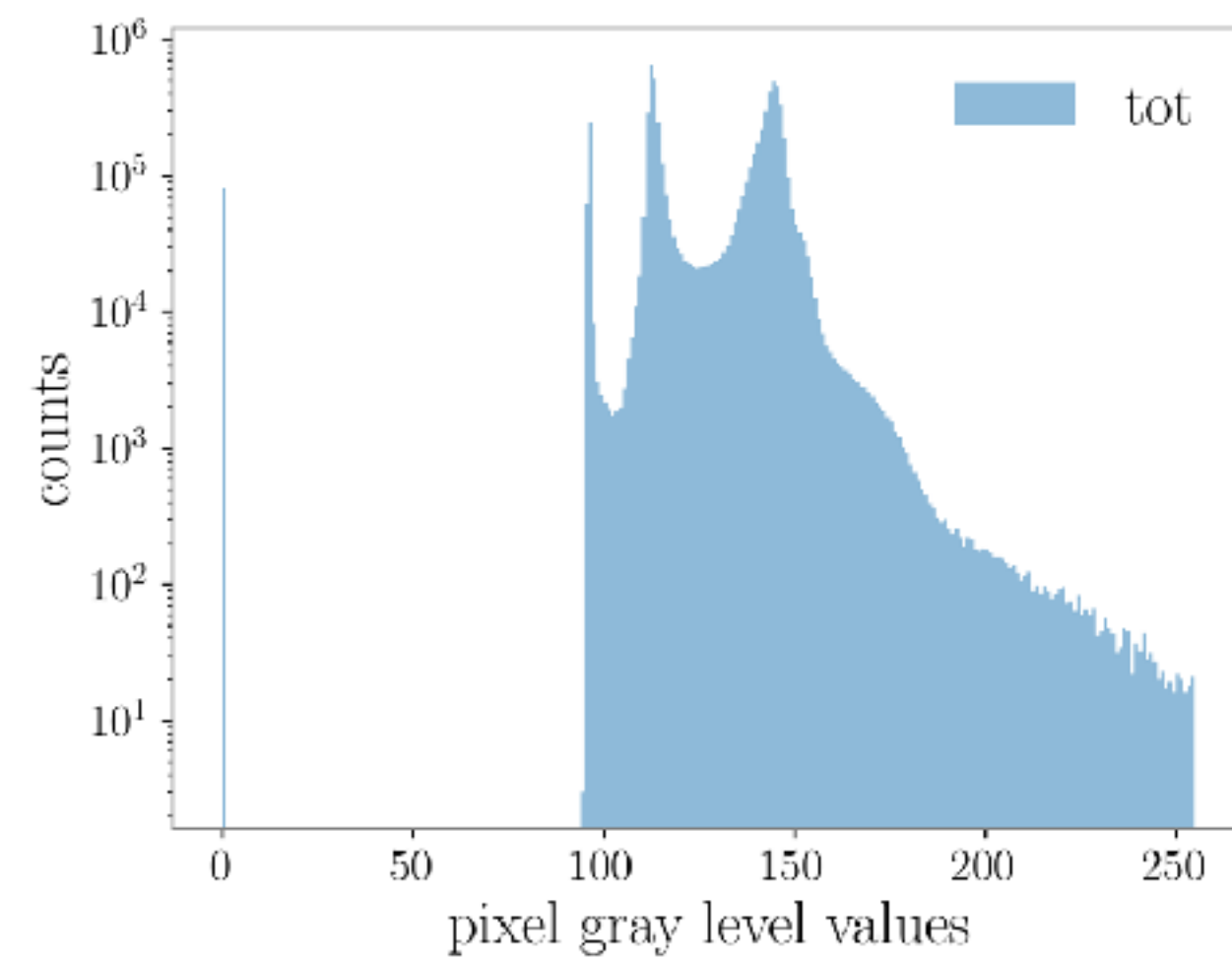
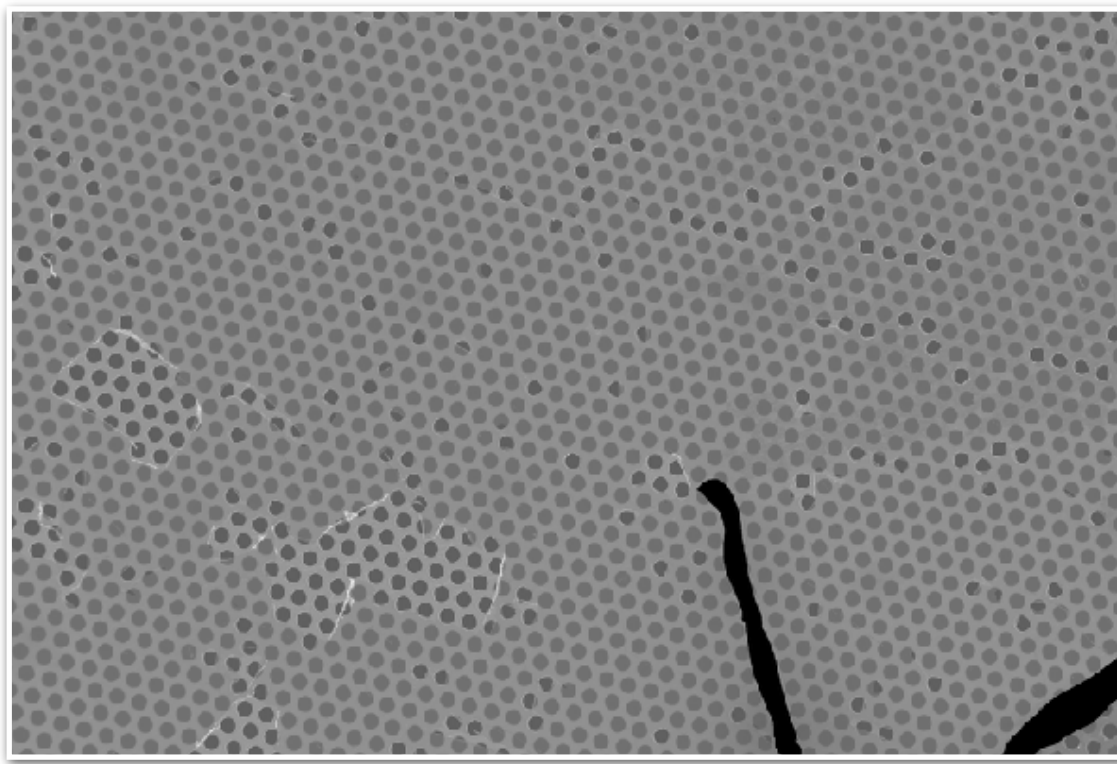
$$A_{cell} = (3473 \pm 3) \text{ pixel}$$

Autocorrelation spectrum:

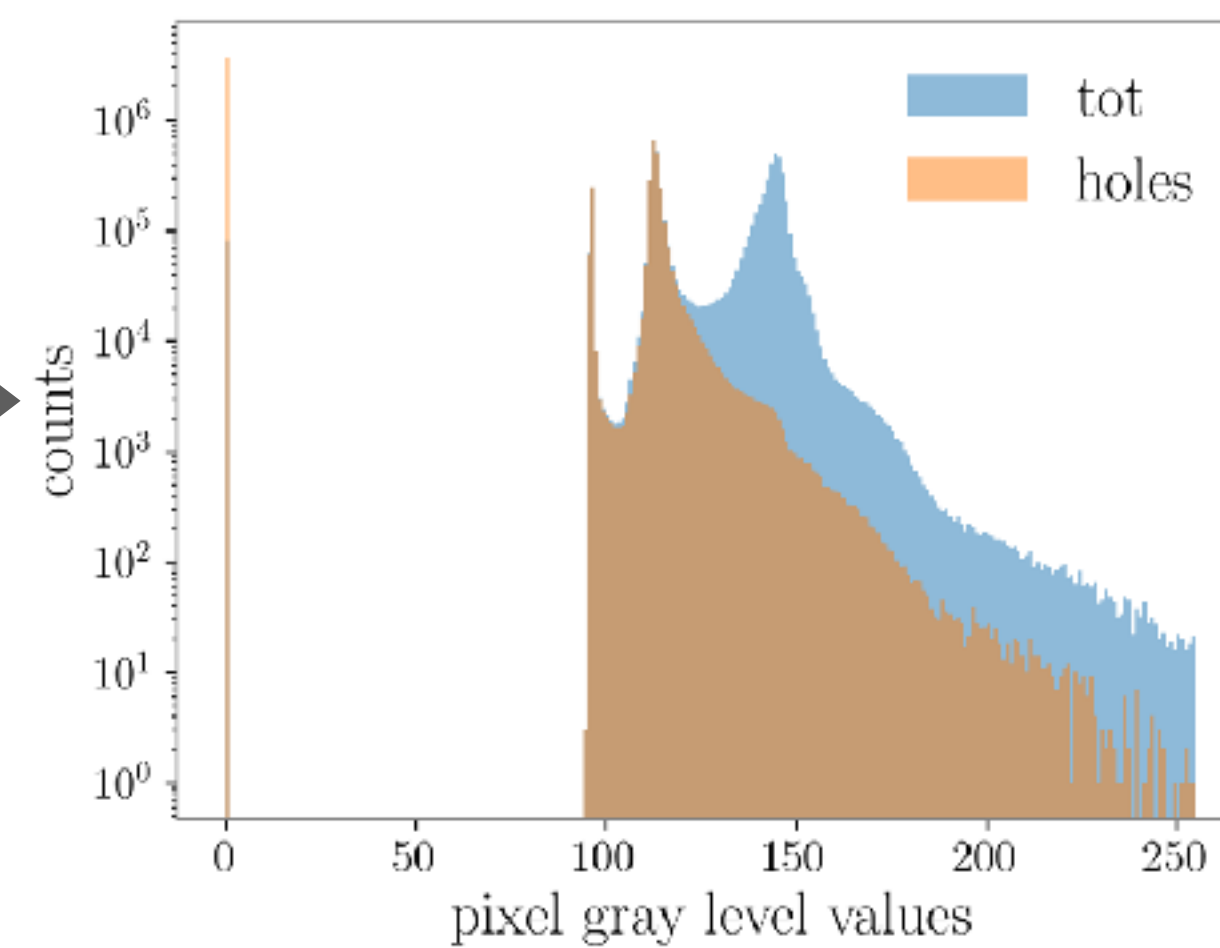
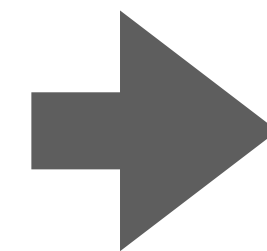
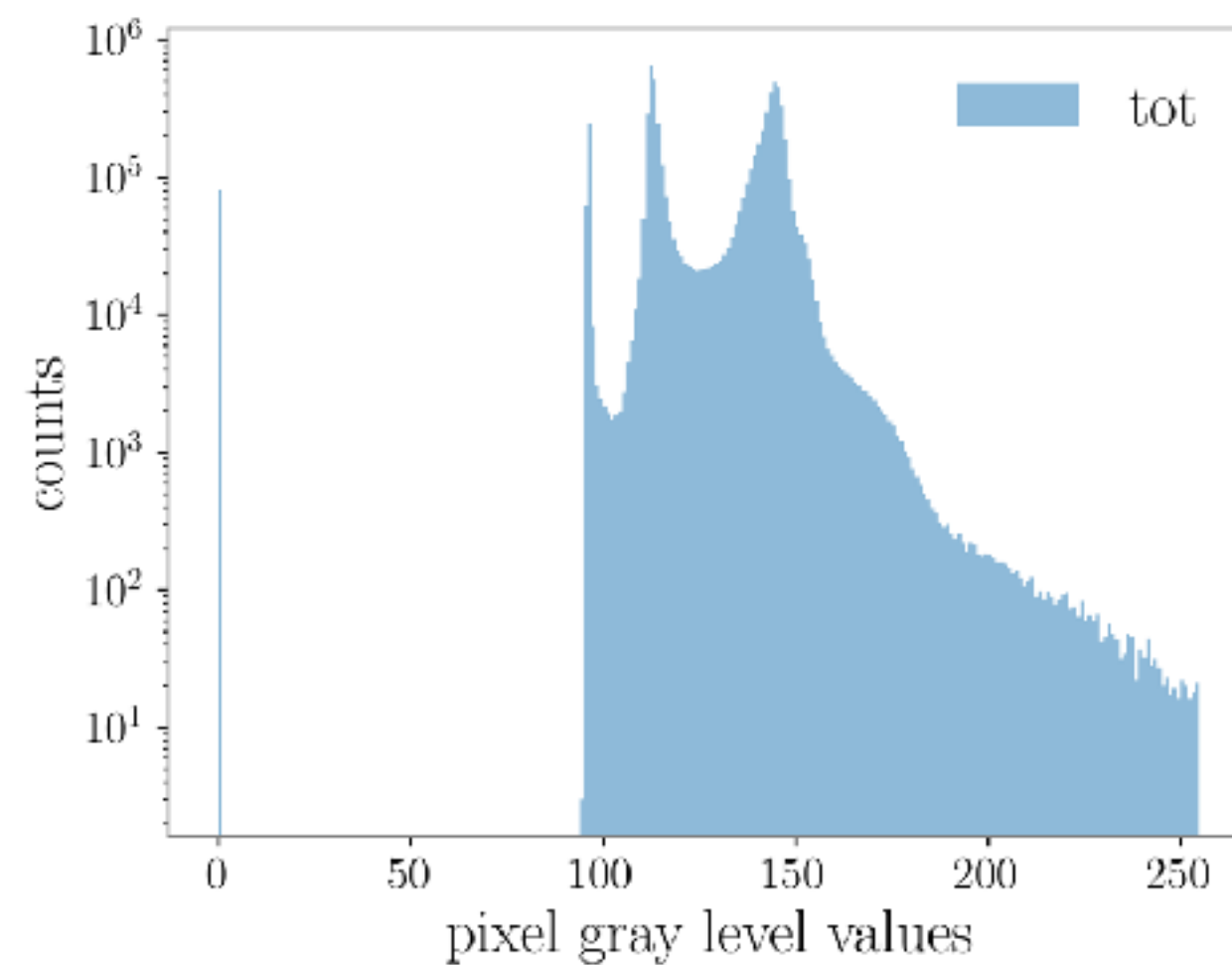
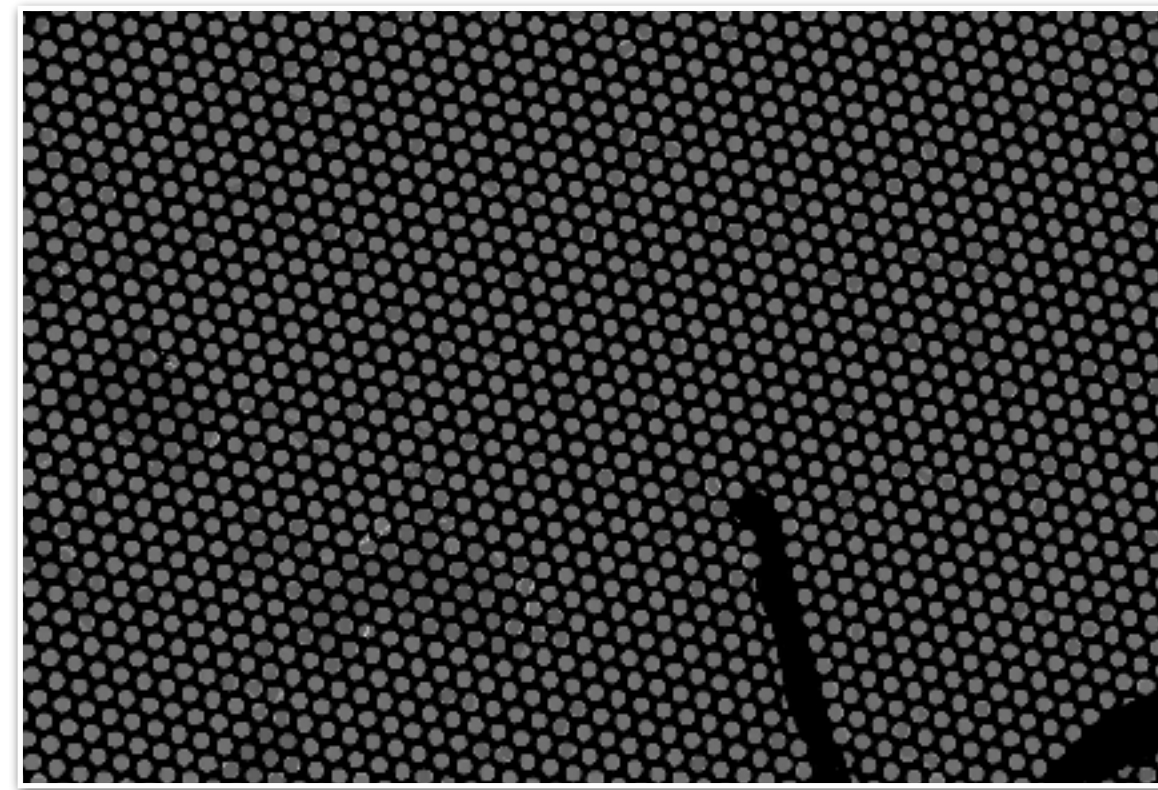
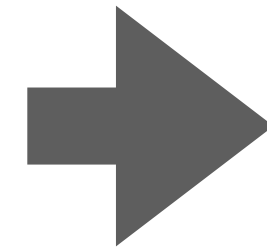
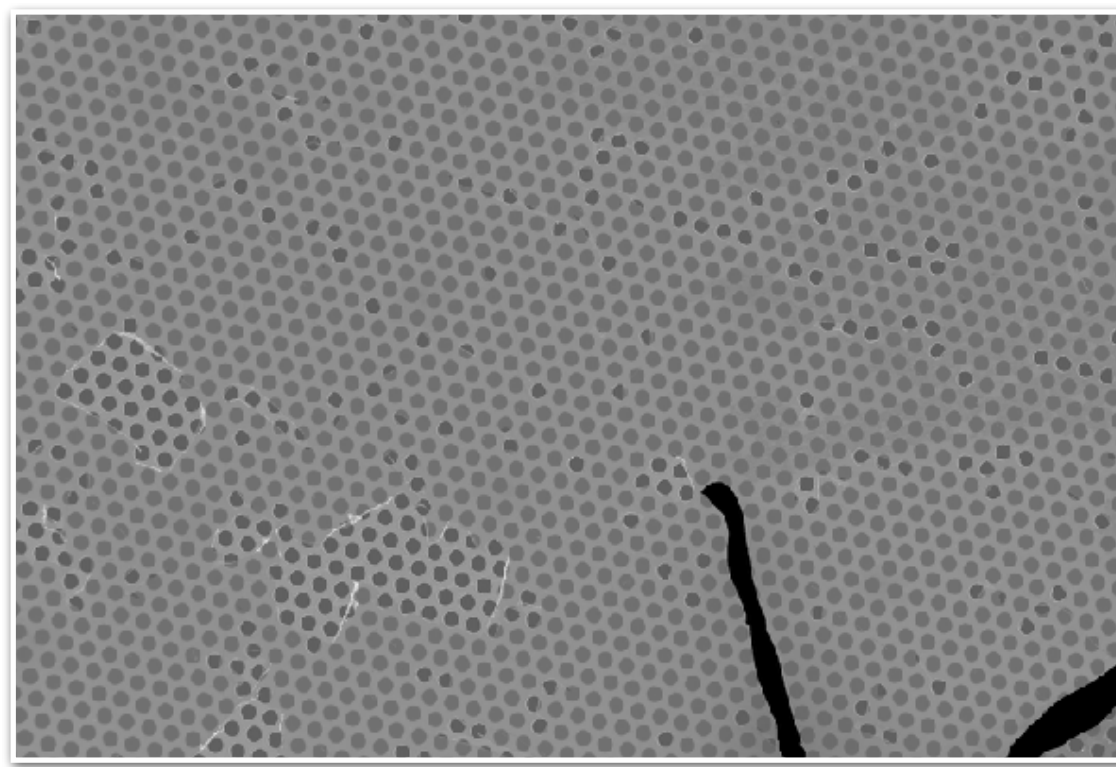


$$T_{geom} = (42.0 \pm 1.6) \%$$

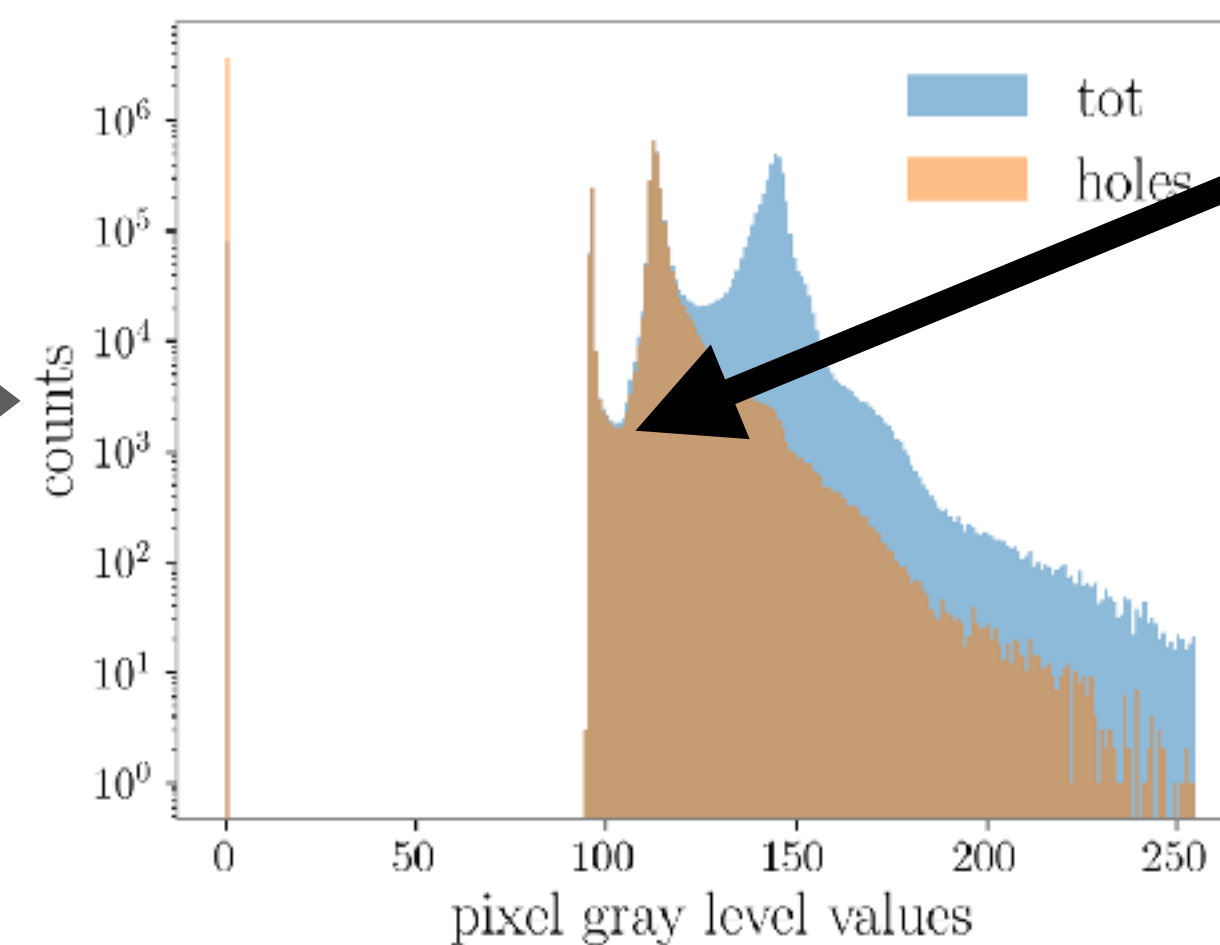
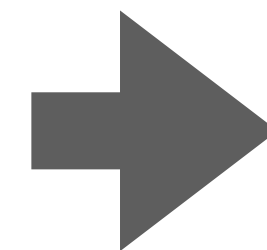
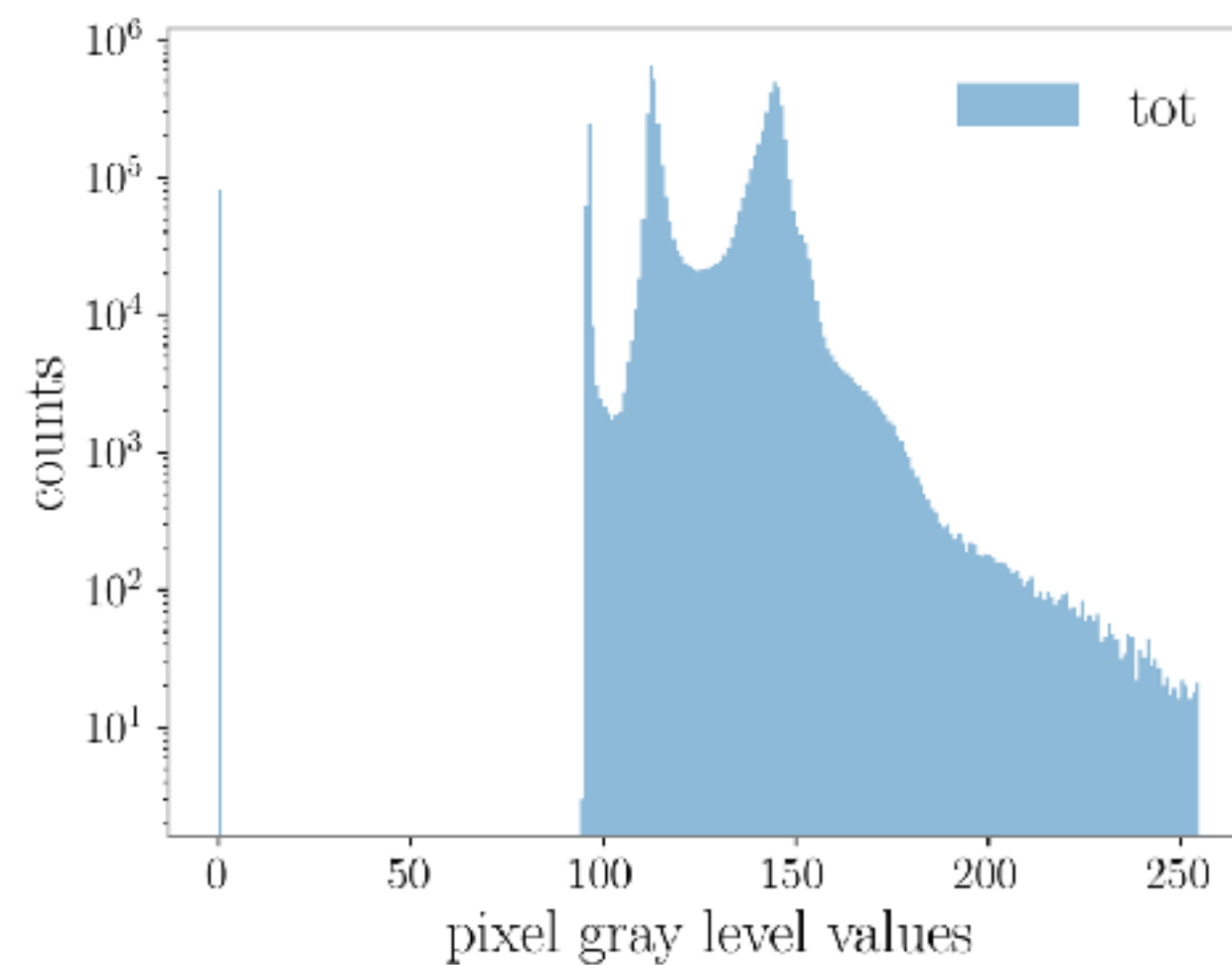
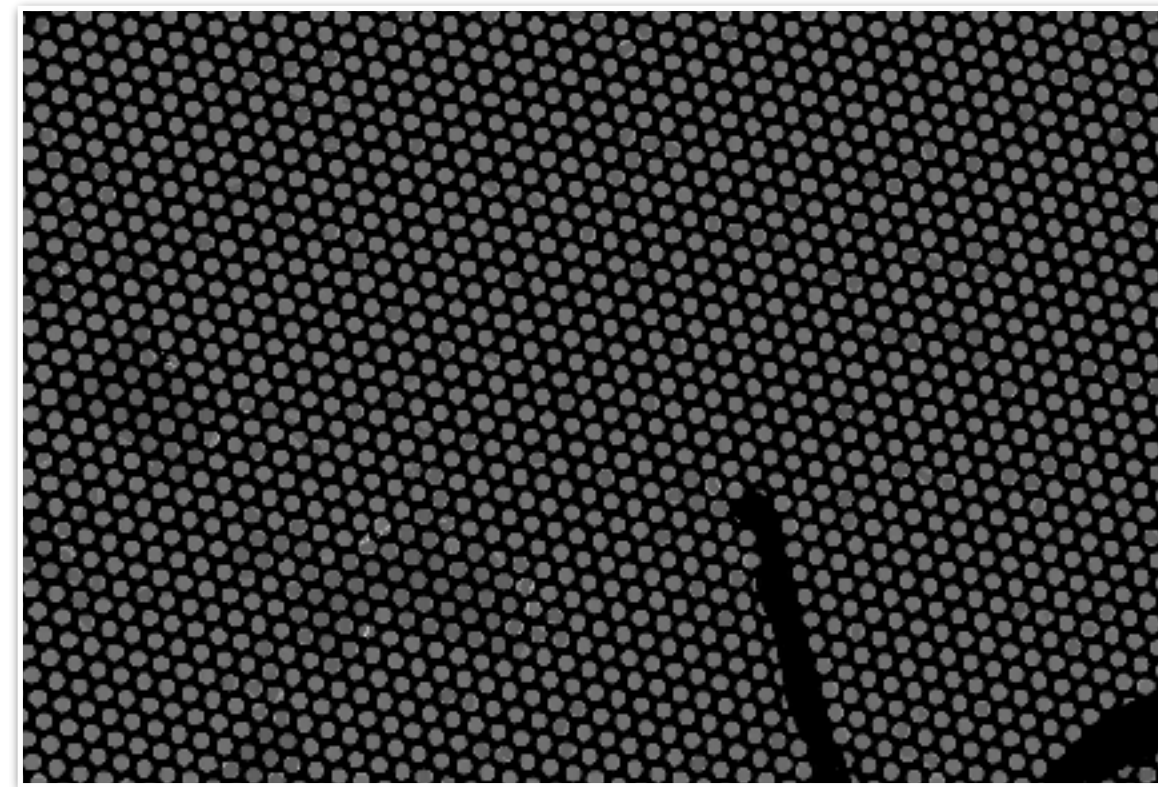
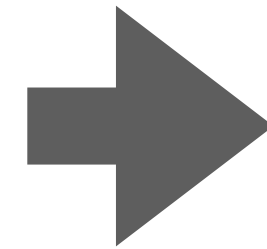
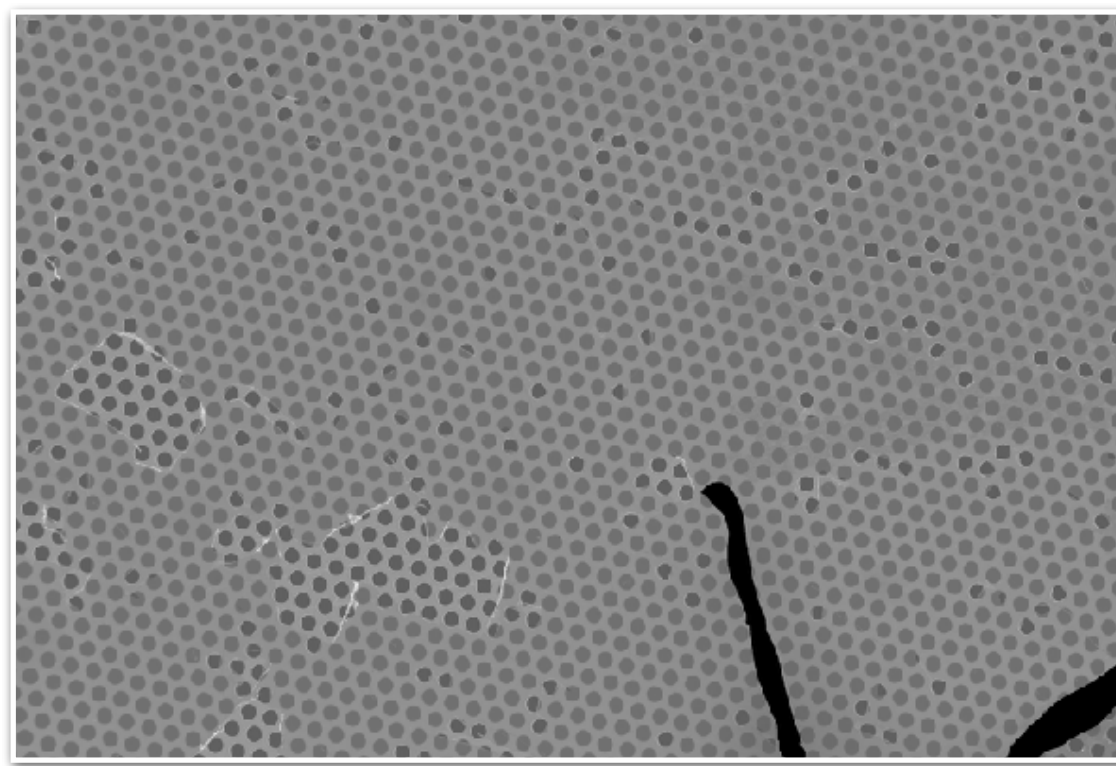
GRAPHENE IDENTIFICATION



GRAPHENE IDENTIFICATION

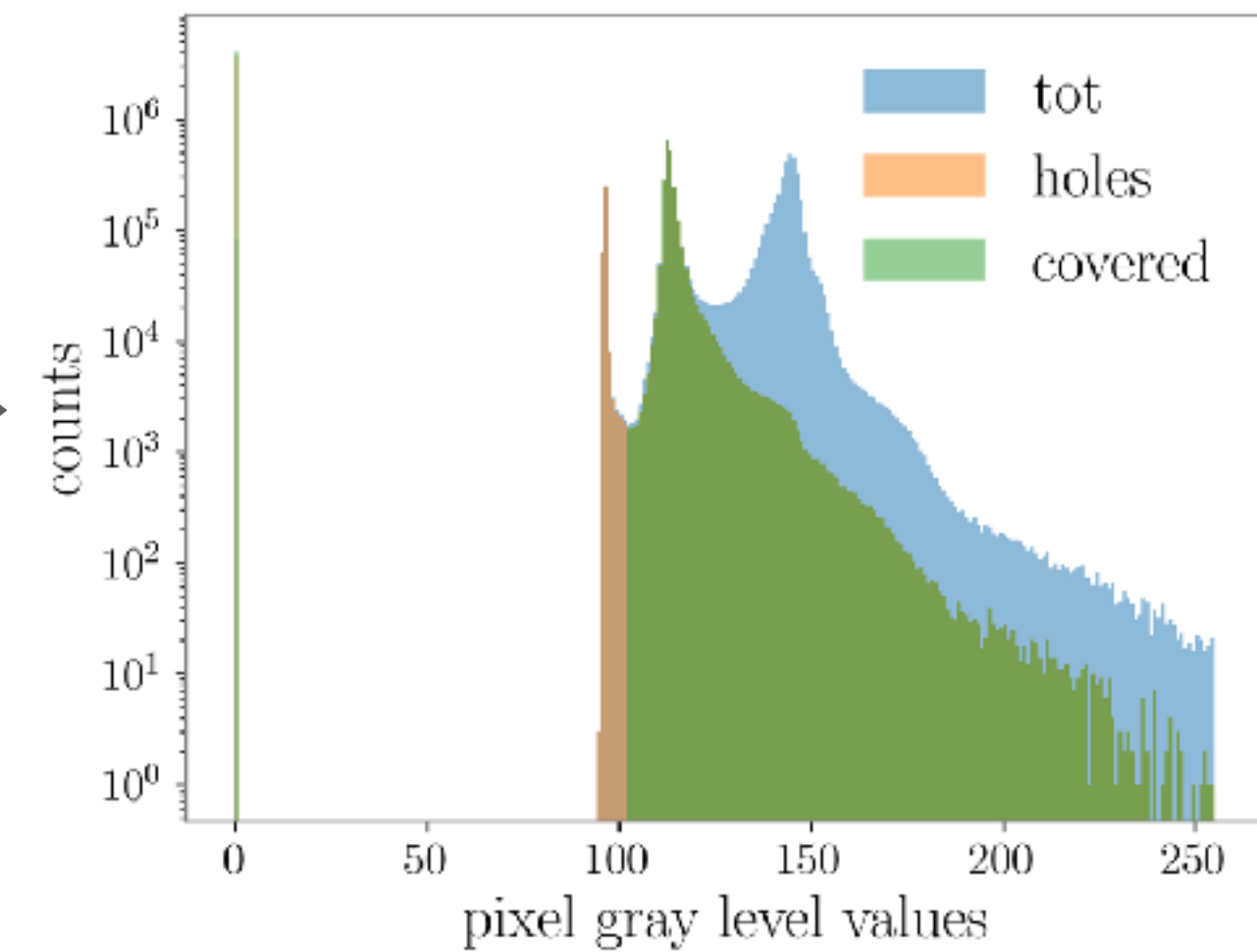
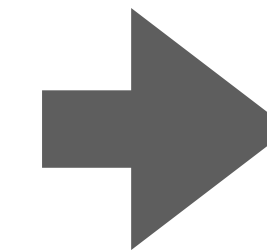
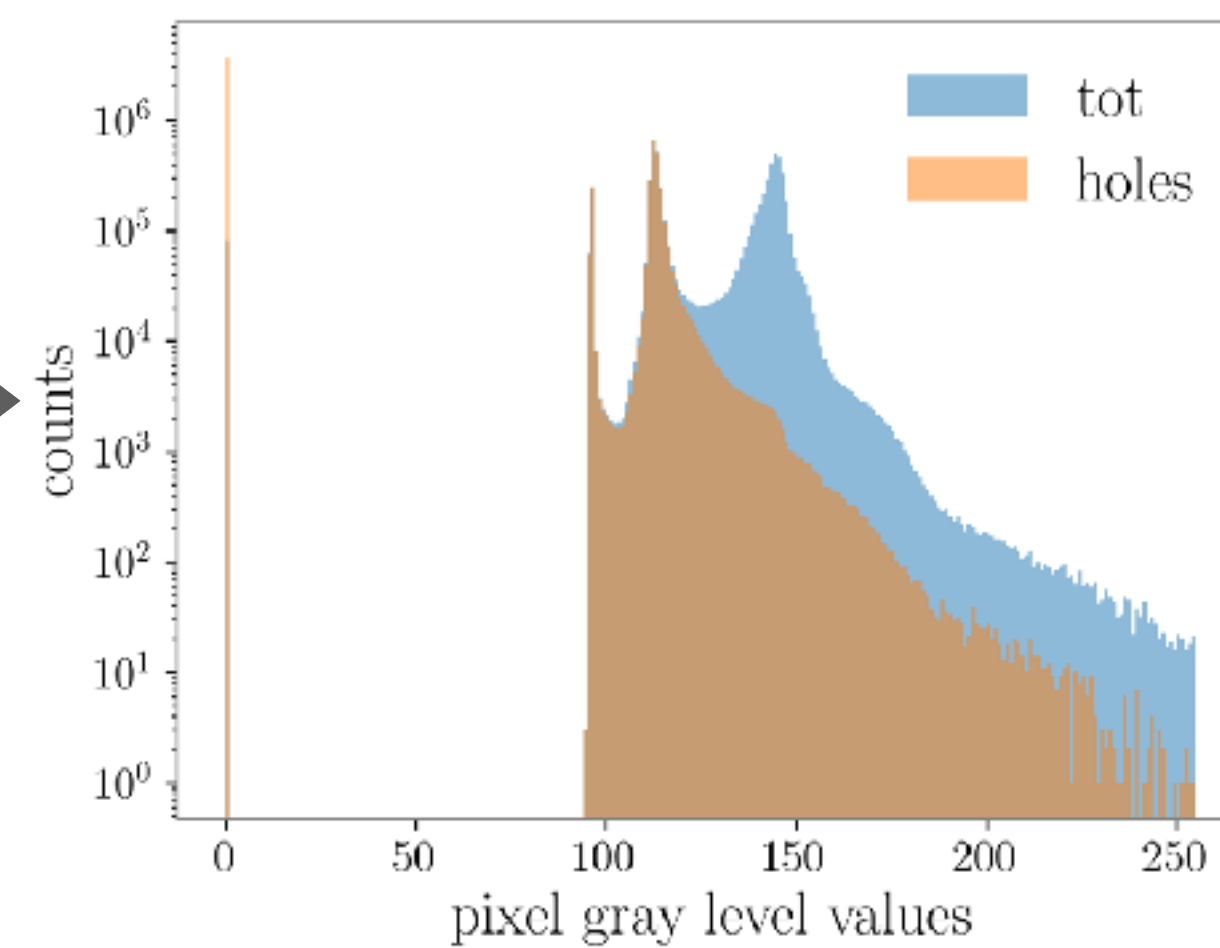
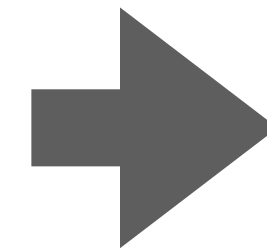
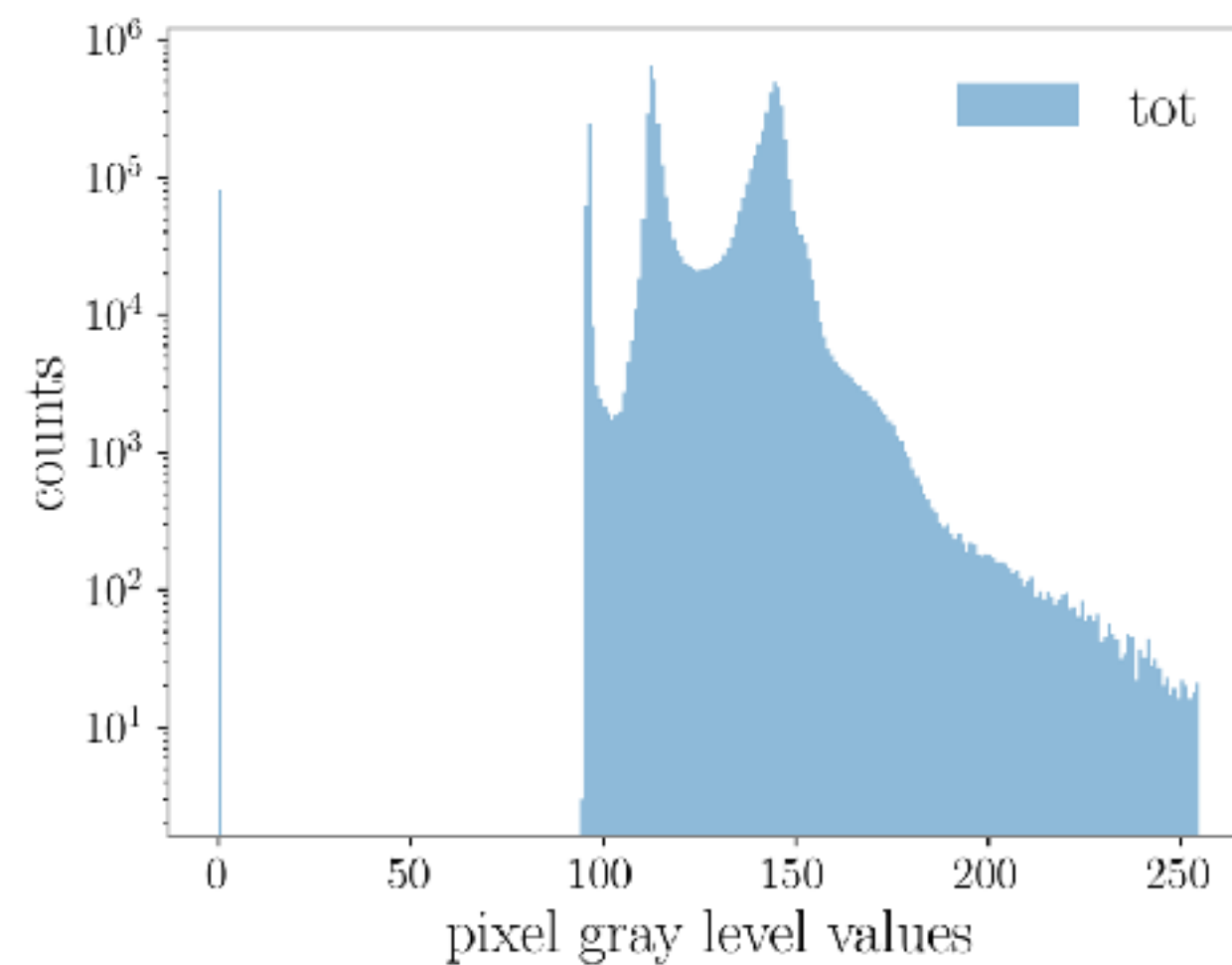
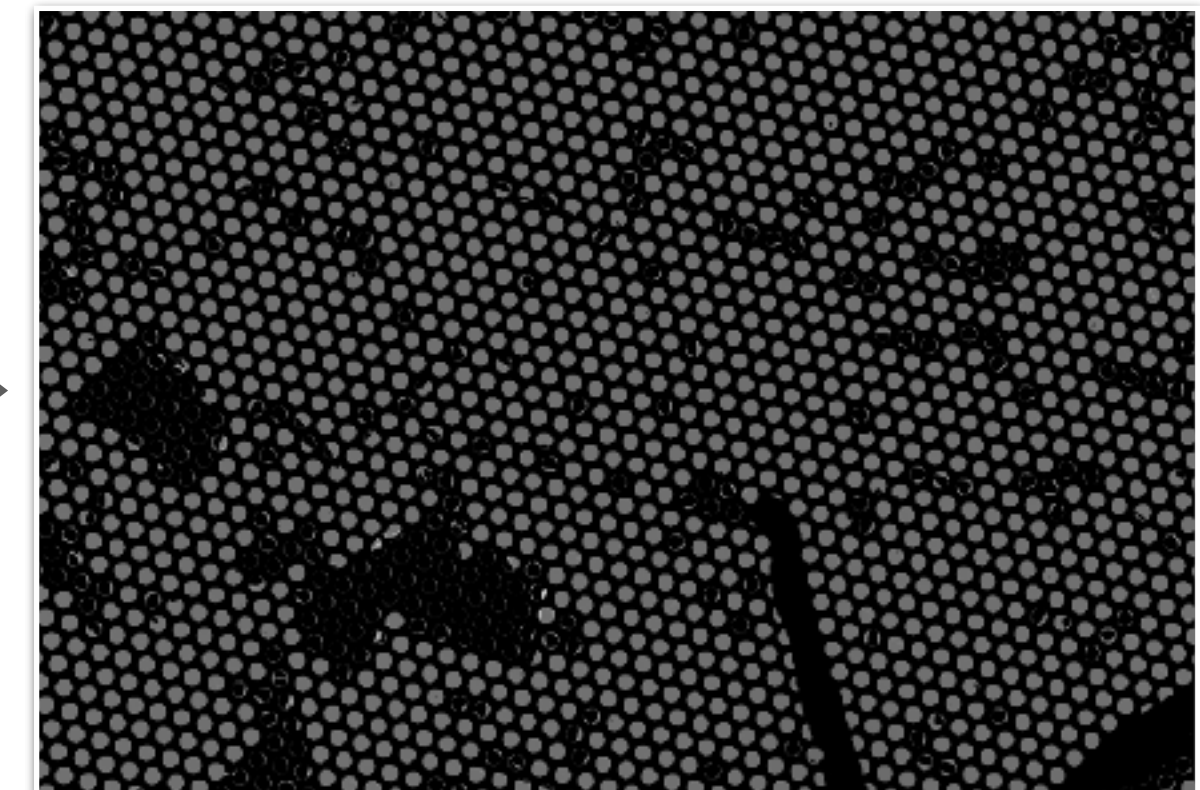
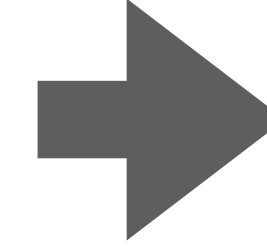
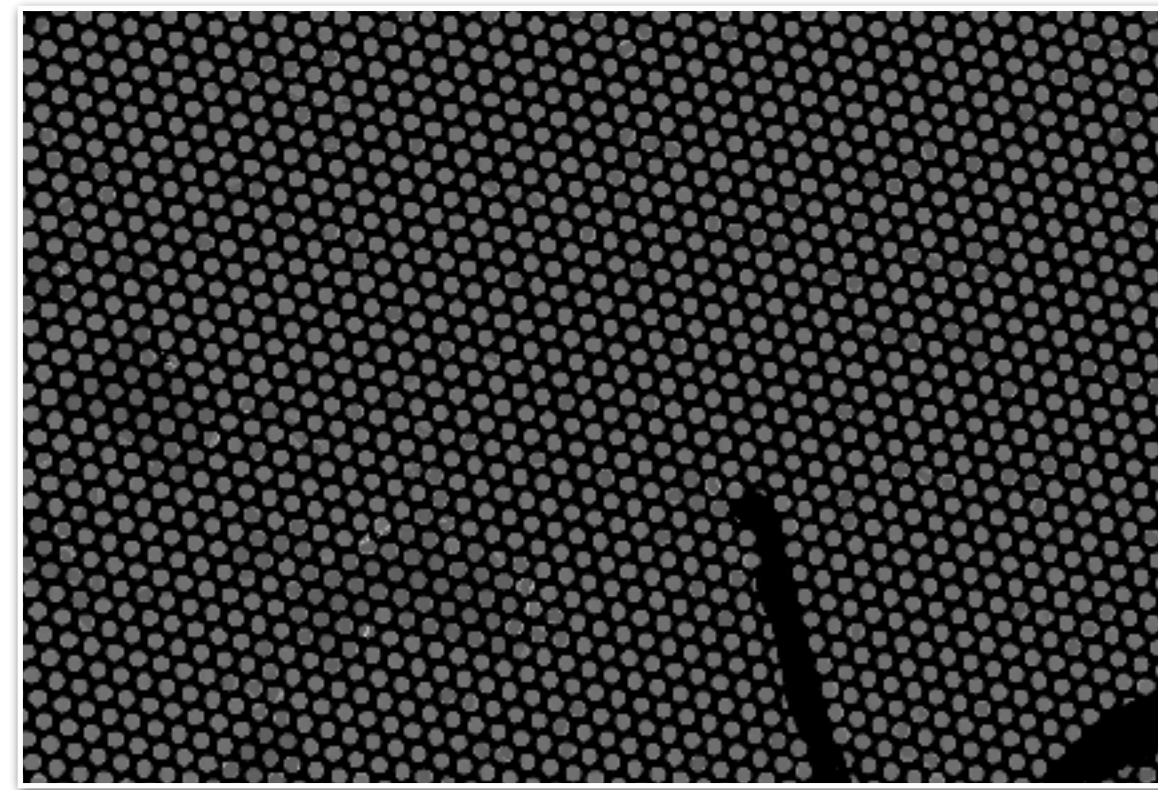
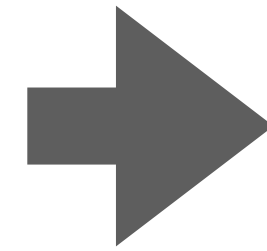
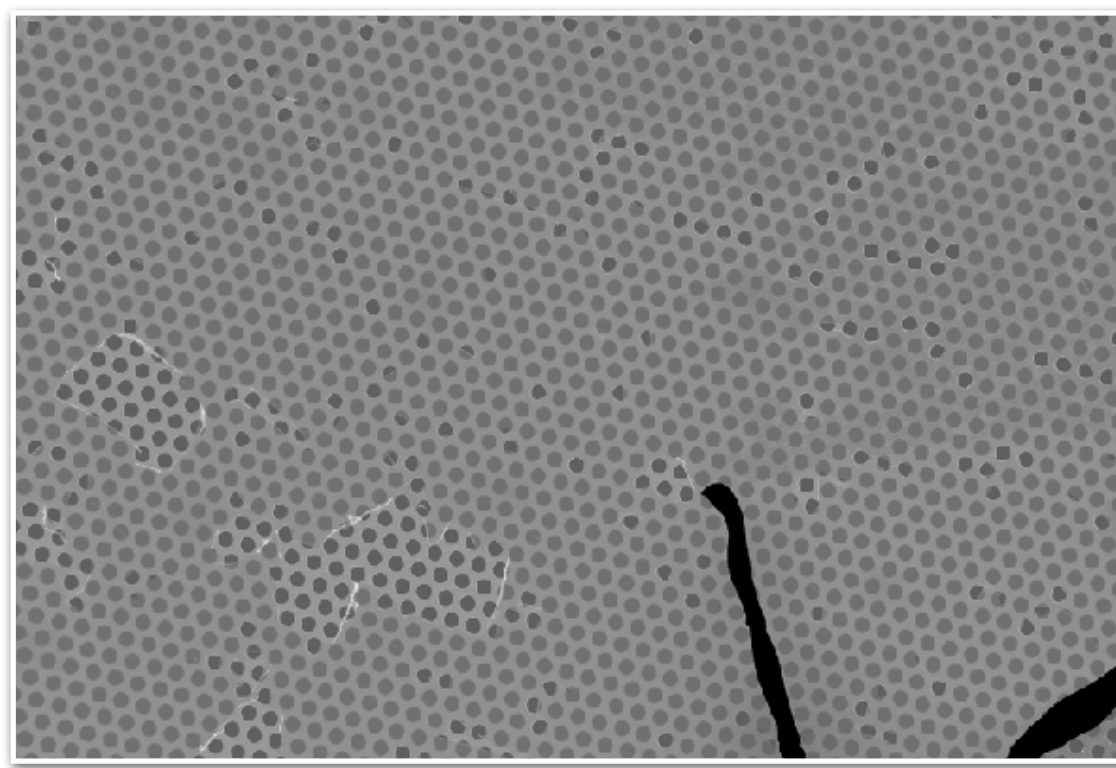


GRAPHENE IDENTIFICATION



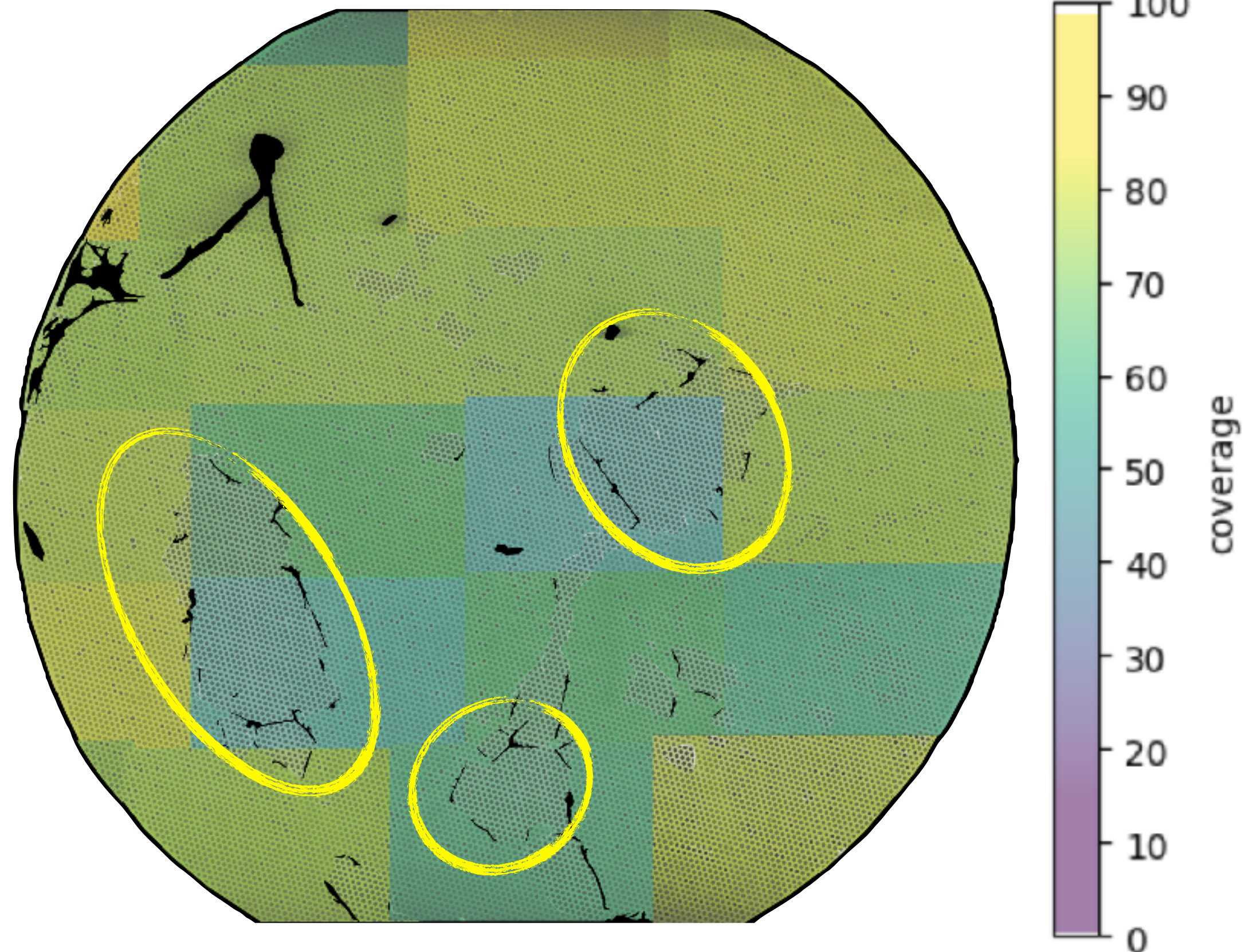
Compute minimum to separate covered and uncovered holes

GRAPHENE IDENTIFICATION

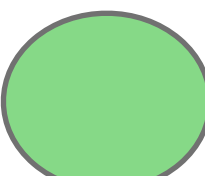


SAMPLE VISUALIZATIONS

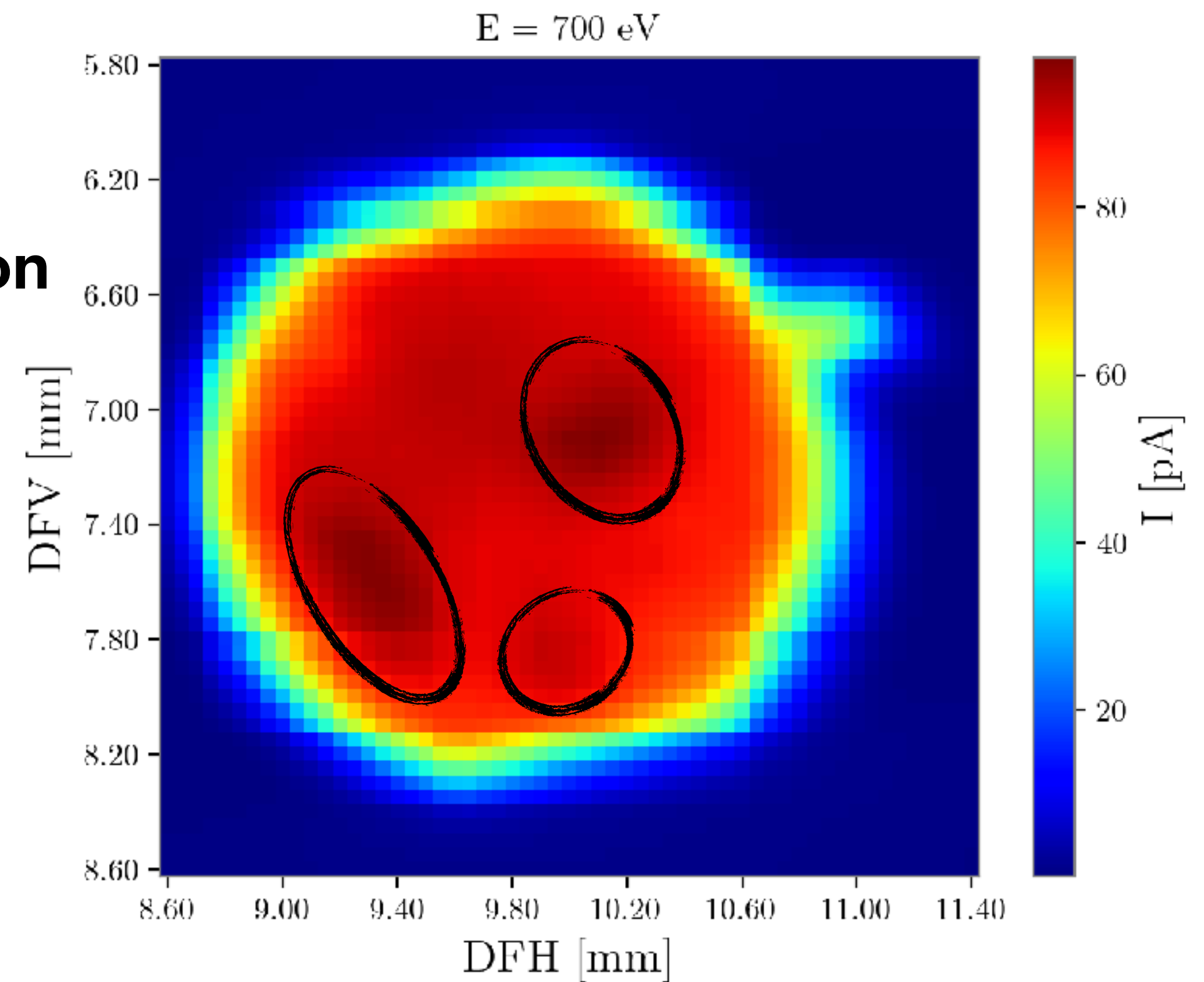
- SEM:



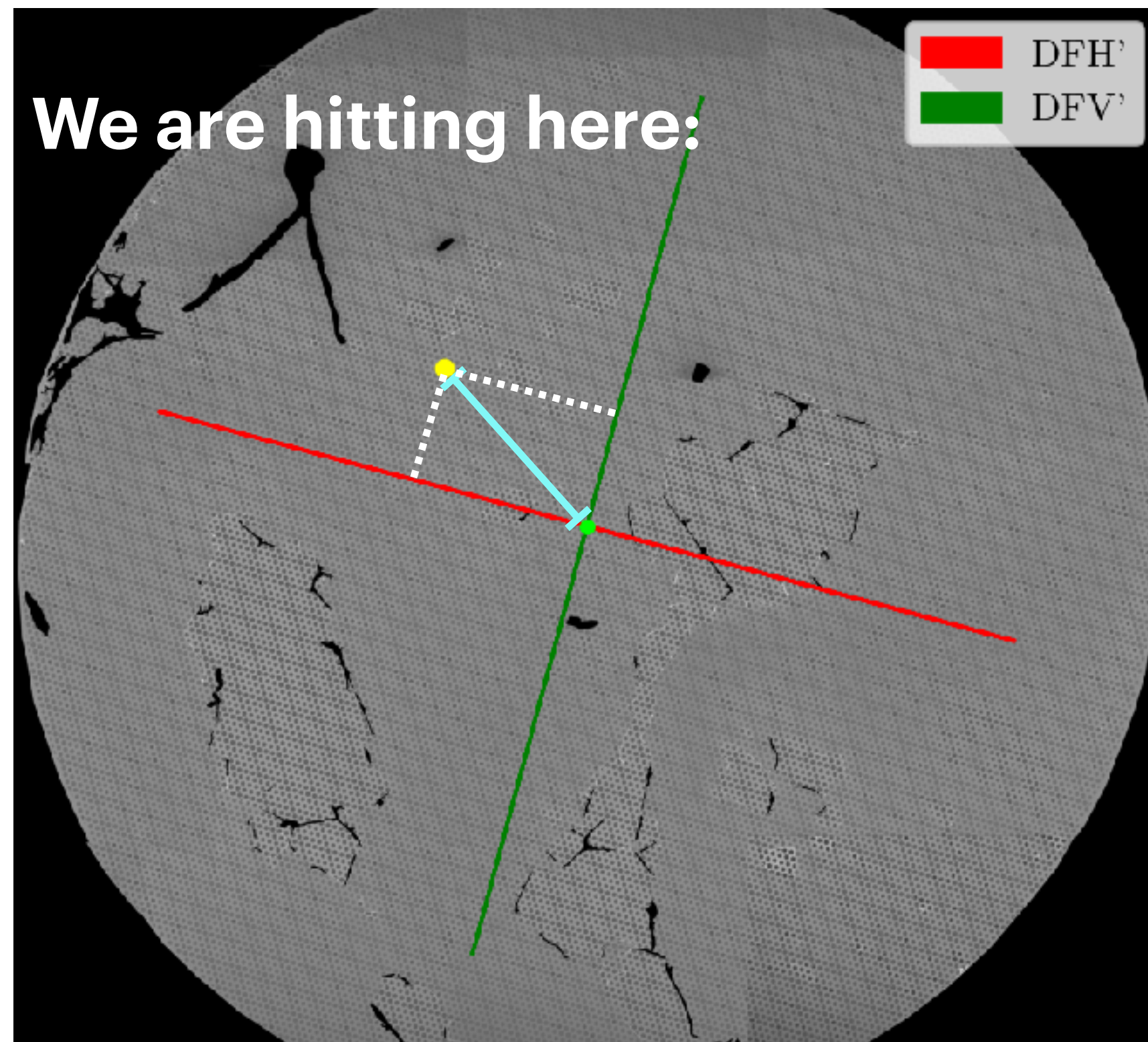
- Transmission map with our apparatus:


= electron
spot

Gun DeFlections ▼



TRANSMISSION “*AS PREPARED*”

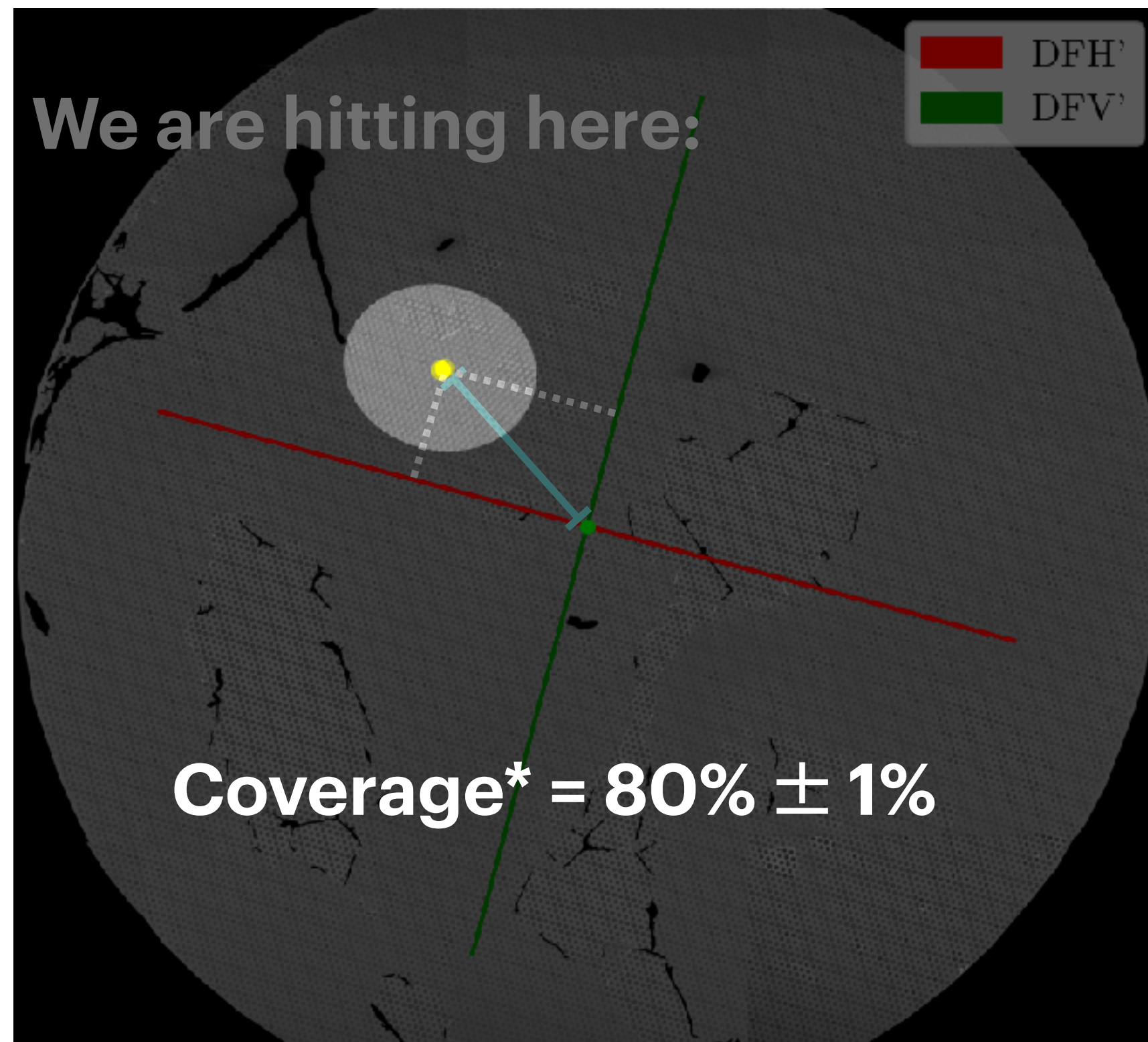


$$T_G = \frac{1}{a} \left(\frac{I_{meas}}{I_0 T_{grid}} - (1 - a) \right)$$

* *Sample as prepared* = graphene + PMMA

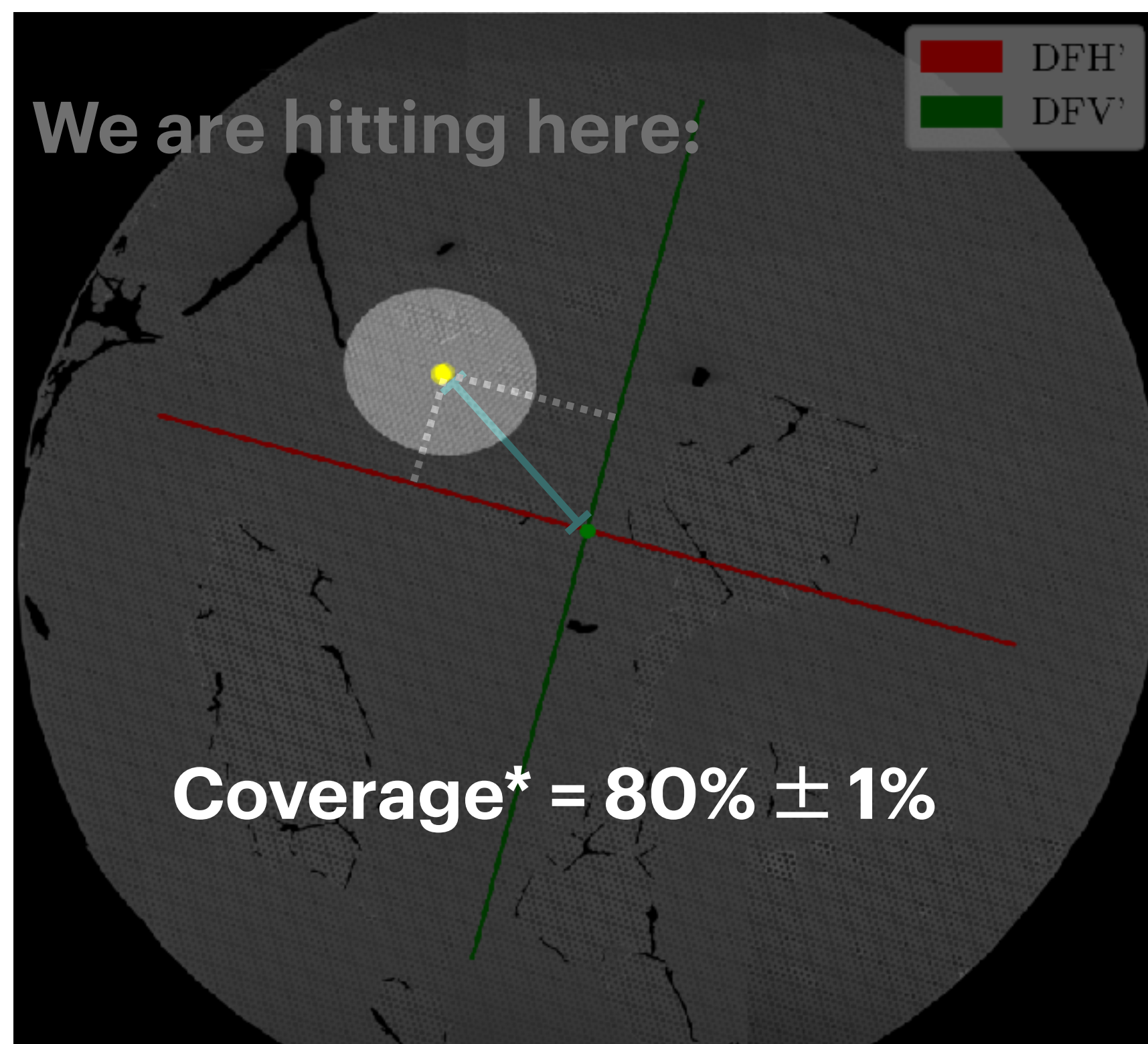
TRANSMISSION “*AS PREPARED*”

$$T_G = \frac{1}{a} \left(\frac{I_{meas}}{I_0 T_{grid}} - (1 - a) \right)$$



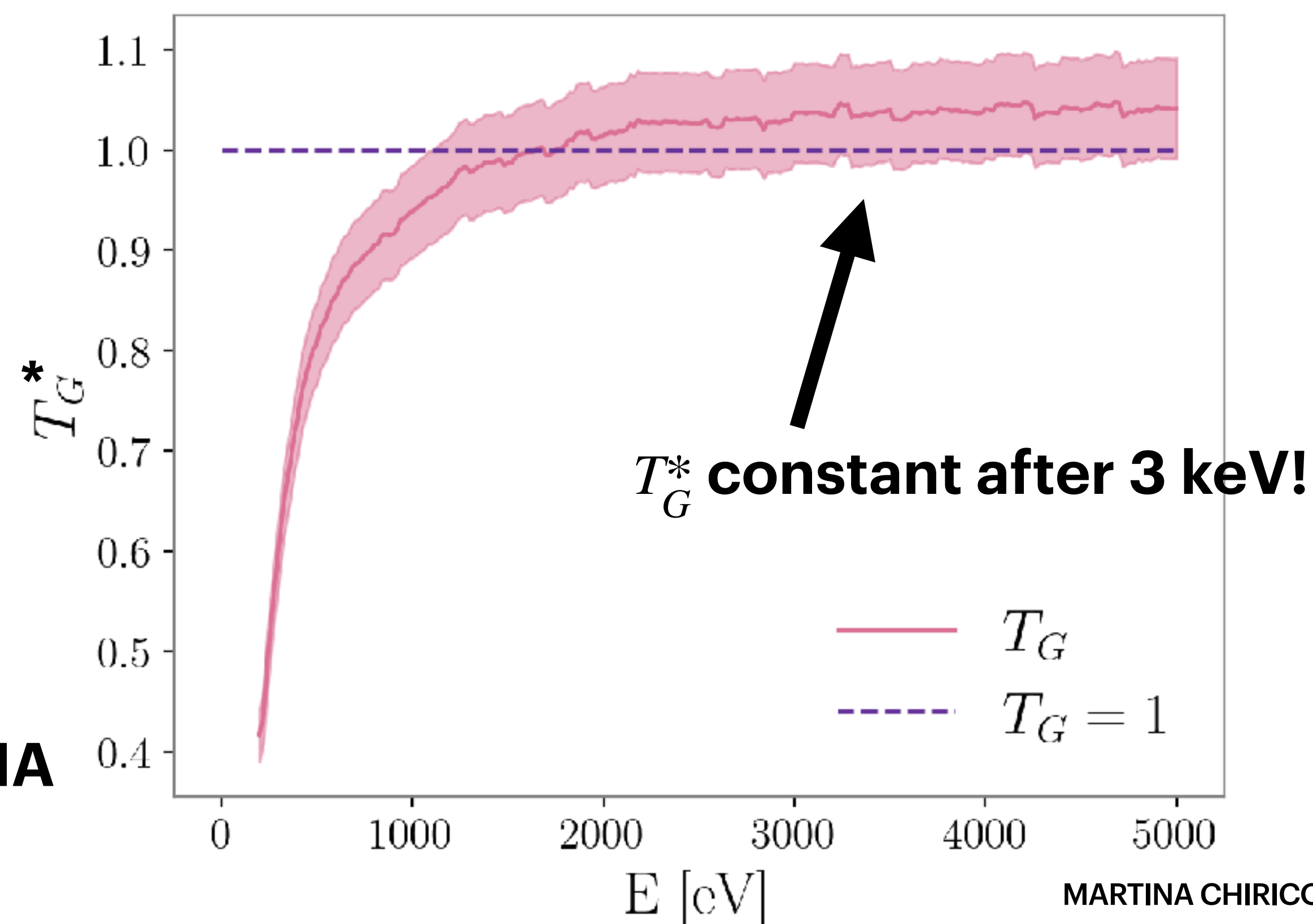
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TRANSMISSION “AS PREPARED”



* *Sample as prepared* = graphene + PMMA

$$T_G = \frac{1}{a} \left(\frac{I_{meas}}{I_0 T_{grid}} - (1 - a) \right)$$



SAMPLE IS CLEANED THROUGH ANNEALING

- **We want to preserve
as much graphene as
possible**

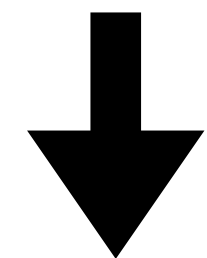
SAMPLE IS CLEANED THROUGH ANNEALING

- We want to preserve as much graphene as possible

1 hour @ 350°C



1 hour @ 350°C



XPS and EELS

SAMPLE IS CLEANED THROUGH ANNEALING

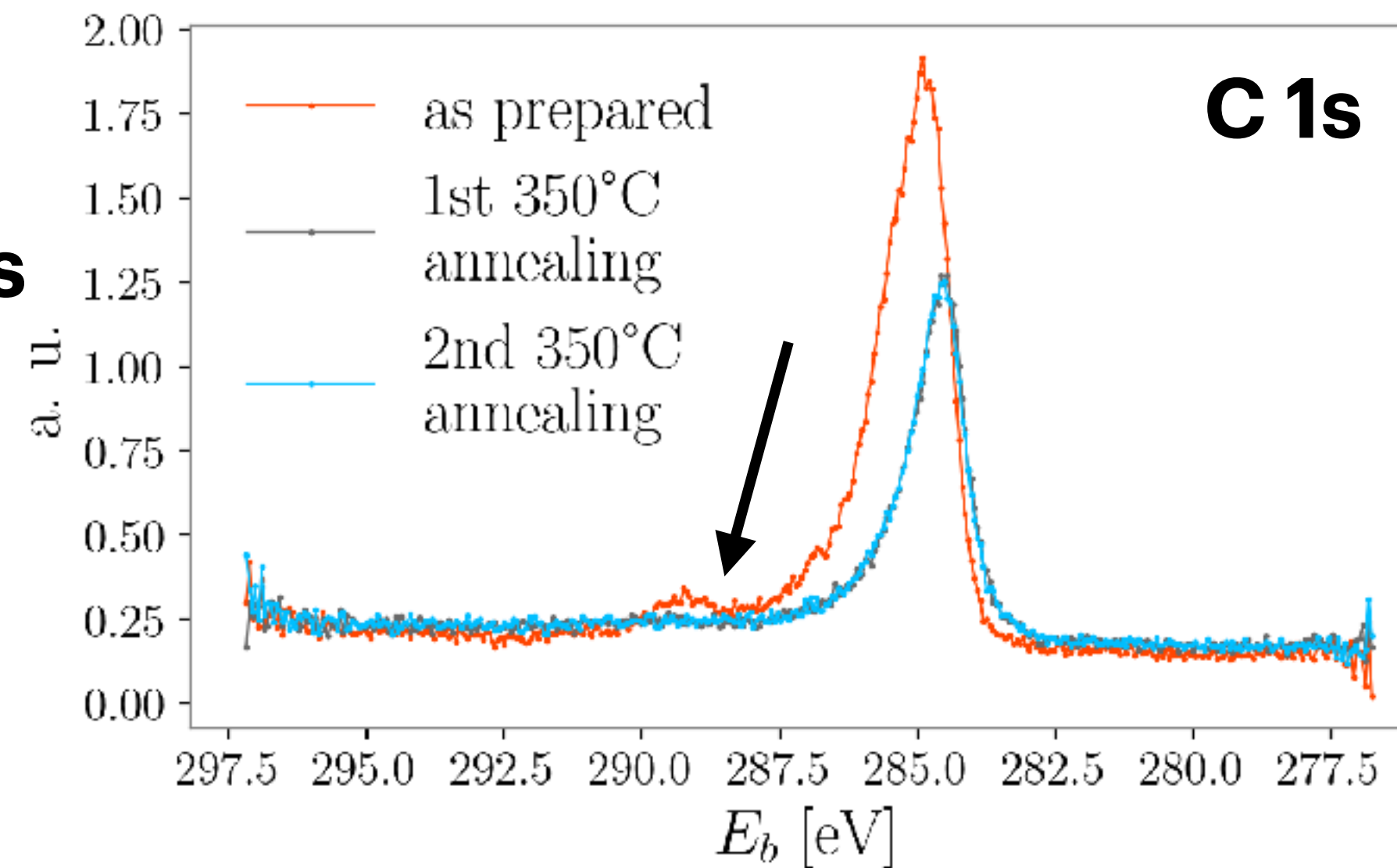
- We want to preserve as much graphene as possible

1 hour @ 350°C

XPS and
EELS

1 hour @ 350°C

XPS and EELS



SAMPLE IS CLEANED THROUGH ANNEALING

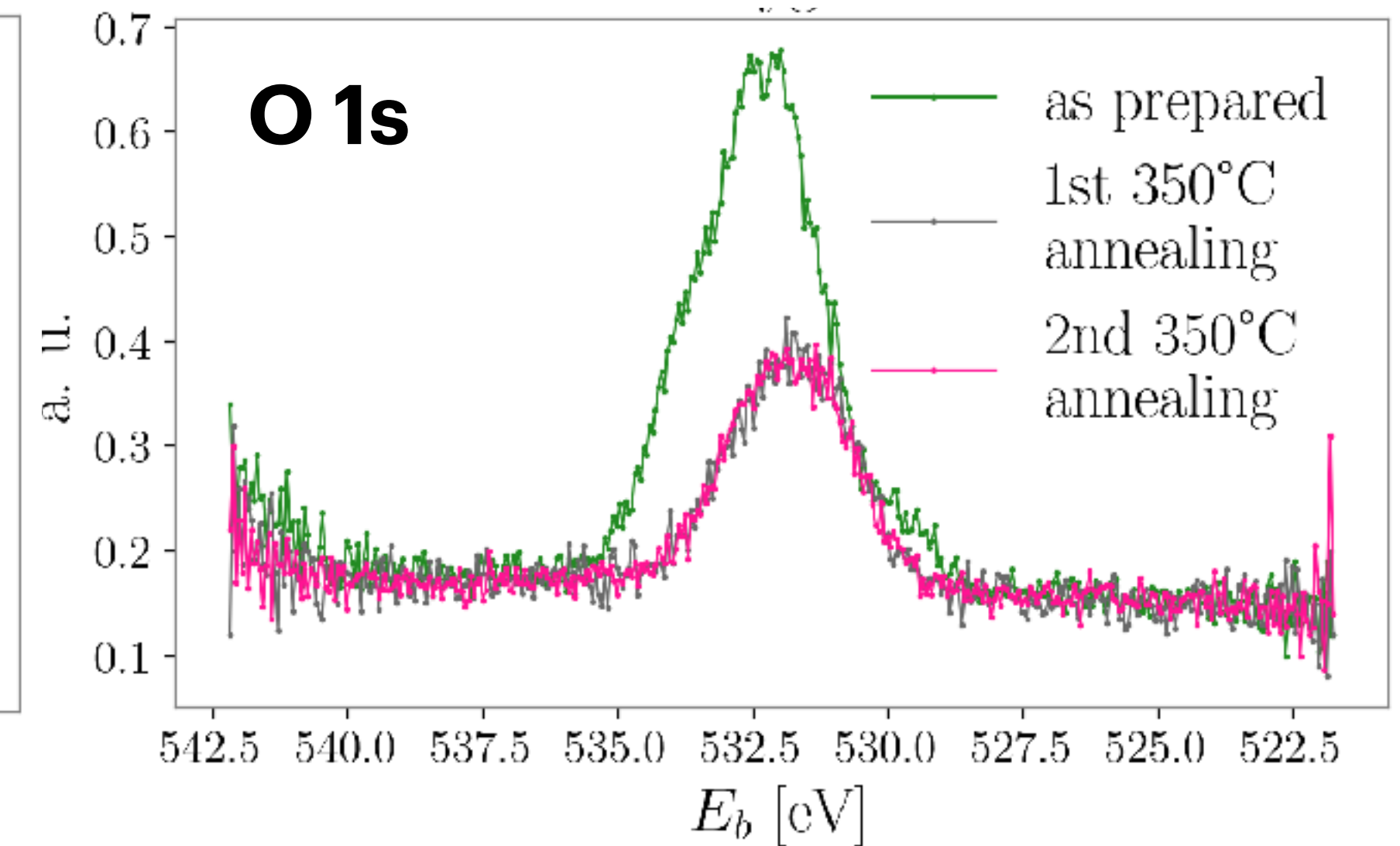
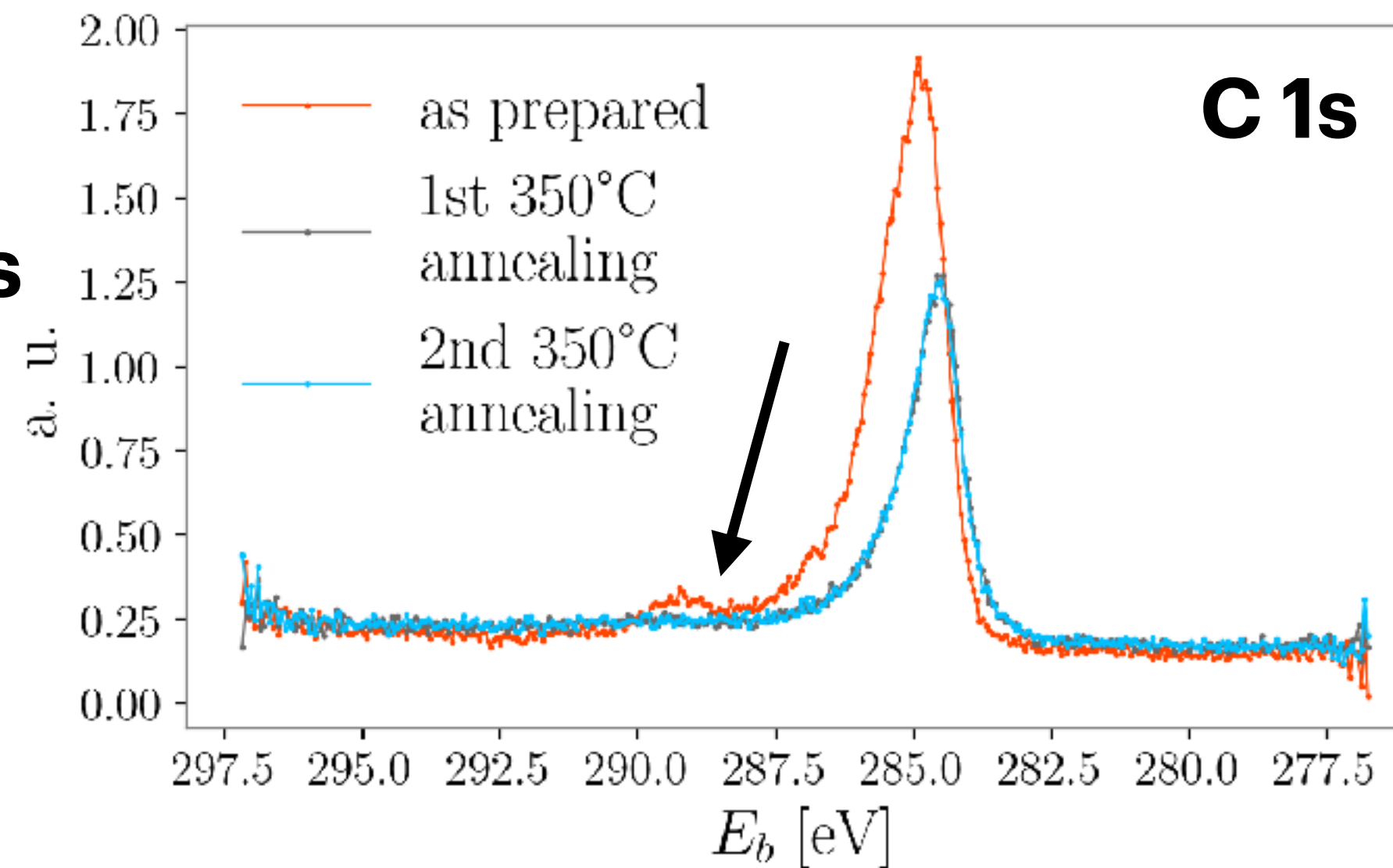
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SAMPLE IS CLEANED THROUGH ANNEALING

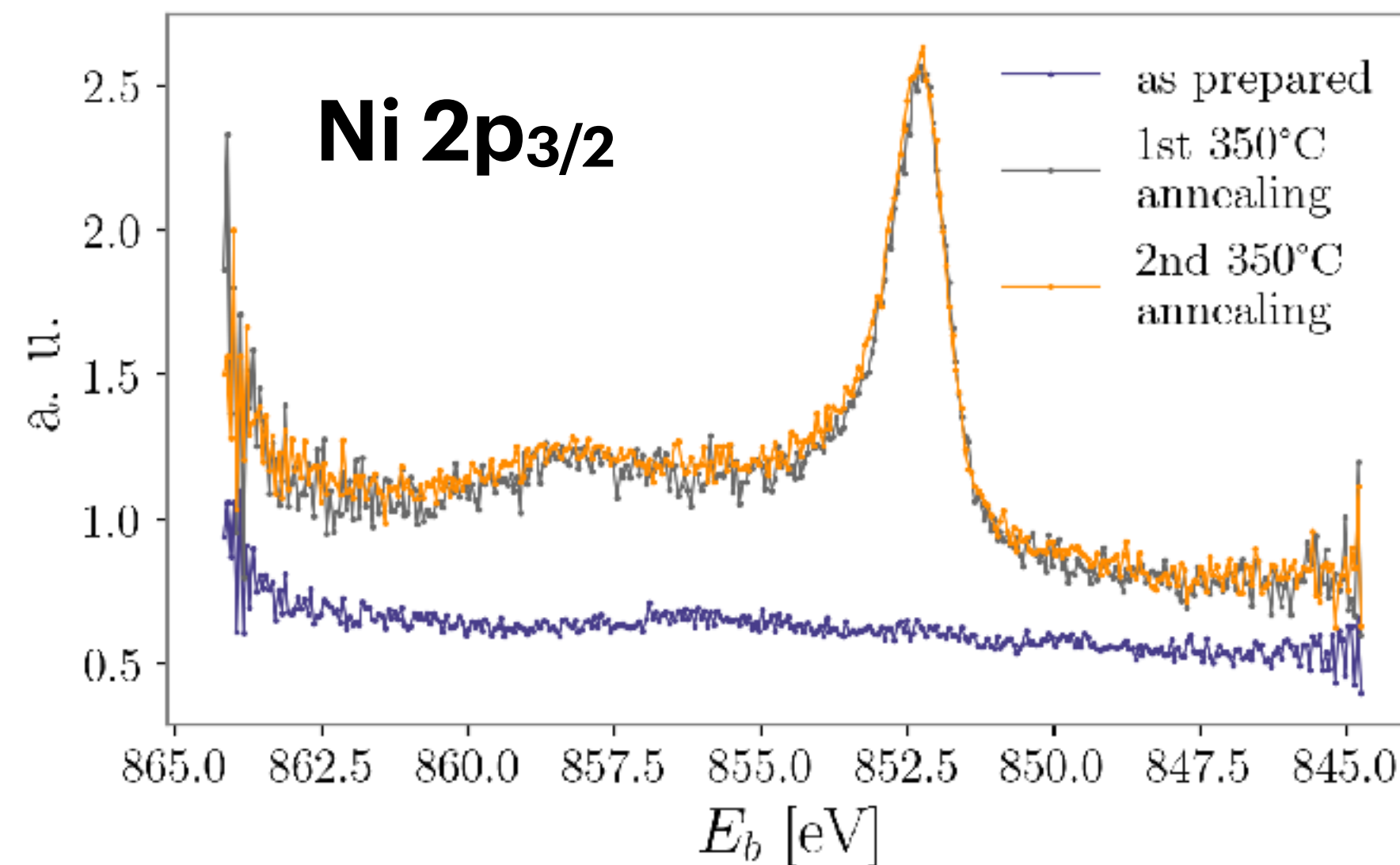
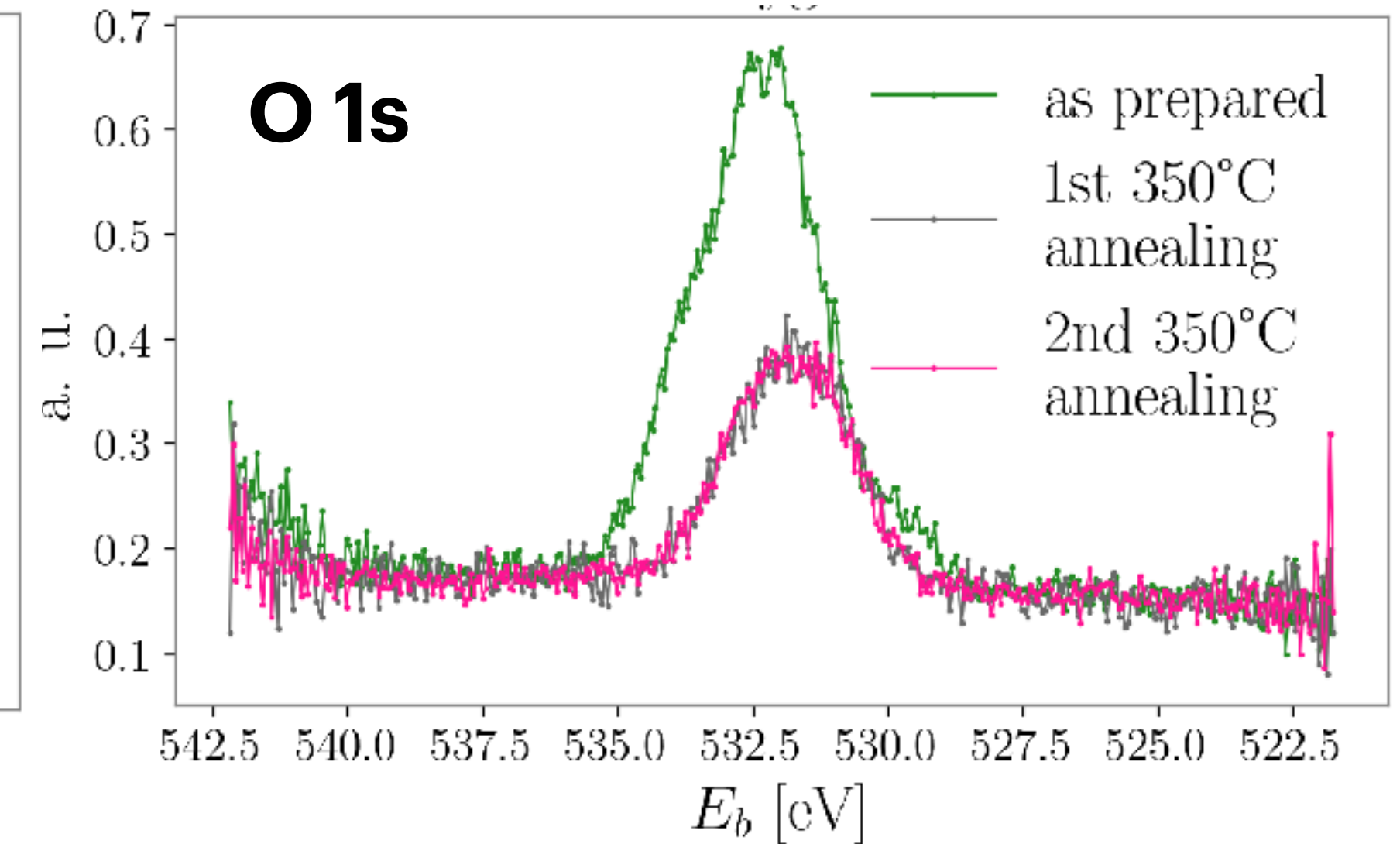
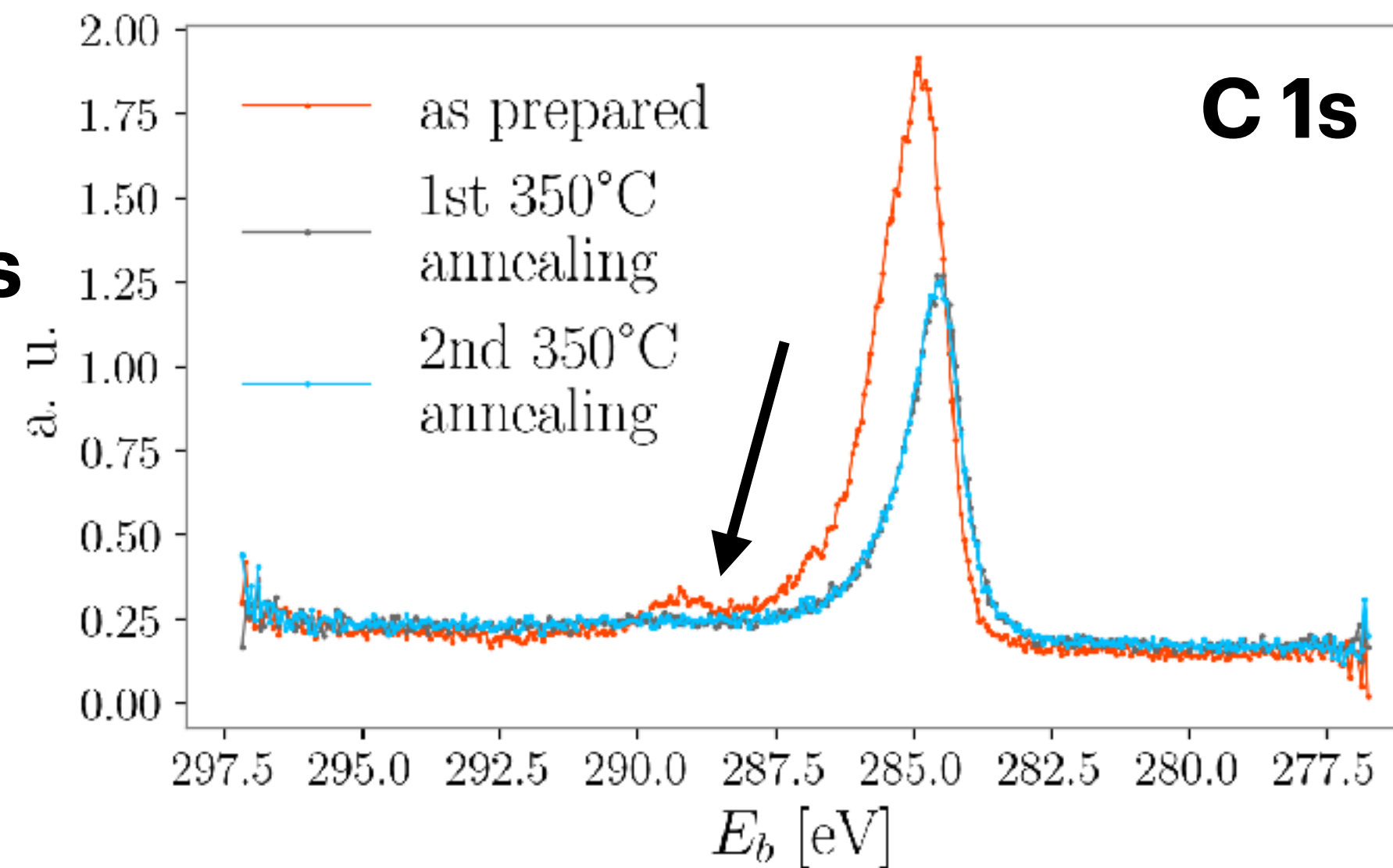
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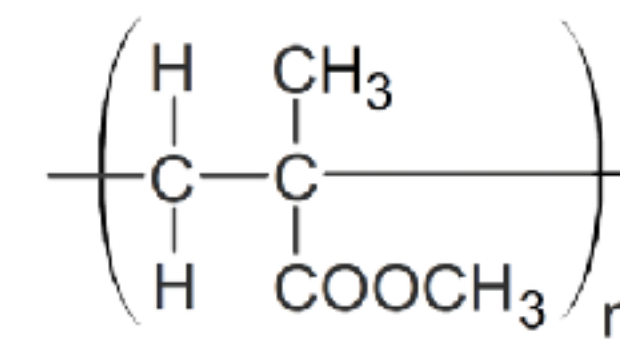
XPS and
EELS

1 hour @ 350°C

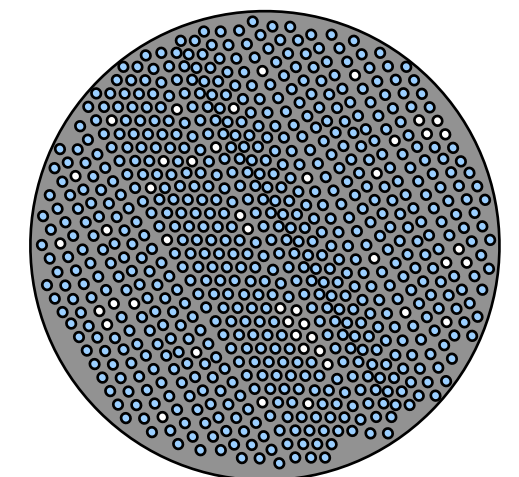
XPS and EELS



PMMA:



Nickel grid:



SAMPLE IS CLEANED THROUGH ANNEALING

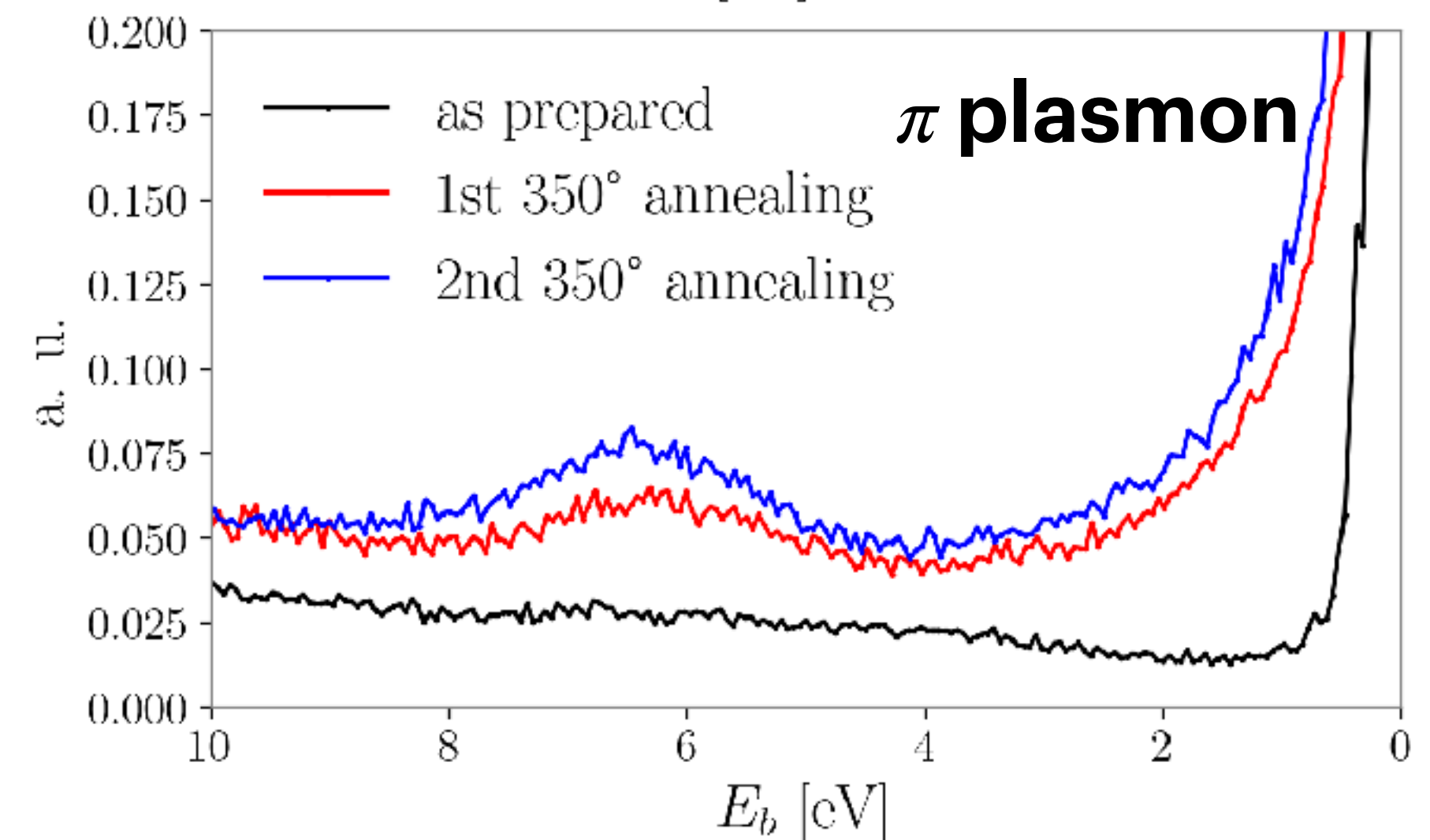
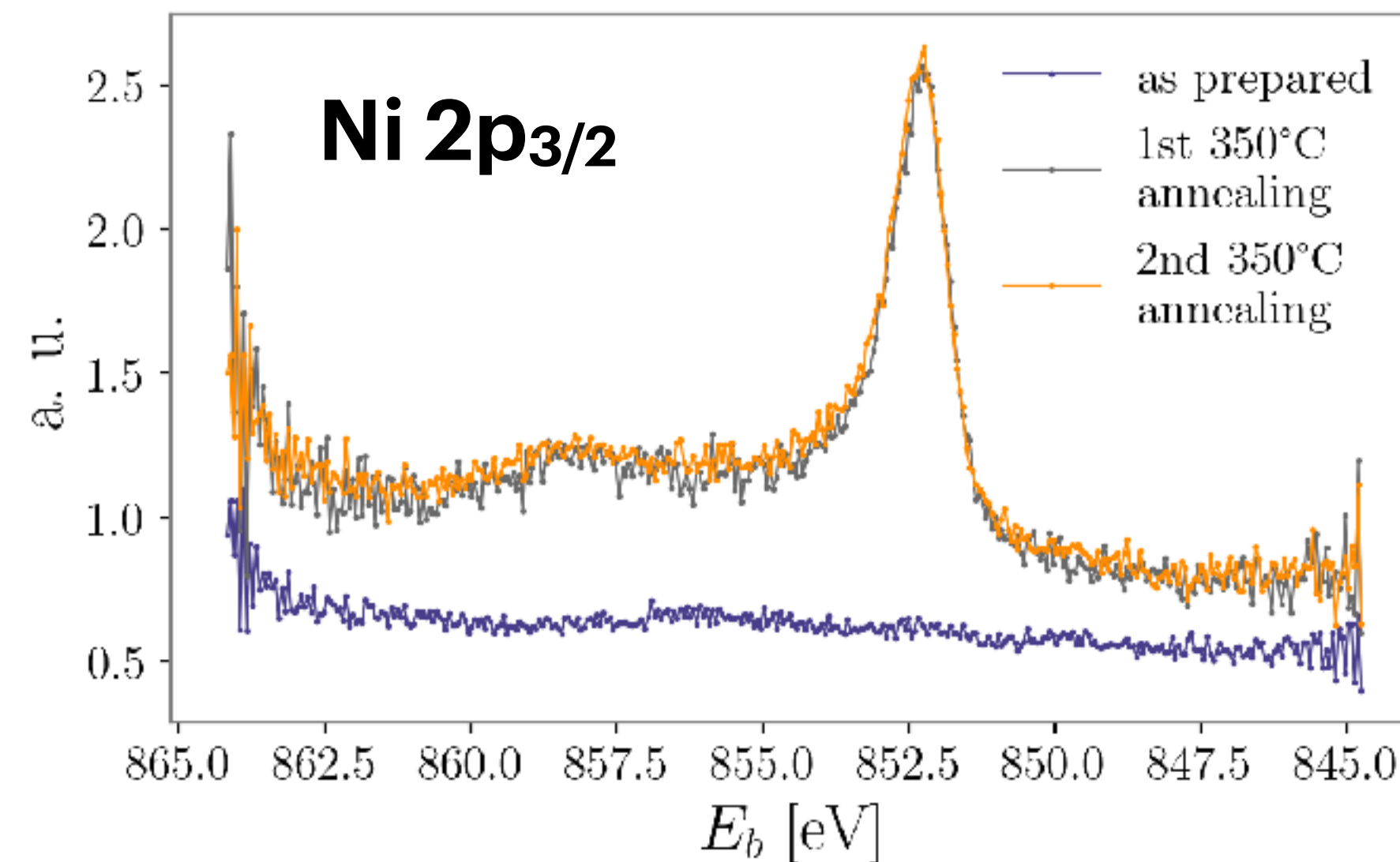
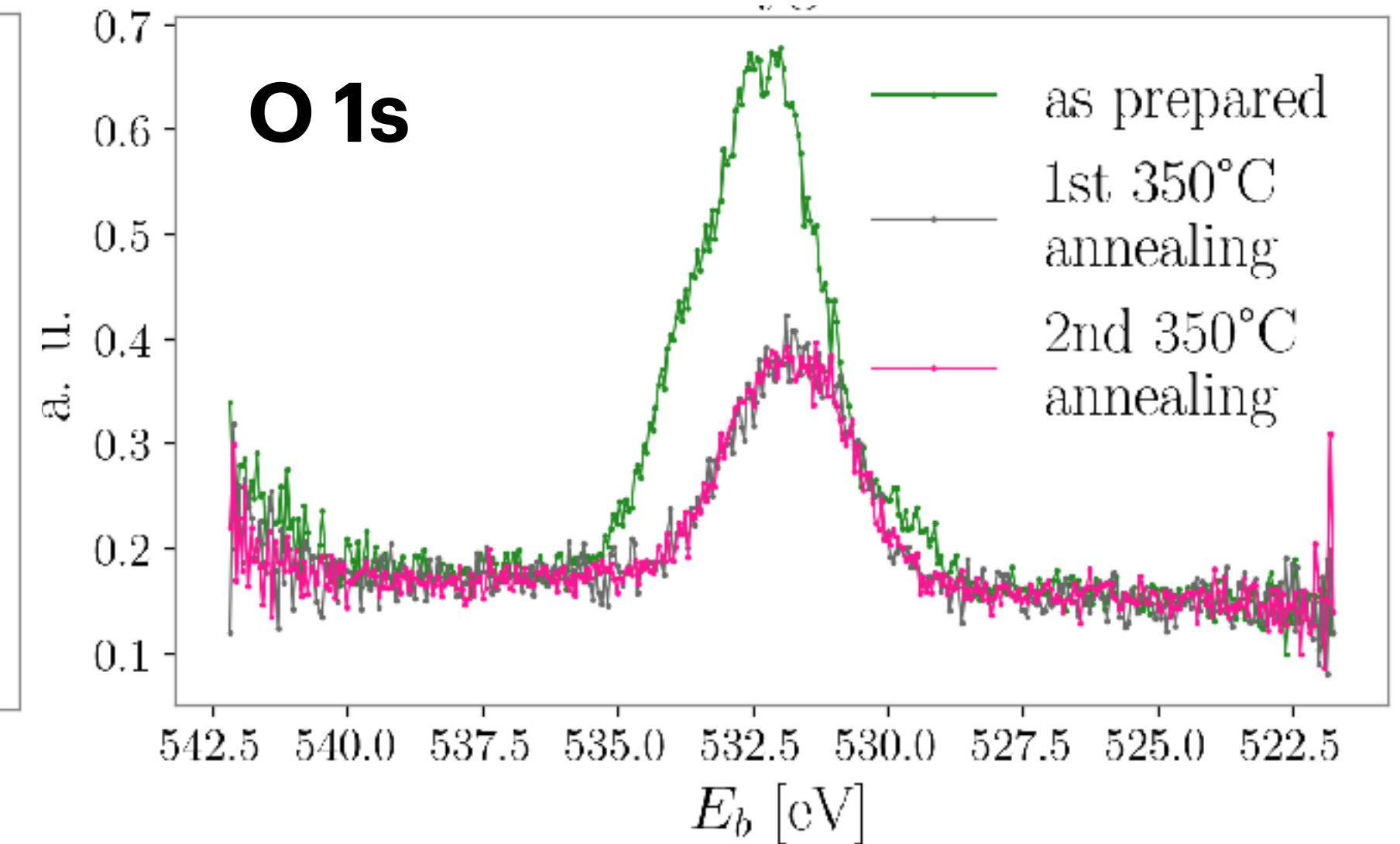
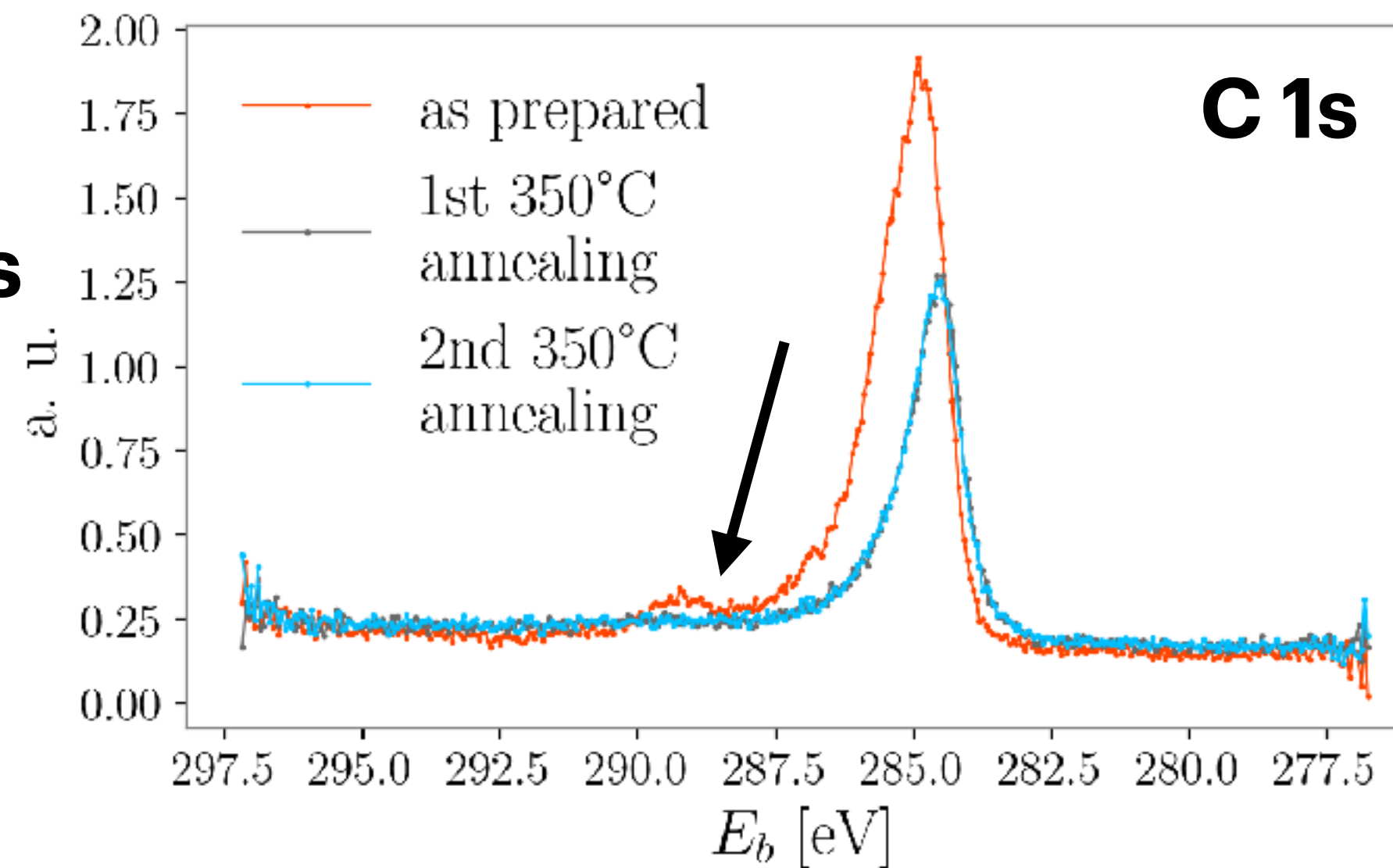
- We want to preserve as much graphene as possible

1 hour @ 350°C

XPS and
EELS

1 hour @ 350°C

XPS and EELS

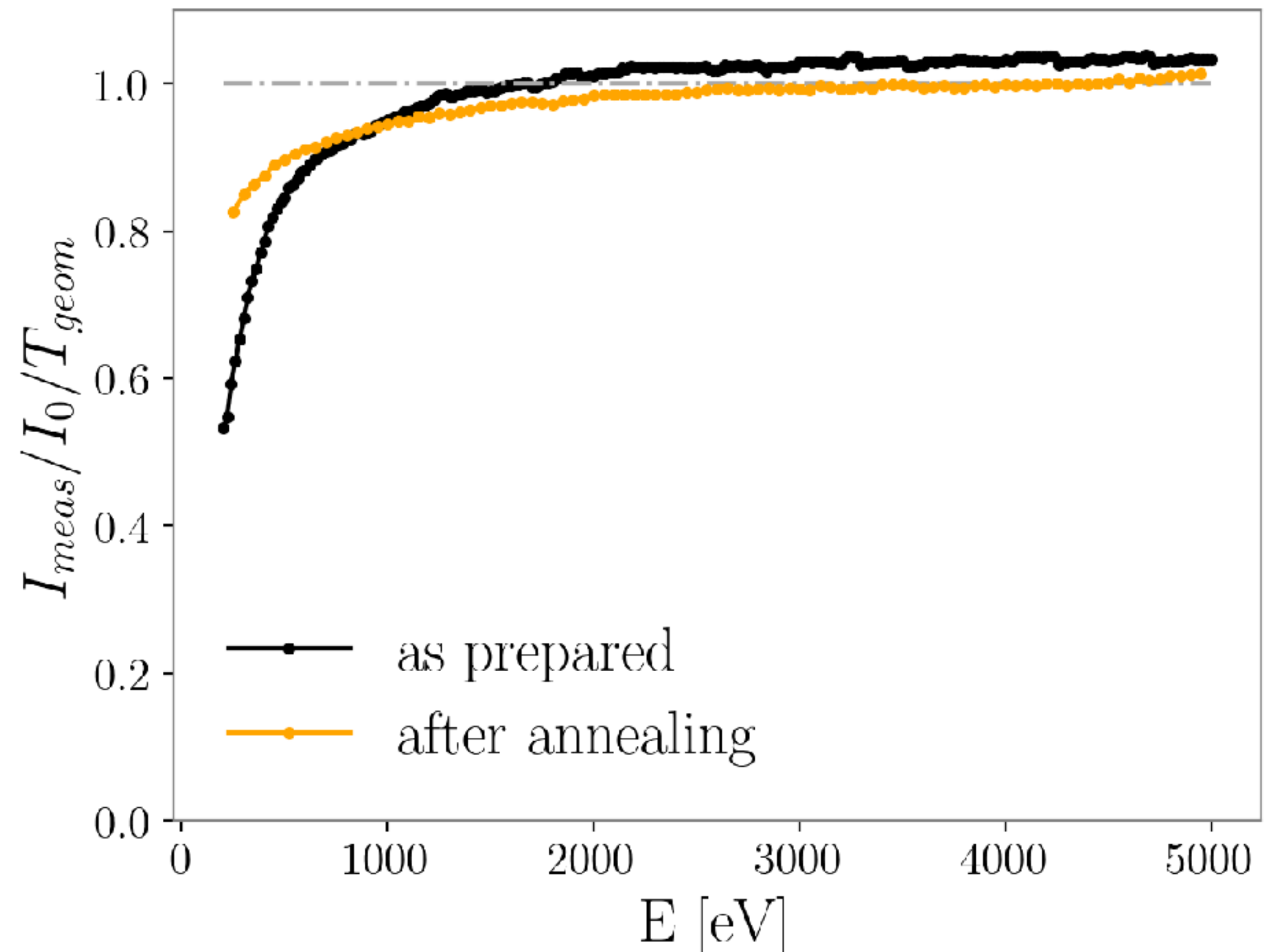


TRANSMISSION AFTER ANNEALING

WORK IN PROGRESS!

First considerations:

- Energy dependency: we still have graphene on the sample!
- Transmission improves after annealing
- **Transparency** after 3 keV!



TO CONCLUDE:

- The measurement of the **transmission** of electrons through graphene between 200 eV and 5000 eV has been performed on the as prepared sample
- Graphene monolayer as prepared is **practically transparent** to electrons above 3 keV
- The sample has been cleaned with **double annealing** at 350° C
- Transmission in the same range through the clean sample is reveals higher transmission at lower energies and is still **transparent** to electrons
- **SEM investigation** scheduled for next week

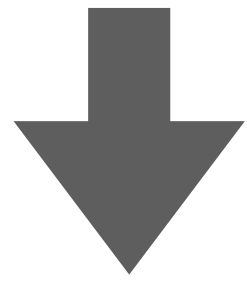
Thank you for your attention!

BACKUP



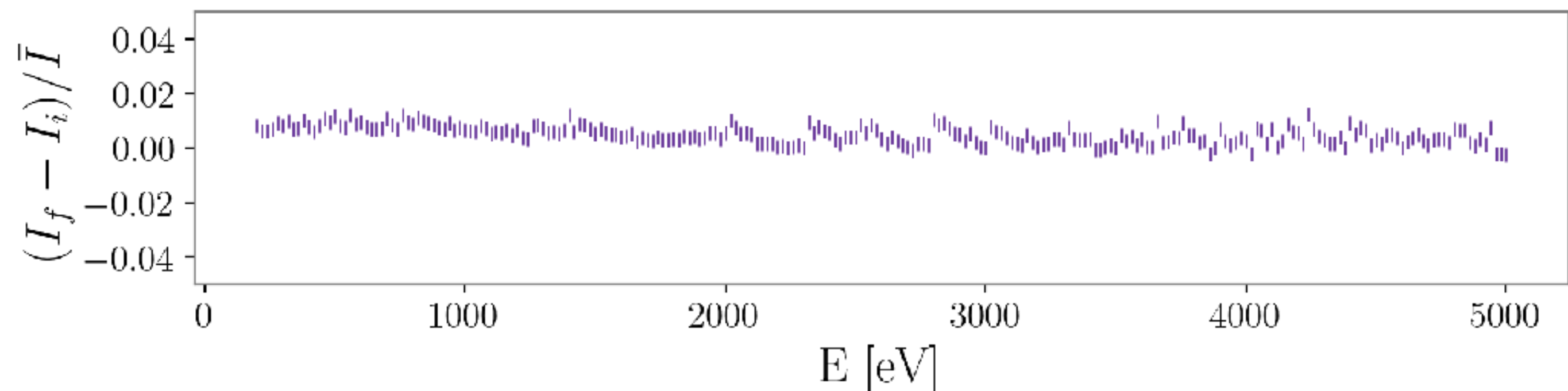
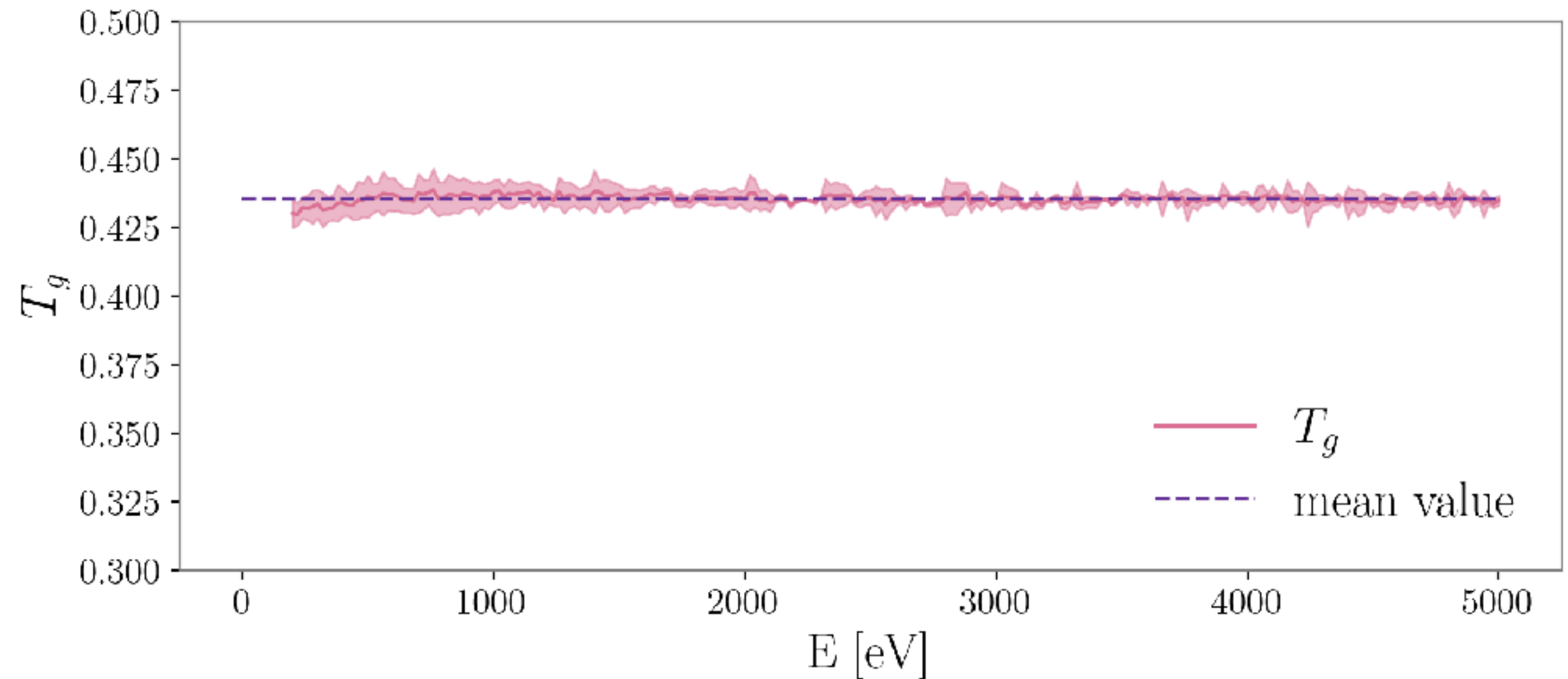
CHECKS WITH AN EMPTY GRID

- Geometric transmission of an empty grid does **not depend** on in energy



We can use SEM images of the grid to estimate it

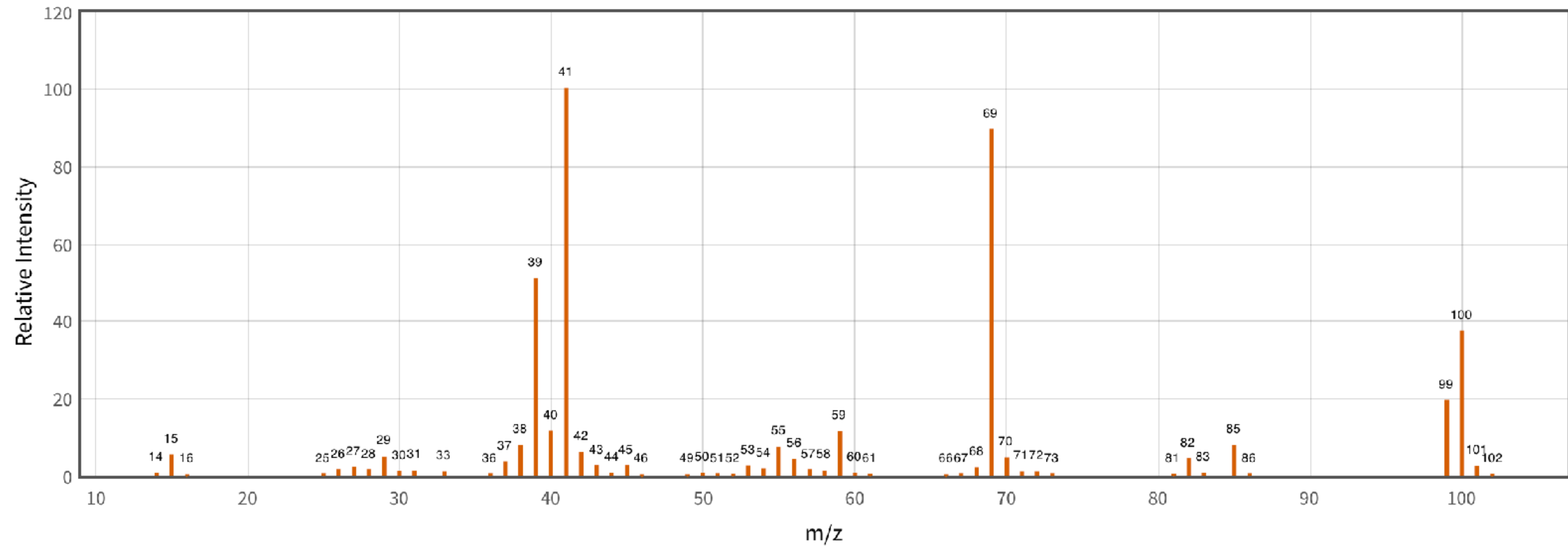
- Current fluctuations during a single measurement below 1%



PMMA FRAGMENTATION PATTERN

Methyl methacrylate

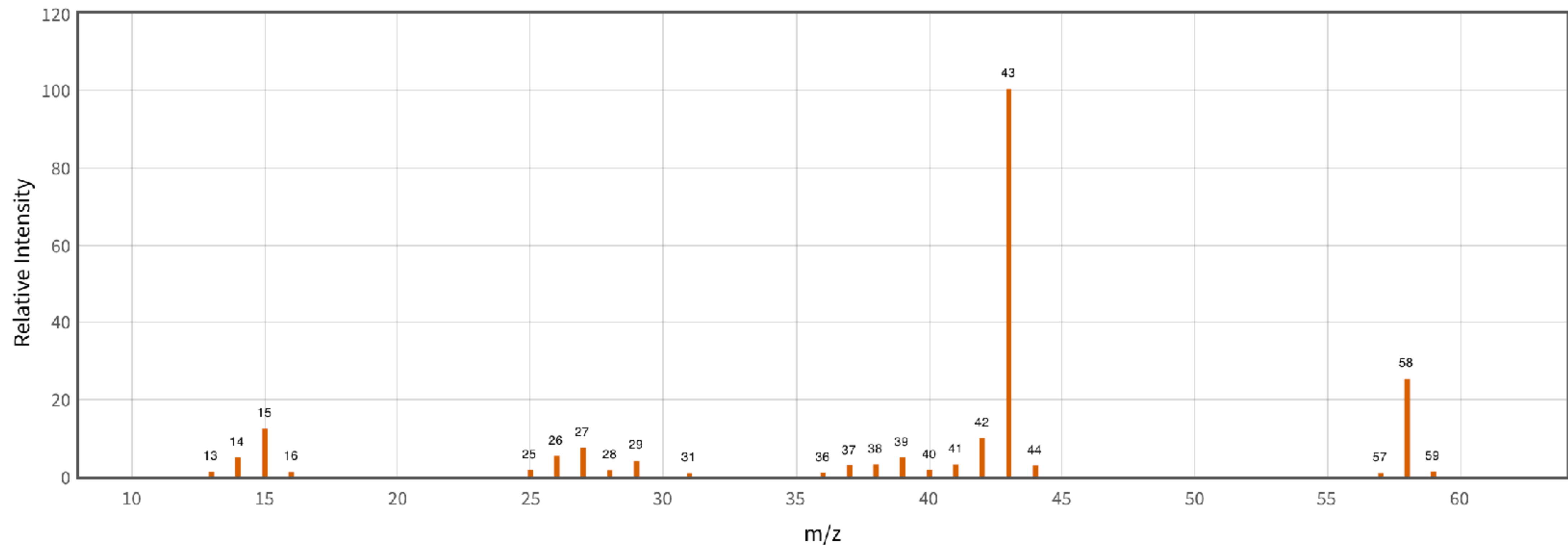
Mass Spectrum



ACETONE FRAGMENTATION PATTERN

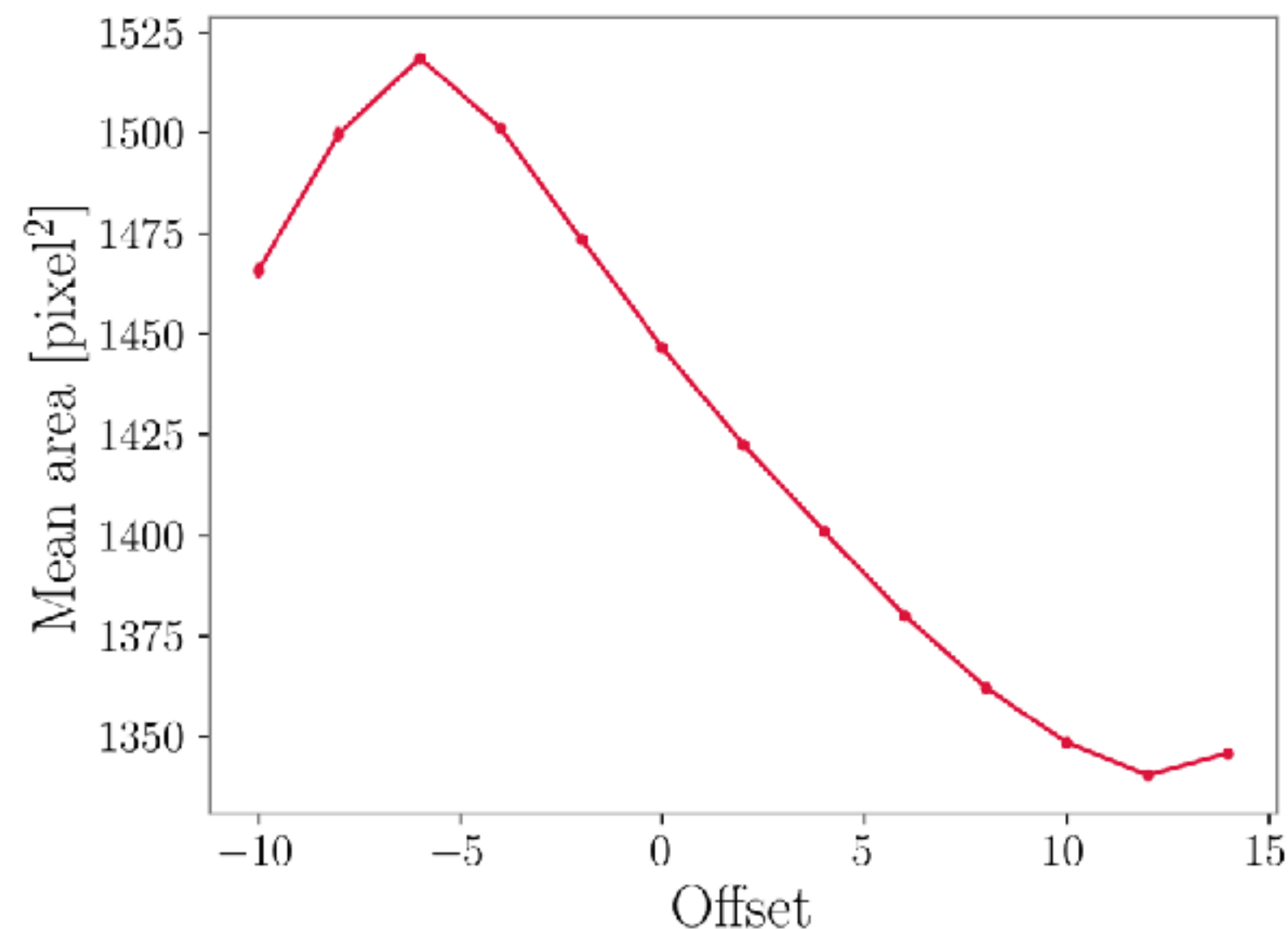
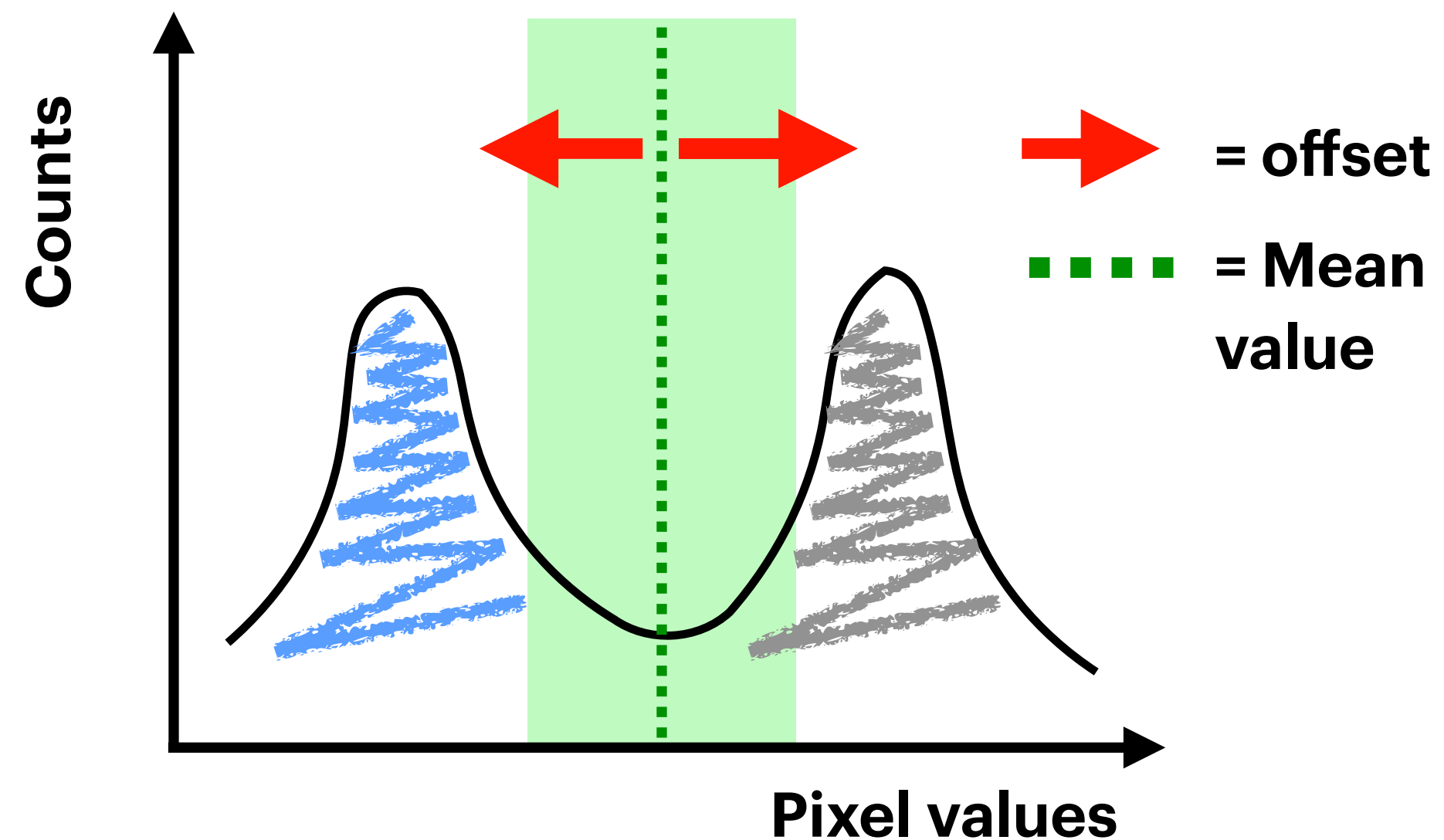
Acetone

Mass Spectrum



MEASURE HOLE AREAS

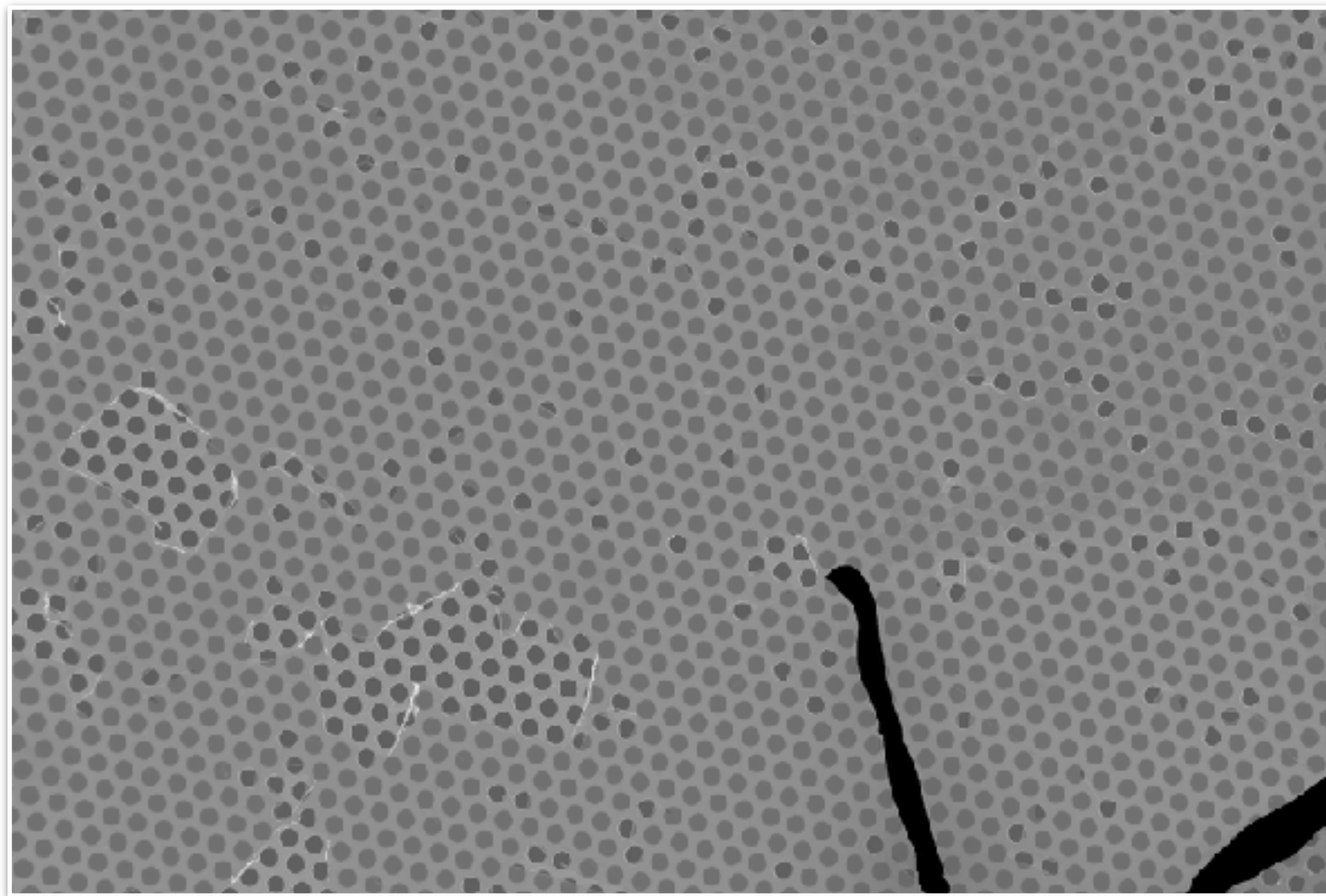
- Uncertainty in the definition of the **border** of a hole. With this method covered and uncovered holes appear to have different areas
- Change threshold by adding an **offset** to the mean value and see how the mean area changes



- New SEM analysis will help us to investigate this aspect

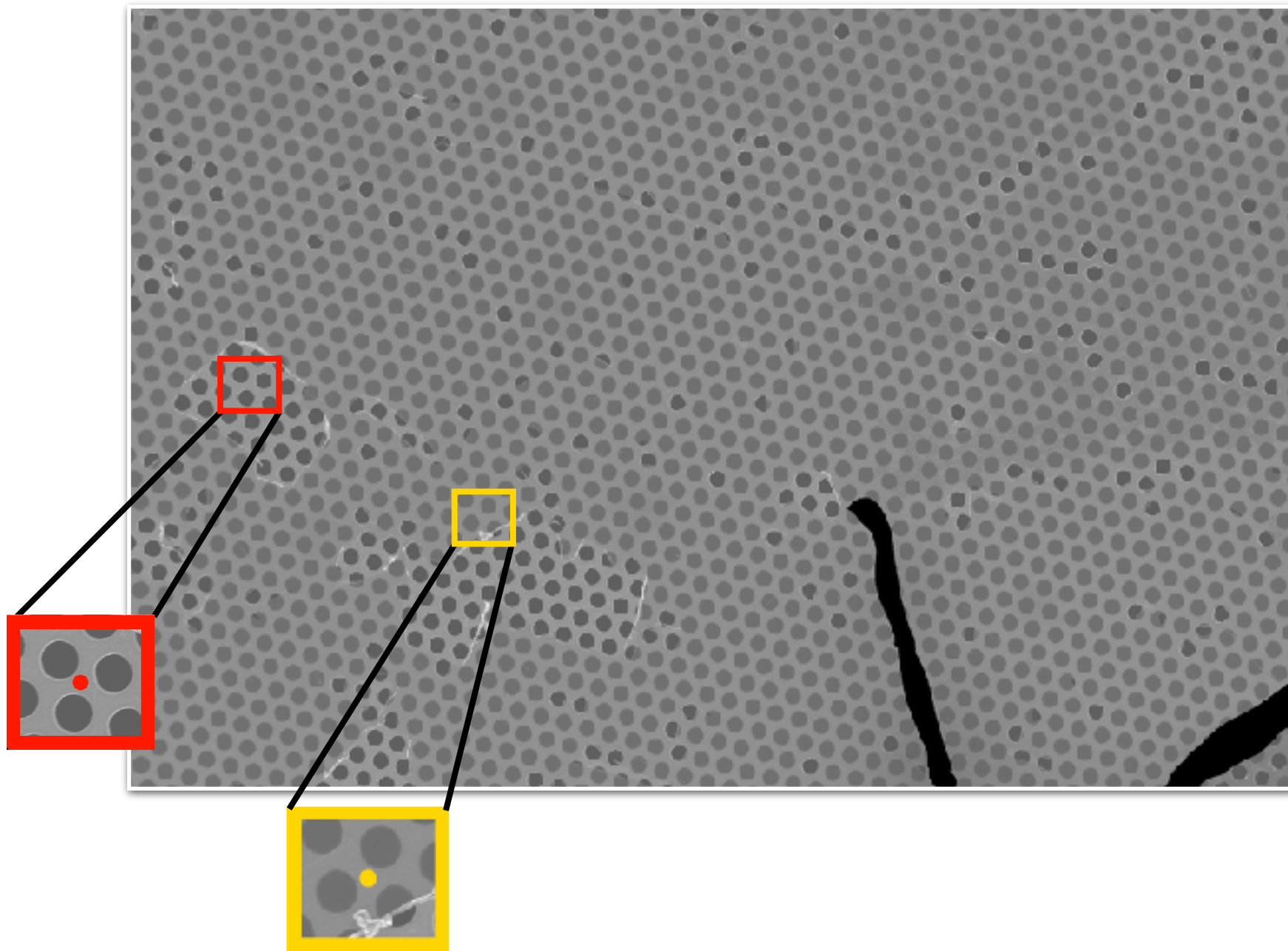
CREATE A MASK TO EXTRACT HOLES

- Cut labels and corrupted parts



CREATE A MASK TO EXTRACT HOLES

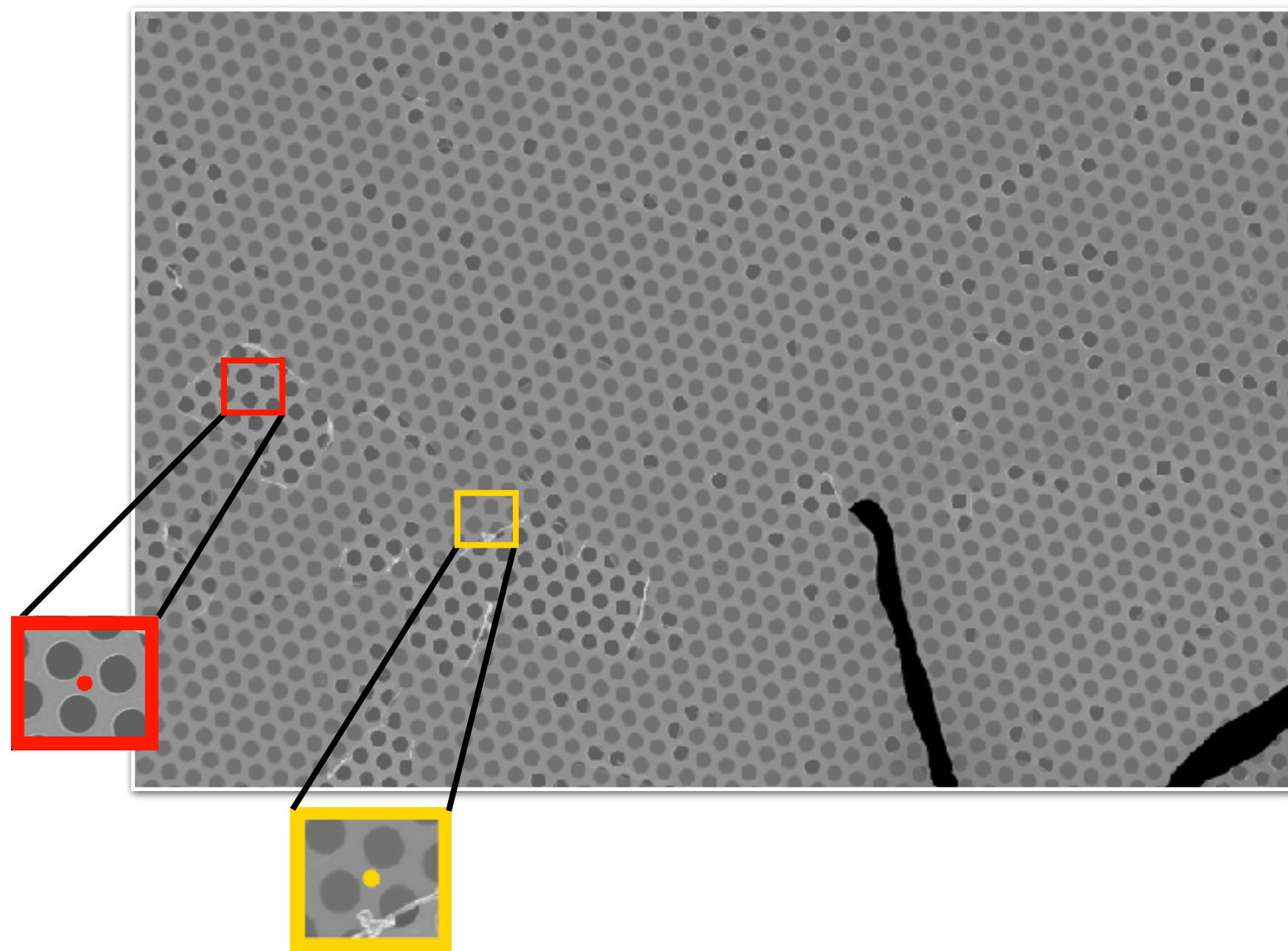
- Cut labels and corrupted parts



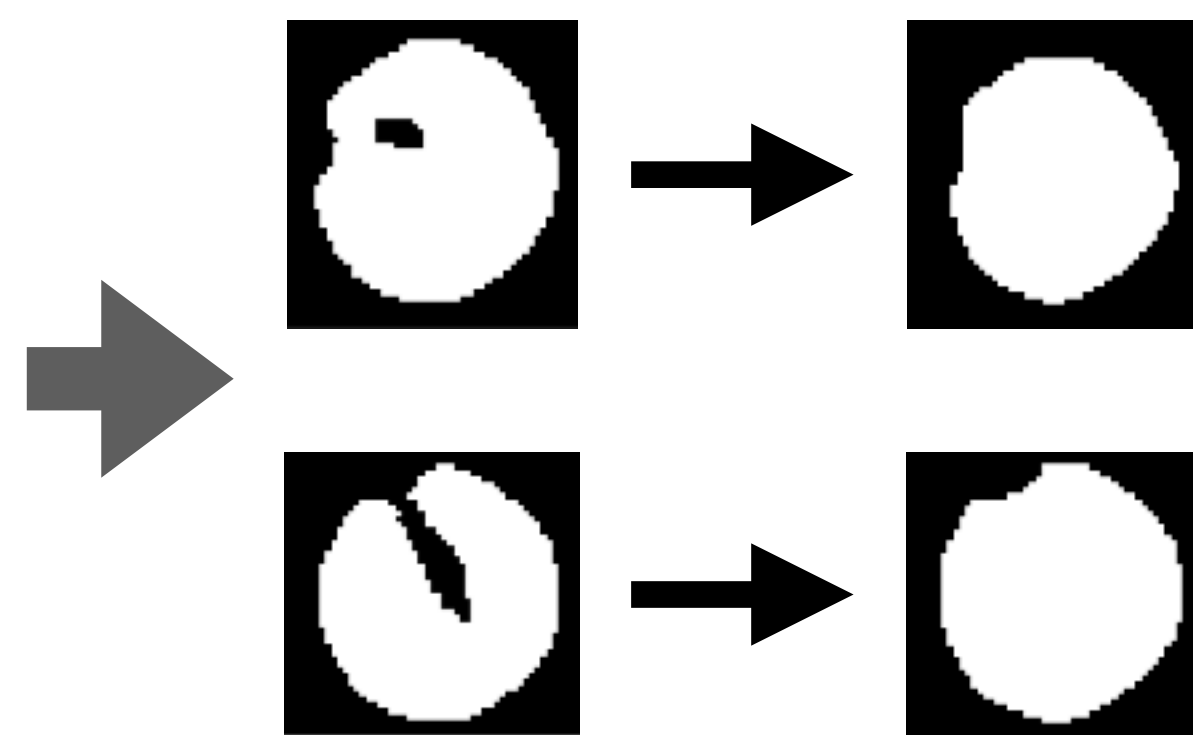
- Choose threshold pixel by pixel (*Adaptive threshold*):
mean inside the box + **offset**

CREATE A MASK TO EXTRACT HOLES

- Cut labels and corrupted parts



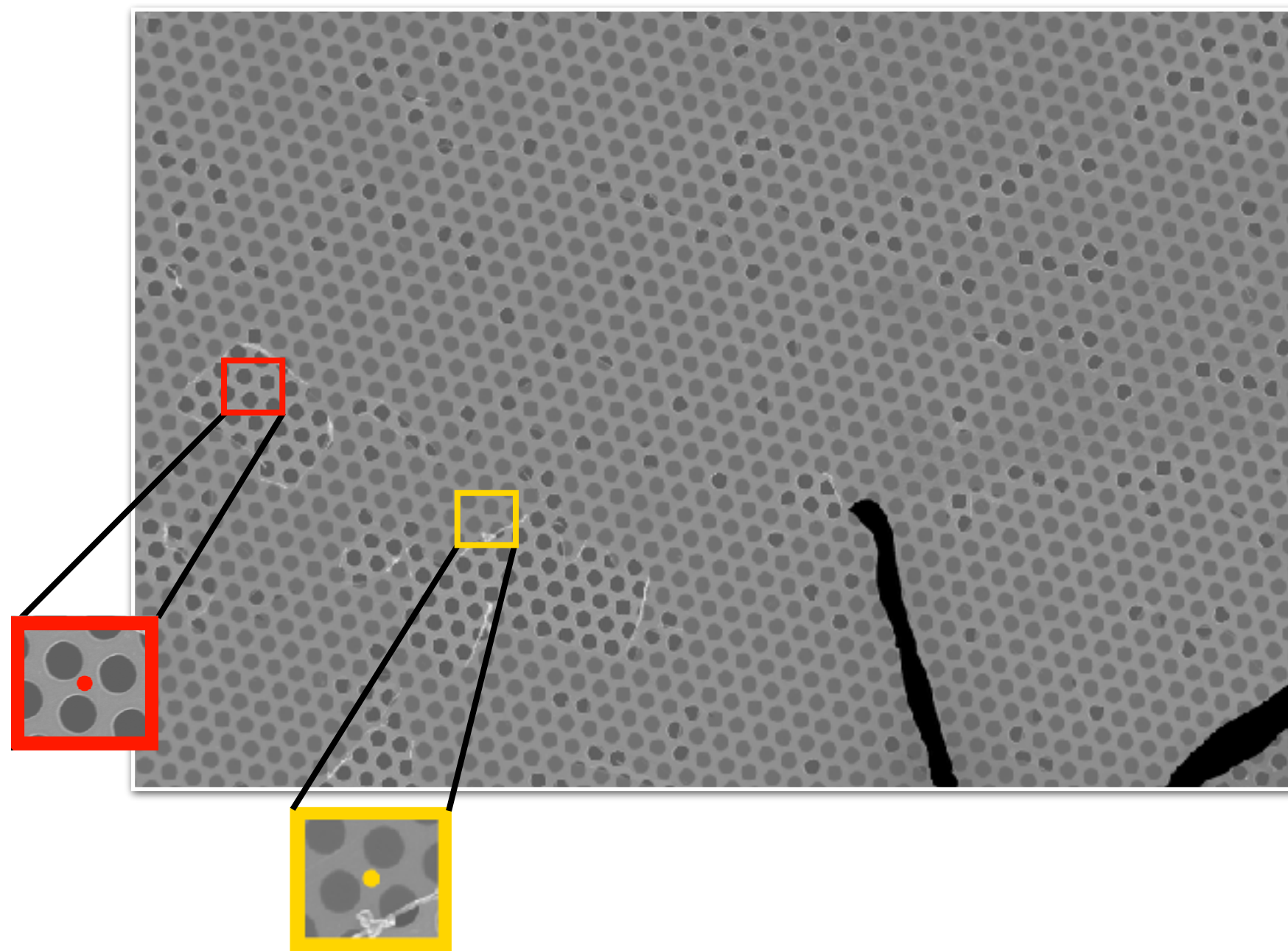
- Choose threshold pixel by pixel (*Adaptive threshold*):
mean inside the box + **offset**



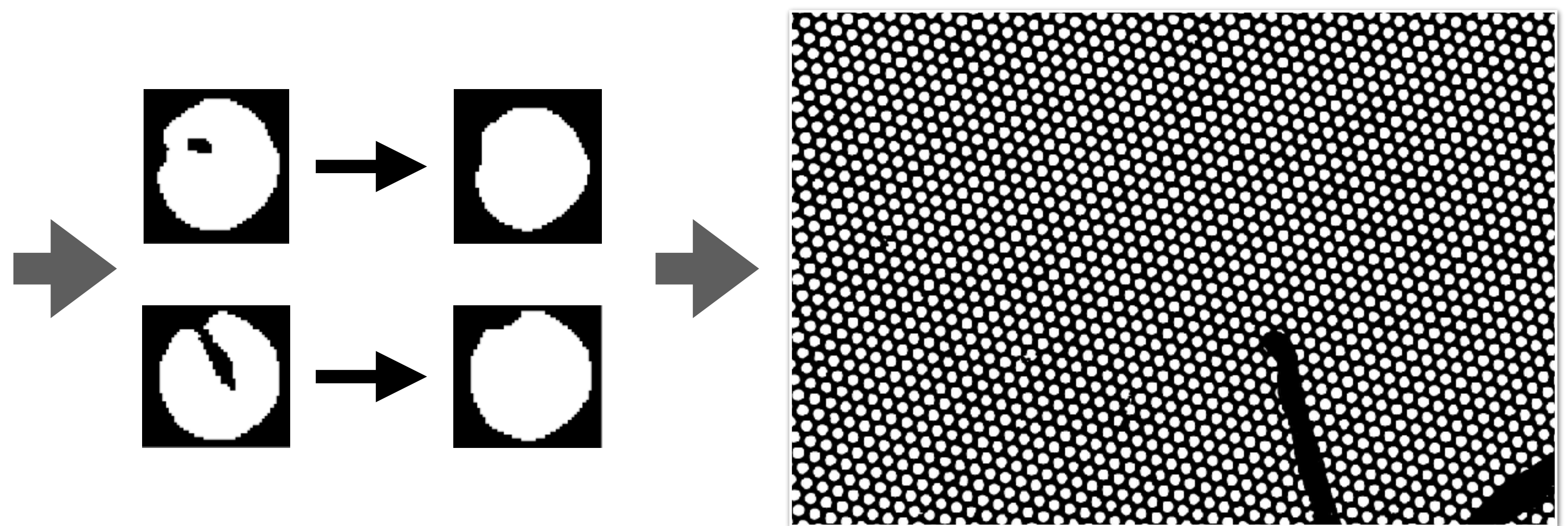
- “Compactify” objects
(*Morphological closure*)

CREATE A MASK TO EXTRACT HOLES

- Cut labels and corrupted parts



- Choose threshold pixel by pixel (*Adaptive threshold*):
mean inside the box + **offset**



- “Compactify” objects (*Morphological closure*)

- Select *good* holes:
 - size $\in [1100, 1700] \text{ pixel}^2$
 - circularity $\in [0.92, 1.00]$